# INSTRUMENT ENGINEERS' HANDBOOK

Fourth Edition

# Process Control and Optimization

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Fourth Edition

# **Process** Control and Optimization **VOLUME II**

Béla G. Lipták

EDITOR-IN-CHIEF

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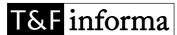
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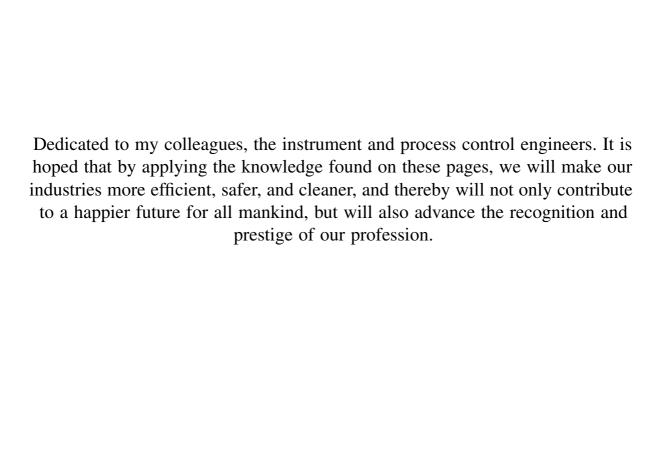
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### INTRODUCTION

This is the fourth edition of the *Instrument Engineers' Handbook (IEH)*. This handbook serves the automation and control engineering (ACE) profession and has been published once every decade since 1969. The subject of the first volume is measurement; the second volume deals with control; and the third volume is devoted to the topics of software and digital networks.

In the introduction to each new edition, I give a summary of the key developments of the previous decade and point to the challenges we face in the coming decade. Before discussing the previous and the next decades, however, I will say a few words about the growing pains of the ACE profession. I will conclude this introduction with a brief summary of the history of this handbook.

#### **AUTOMATION AND CONTROL ENGINEERING (ACE)**

Ours is a very young profession. When the first edition of the *Instrument Engineers' Handbook (IEH)* was published, Marks' *Mechanical Engineers' Handbook* was in its fifth and Perry's *Chemical Engineers' Handbook* was in its sixth edition. It is partly for this reason that while people know what kind of engineer an ME or a ChE is, they have no idea what I do when I say that my field is process control or instrumentation. I just get a blank stare.

It is time for us to change that. The first step should be to use a name for our profession that people understand. It is time for our profession to develop a distinct identity.

When I was teaching at Yale, my course was offered under the Chemical Engineering Department. This was not because Yale had anything against our profession; it was simply because they did not know where to put my course. Even this handbook of mine proves the confusion about our identity, because Taylor & Francis publishes this handbook among its Electrical Engineering books. Once again, the reason is not that Taylor & Francis has something against our profession. No, the reason is that we have not yet developed our distinct identity.

"Automation" is a term that the wider public understands. Therefore, I would suggest that we consistently refer to our profession as Automation and Control Engineering (ACE). Together with that, the name of our professional society should also be changed to International Society of Automation (ISA). Another clarifying step could be to change the title of our society magazine from *InTech* to *AutomationTech* because "In" does not say much.

The potentials of the ACE profession are great. While as a profession we have been anonymous, we have already designed fully automated Mars explorers and fully optimized industrial plants. Now it is time to let the world know that we exist. It is time to add to the list of ME, EE, or ChE professional engineering licenses one for ACE engineers; it is time for universities to offer degrees in ACE engineering and for publishers to set up ACE departments.

We should not be shy about this. After all, no engineering profession can claim what we can. No engineering profession can offer to increase the global gross domestic product by trillions of dollars simply through optimization, without building a single new plant, while also *increasing* safety and *reducing* pollution. We can do that. We can increase productivity without using a single pound of additional raw material and without requiring a single additional BTU of energy. Yes, our profession does deserve a distinct identity.

#### **DEVELOPMENTS OF THE LAST DECADE**

These days, the computer is our main tool of control. The chapters of this volume describe how the computer is being used in optimizing our processes, providing self-diagnostics, and displaying status information in operator-friendly formats. Today, the World Wide Web provides access to great quantities of data; in the future it will also provide problem-solving capability, so that through the grid, every ACE engineer will have a supercomputer at his or her disposal.

During the last decade, the artificial separation between the roles of DCS, PLC, and PC packages has started to disappear because their separate roles of control (DCS), logic sequencing (PLC), or simulation, and business-related tasks (PC) are beginning to be integrated. I believe that in the near future DCS will simply mean digital control system. Once the digital bus protocols are integrated into a single global standard, the presently required interfacing cards (and the associated risk of mixup) will disappear, and therefore our control systems will become safer, simpler, and more effective.

In the paragraphs below I review some of the developments of the last decade.

#### Is the Age of the PID Over?

Designating a valve on a flow sheet as a temperature control valve (TCV) will not suspend the laws of nature, and this arbitrary designation will not, for example, prevent the valve from affecting the process pressure. Similarly, the number of available control valves in a process will not necessarily coincide with the number of process properties that need to be controlled. Multivariable herding or envelope control overcomes this limitation of uncoordinated single loop controllers and lets us control all variables that need to be controlled, while minimizing interactions.

The majority of our control loops are still keeping single process variables on set point, but the age of multivariable control has already arrived. In the majority of cases, we still tend to control levels, flows, and temperatures as if these single loops operated in a vacuum, but others are already recognizing that loops do interact and that the opening or closing of a control valve affects not only the one variable we are controlling. For these reasons, the decoupling of interactions based on relative gain calculations have become important tools in the tool boxes of ACE engineers.

Many of us have concluded that the single-loop mentality is wrong because our plants do not produce flows, levels, and temperatures; hence, the control of these variables should not be our ultimate goal. Our ultimate goal should be to optimize the productivity and safety of the whole plant. As a consequence, we are now thinking in terms of unit operation controllers. In these multivariable control systems, the total unit operation (be it a boiler, a distillation column, or a compressor) is being controlled.

#### **The Set Point**

Advances have also been made in rethinking the role of the set point. In one aspect, the single set point is often replaced by a set point gap, so that as long as the controlled variable is within that gap, the output is unaltered. This tends to stabilize sensitive loops, such as flow.

Another aspect in which the set point is treated differently today is its effect on the controller output. In many algorithms a change in set point does not change the proportional or derivative contributions to the output because the P and D modes act only on the measurement.

In other algorithms, while the set point change does affect the integral contribution to the output, the set point change is "feedforwarded" directly to the output to minimize reset windup. Reset windup is also minimized by external feedback, taken from the slave measurement in case of cascade loops, from the valve signal in case of selective loops, and from the inverse model in feedforward loops.

#### **Dynamics and Dead Time**

The dynamics of control are also better understood today. It is clear that for quarter amplitude damping the gain product of the loop should be about 0.5. This means that in order to keep this product constant, if the process gain doubles, the controller gain must be cut in half. This understanding is critical to the control of all nonlinear processes (heat transfer, chemical reaction, pH, etc.). Clearly understanding this goal also allows for gain adaptation based on either measurements or modeling.

Similarly, the role of dead time is also better understood today. Most ACE engineers know that the integral and derivative control modes must be tuned to match the dead time. Therefore, the control goal is to reduce the loop dead time to a minimum and keep it constant. If that is not possible because the process dead time must vary (transportation lag caused by displacing a fixed volume), it is necessary to match that variable dead time with adapted I and D settings. When the dead time is large, the regular PID algorithm is replaced with sample-and-hold or predictor algorithms.

#### **Unit Operations Controllers**

An already existing multipurpose reactor package (described in this volume) can be reconfigured through software modifications to become a stripper, distillation, or crystallizer unit controller. Other multivariable, envelope, and matrix control systems described in this volume are aimed at increasing the efficiency or the productivity of the process, while treating the individual variables—the temperatures, pressures, and levels—only as constraints.

There are hundreds of expert systems, all serving some form of optimization. From the perspective of their methods of operation, one can group them into model-based and model-free methods. They both control multivariable unit operations and because they both evaluate the total process, they also eliminate the interactions between the various controlled and manipulated variables.

Expert systems, which are used in unit operations controllers, are also useful in decoupling the interactions through relative gain and other techniques. Probably the greatest progress has occurred in the area of model-based control, which utilizes both steady-state and dynamic models and allows both for the prediction of process responses before they occur and for continual refinement of the model by empirical updating. In this regard neural networks, artificial intelligence, statistical process control, fuzzy logic, and empirical optimization strategies have all made some contribution.

#### **Model-Based and Model-Free Control**

Model-Based Control (MBC), Model Predictive Control (MPC), and Internal Model Control (IMC) are suited for the

optimization of well-understood unit processes, such as heat transfer or distillation. Their performance is superior to that of model free systems because they are capable of anticipation and thereby can predict the process response to new situations. In this sense their performance is similar to that of feedforward control systems, while model-free systems behave in a feedback manner only.

The performance of a model-free expert system can be compared to the behavior of a tennis player. The tennis player does not necessarily understand Newton's laws of motion or the aerodynamic principles that determine the behavior of a tennis ball. The tennis player has simply memorized the results of a large number of past "process" responses. This is also the basis of most human learning. All the neural network—based software packages mimic this method of learning.

Neural networks, fuzzy logic, and statistical process control are all such model-free methods, which can be used without the need for knowing the mathematical model of the process. The major difference between fuzzy logic and neural networks is that the latter can only be trained by data, but

not with reasoning. Fuzzy logic is superior from this perspective because it can be modified both in terms of the gain (importance) of its inputs and in terms of the functions of its inputs.

The main limitations of all model-free expert systems are their long learning period (which can be compared to the maturing of a child) and the fact that their knowledge is based solely on past events. Consequently, they are not prepared to handle new situations. Therefore, if the process changes, they require retraining because they can only anticipate repetitive events.

#### **Artificial Neural Networks (ANN)**

One of the tools used in building models is the Artificial Neural Network (ANN), which can usually be applied under human supervision or can be integrated with expert and/or fuzzy logic systems. Figure 1 shows a three-layer ANN network, which serves to predict the boiling point of a distillate and the Reid vapor pressure of the bottoms product of a

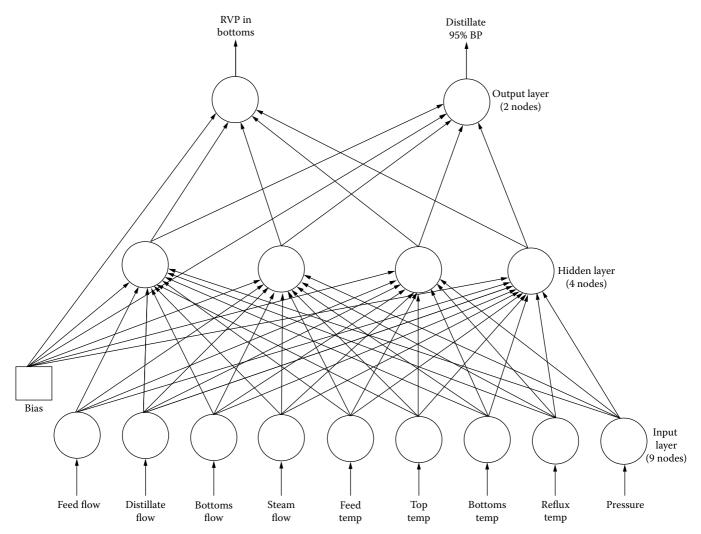


FIG. 1

A three-layer artificial neural network (ANN) can be used to predict the quality of overhead and bottoms products in a distillation column.

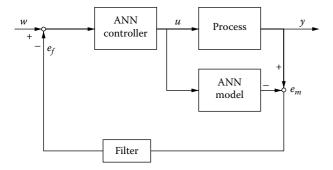


FIG. 2
The use of an artificial neural network in an IMC (Internal Model Control) application.

column. Such predictive ANN models can be valuable because they are not limited by either the unreliability or the dead time of analyzers.

The "personality" of the process is stored in the ANN network by the way the processing elements (nodes) are connected and by the importance assigned to each node (weight). The ANN is "trained" by example and therefore it contains the adaptive mechanism for learning from examples and to adjust its parameters based on the knowledge that is gained through this process of adaptation. During the "training" of these networks, the weights are adjusted until the output of the ANN matches that of the real process.

Naturally, these networks do need "maintenance" because process conditions change; when that occurs, the network requires retraining. The hidden layers help the network to generalize and even to memorize.

The ANN network is also capable of learning input/output and inverse relationships. Hence it is useful in building Internal Model Control (IMC) systems based on ANN-constructed plant models and their inverses. In a neural controller (Figure 2), the ANN can be used in calculating the control signal.

#### **Herding Control**

When a large number of variables is involved, model free herding control can be considered. This approach to control can be compared to the herding of sheep, where the shepherd's dog goes after one animal at a time and changes the direction or speed of the whole herd by always influencing the behavior of the least cooperative sheep.

I have successfully applied such herding algorithms in designing the controls of the IBM headquarters building in New York City. By herding the warm air to the perimeter (offices with windows) from the offices that are heat generators even in the winter (interior offices), the building became self-heating. This was done by changing the destination of the return air from one "hot" office at a time (the one that was the warmest in the building) and simultaneously opening the supply damper of the "coldest office" to that same header.

I have also applied the herding algorithm to optimize the process of computer chip manufacturing by eliminating the minute pressure differences that can cause dust-transporting drafts, which in turn can ruin the chips.

In general, herding control is effective if thousands of manipulated variables exist and they all serve some common goal.

#### **Common-Sense Recommendations**

While evaluating and executing such sophisticated concepts as optimized multivariable control, the ACE engineer's best friend is common sense and our most trusted teacher is still Murphy, who says that anything that can go wrong, will. In order to emphasize the importance of common sense, I will list here some practical recommendations:

- Before one can control a process, one must fully understand it.
- Being progressive is good, but being a guinea pig is not. Therefore, if the wrong control strategy is implemented, the performance of even the latest digital hardware will be unacceptable.
- An ACE engineer is doing a good job by telling plant management what they need to know and not what they like to hear.
- Increased safety is gained through backup. In case of measurement, reliability is increased by the use of multiple sensors, which are configured through median selectors or voting systems.
- If an instrument is worth installing, it should also be worth calibrating and maintaining. No device can outperform the reference against which it was calibrated.
- All man-made sensors detect relative values, and therefore the error contribution of references and compensators must always be included in the total error.
- Sensors with errors expressed as percent of the actual reading are preferred over those with percent of fullscale errors. If the actual percent of reading error increases as the reading moves down-scale, the loop performance will also deteriorate.
- It is easier to drive within the limits of a lane than to follow a single line. Similarly, control is easier and more stable if the single set point is replaced by a control gap.
- Process variables should be allowed to float within their safe limits as they follow the load. Constancy is the enemy of efficiency. Optimization requires efficient adaptation to changing conditions.
- Trust your common sense, not the sales literature.
   Independent performance evaluation based on the recommendations of international and national users' associations (SIREP-WIB) should be done before installation, not after it. The right time for "business lunches" is after start-up, not before the issue of the purchase order.
- Annunciators do not correct emergencies; they just throw those problems that the designers did not know how to handle into the laps of the operators. The smaller the annunciator, the better the design.

#### **FUTURE NEEDS**

I have already mentioned such needs as the establishment of our professional identity as automation and control engineers (ACE) or the need to integrate DCS, PLC, and PC hardware into a new digital control system (DCS+) that incorporates the features of all three. I have also briefly mentioned the need for bringing order into our "digital Babel" and to stop the trend toward software outsourcing (selling DCS systems without some software packages), which is like selling violins without the strings.

I would not be surprised if, by the end of the 21st century, we would be using self-teaching computers. These devices would mimic the processes taking place in our children's brains, the processes that allow babies to grow into Einsteins by learning about their environment. These devices would be watching the operation of a refinery or the landing and takeoff of airplanes and eventually would obtain as much knowledge as an experienced operator or pilot would have.

If this comes to pass, some might argue that this would be a step forward because machines do not forget; do not get tired, angry, or sleepy; and do not neglect their job to watch a baseball game or to argue with their spouse on the phone. This might be so, yet I would still prefer to land in a human-piloted airplane. I feel that way because I respect Murphy more than most scientists and I know that he is right in stating that "anything that can happen, will." For this reason, the knowledge of the past, which is the knowledge of the computer, might still not be enough.

In addition to new control tools, we will also have new processes to control. Probably the most important among these will be the fuel cell. The fuel cell is like a battery, except that it does not need recharging because its energy is the chemical energy of hydrogen, and hydrogen can come from an inexhaustible source, namely water. In order to gain the benefits of tripling the tank-to-wheel efficiency of our transportation systems while stopping global warming, we will have to learn to control this new process. The challenge involves not only the control of the electrolytic process that splits the water by the use of solar energy, but also the generation, storage, and transportation of liquid or slurry hydrogen.

As I was editing this reference set for the fourth time, I could not help but note the new needs of the process control industry, which are the consequences of the evolution of new hardware, new software, and new process technologies. Here, in the paragraphs that follow, I will describe in more detail what I hope our profession will accomplish in the next decade.

#### **Bringing Order to the "Digital Babel"**

In earlier decades, it took time and effort to reach agreement on the 3- to 15-PSIG (0.2- to 1.0-bar) pneumatic and later on the 4- to 20-mA DC standard current signal range. Yet when these signal ranges were finally agreed upon, the benefit was universal because the same percentage of full scale

measurement was represented by the same reading on every device in the world.

Similarly, the time is ripe for a single worldwide standard for all digital I/O ranges and *digital communication protocols*. The time is ripe for such an internationally accepted digital protocol to link all the digital "black boxes" and to eliminate the need for all interfacing.

By so doing, we could save the time and effort that are being spent on figuring out ways to interconnect black boxes and could invest them in more valuable tasks, such as enhancing the productivity and safety of our processing industries.

#### **Networks and Buses**

Protocol is the language spoken by our digital systems. Unfortunately, there is no standard that allows all field devices to communicate in a common language. Therefore the creation and universal acceptance of a standard field bus is long overdue.

There is nothing wrong with, say, the Canadians having two official languages, but there is something wrong if a pilot does not speak the language of the control tower or if two black boxes in a refinery do not speak the same language. Yet the commercial goal of manufacturers to create captive markets resulted in some eight protocols. These control-oriented communication systems are supported by user groups, which maintain Internet sites as listed below:

AS-Interface	www.as-interface.com
DeviceNet	www.odva.org
HART	www.hartcomm.org
PROFIBUS	www.profibus.org
Found. Fieldbus	www.fieldbus.org
OPC Foundation	www.opcfoundation.com
WorldFIP	www.worldfip.org
ControlNet	www.controlnet.com
MODBUS	www.modbus.org
Ethernet TCP/IP*	www.industrialethernet.com

\*TCP - Transmission control protocol

During the last decade, HART has become the standard for interfacing with analog systems, while Ethernet was handling most office solutions. SCADA served to combine field and control data to provide the operator with an overall view of the plant. While there was no common DCS fieldbus protocol, all protocols used Ethernet at the physical and TCP/IP at the Internet layer. MODBUS TCP was used to interface the different DCS protocols.

The layers of the communication pyramid were defined several ways. OSI defined it in seven (7) layers, #1 being the physical and #7 the application layer (with #8 being used for the "unintegrated," external components). The IEC-61512 standard also lists seven levels, but it bases its levels on

IP - Internet protocol

physical size: (1) control module, (2) equipment, (3) unit, (4) process cell, (5) area, (6) site, and (7) enterprise.

As I noted earlier, in the everyday language of process control, the automation pyramid consists of four layers: #1 is the level of the field devices, the sensors and actuators; #2 is control; #3 is plant operations; and #4 is the level of business administration.

Naturally, it is hoped that in the next decade, uniform international standards will replace our digital Babel, so that we once again can concentrate on controlling our processes instead of protecting our plants from blowing up because somebody used the wrong interface card.

#### **Software Outsourcing**

Another problem in the last decade was the practice of some DCS vendors to sell their "violins without strings," to bid their packages without including all the software that is needed to operate them.

To treat software as an extra and not to include the preparation of the unique control algorithms, faceplates, and graphic displays in the basic bid can lead to serious problems. If the plant does not hire an engineering firm or system integrator to put these strings onto the DCS violin, the plant personnel usually cannot properly do it and the "control music" produced will reflect that. In such cases the cost of plugging the software holes can exceed the total hardware cost of the system.

The cause of another recurring problem is that the instructions are often written in "computerese."

In some bids, one might also read that the stated cost is for "hardware with software license." This to some will suggest that the operating software for the DCS package is included. Well, in many cases it is not; only its license is.

Similarly, when one reads that an analyzer or an optimization or simulation package needs "layering" or is in the "8th layer," one might think that the bid contains eight layers of fully integrated devices. Well, what this language often means is that the cost of integrating these packages into the overall control system is an extra.

So, on the one hand, this age of plantwide digital networks and their associated advanced controls has opened the door for the great opportunities provided by optimization. On the other hand much more is needed before the pieces of the digital puzzle will conveniently fit together, before these "stringless violinists" can be integrated into a good orchestra of automation.

#### **Connectivity and Integration**

Utilizing our digital buses, one can plug in a PC laptop or use a wireless hand tool and instantly access all the data, displays, and intelligence that reside anywhere in a DCS network. This capability, in combination with the ability for self-tuning, self-diagnosing, and optimizing, makes the startup, operation, and maintenance of our plants much more efficient.

The modern control systems of most newly built plants consist of four levels of automation. In the field are the intelligent and self-diagnosing local instruments (sensors, valves, motors, safety devices). This first level is connected by a number of data highways or network buses to the next level in this automation pyramid, the level of control. The third level is plant operations, and the fourth is the enterprisewide business level.

The functions of the DCS workstations include control/ operation, engineering/historian, and maintenance functions, while the enterprise-wide network serves the business functions. In addition, wireless hand tools are used by the roving operators, and external PCs are available to engineers for their process modeling and simulation purposes.

#### HARDWARE-RELATED IMPROVEMENTS NEEDED

I will discuss below some of the areas in which the next decade should bring improvements in the quality and intelligence of the components that make up our control systems. I will discuss the need for better testing and performance standards and the improvements needed in the sensors, analyzers, transmitters, and control valves. I will place particular emphasis on the potentials of "smart" devices.

#### **Meaningful Performance Standards**

The professional organizations of automation and control engineers (ACE) should do more to rein in the commercial interests of manufacturers and to impose uniform performance testing criteria throughout the industry. In the sales literature today, the meanings of performance-related terms such as inaccuracy, repeatability, or rangeability are rarely based on testing, and test references are rarely defined. Even such terms as "inaccuracy" are frequently misstated as "accuracy," or in other cases the error percentages are given without stating whether they are based on full scale or on actual readings. It is also time for professional societies and testing laboratories to widely distribute their findings so that these reliable third-party test results can be used by our profession to compare the performance of the various manufacturers' products.

We the users should also require that the manufacturers always state not only the inaccuracy of their products but also the rangeability over which that inaccuracy statement is valid. In other words, the rangeability of all sensors should be defined as the ratio between those maximum and minimum readings for which the inaccuracy statement is still valid.

It would also be desirable to base the inaccuracy statements on the performance of at least 95% of the sensors tested and to include in the inaccuracy statement not only linearity, hysteresis, and repeatability but also the effects of drift, ambient temperature, over-range, supply voltage variation, humidity, radio frequency interface (RFI), and vibration.

#### **Better Valves**

In the next decade, much improvement is expected in the area of final control elements, including smart control valves.

This is because the performance of the control loop is much affected not only by trim wear in control valves but also by stem sticking caused by packing friction, valve hysteresis, and air leakage in the actuator. The stability of the control loop also depends on the gain of the valve during the tuning of the loop.

In order for a control loop to be stable, the loop is tuned (the gain of the controller is adjusted) to make the gain product of the loop components to equal about 0.5. If the control valve is nonlinear (its gain varies with the valve's opening), the loop will become unstable when the valve moves away from the opening where it was when the loop was tuned. For this reason, the loop must be compensated for the gain characteristics of the valve; such compensation is possible only if the valve characteristics are accurately known.

For the above reasons, it is desirable that the users and the professional societies of ACE engineers put pressure on the manufacturers to accurately determine the characteristics of their valves. The other performance capabilities of the final control elements also need to be more uniformly defined. This is particularly true for the rangeability of control valves. For example, a valve should be called linear only if its gain (Gv) equals the maximum flow through the valve (Fmax) divided by the valve stroke in percentage (100%) throughout its stroke.

The valve manufacturers should also be required to publish the stroking range (minimum and maximum percentages of valve openings) within which the valve gain is what it is claimed to be (for a linear valve it is Fmax/100%). Similarly, valve rangeability should be defined as the ratio of the minimum and maximum valve Cvs, at which the valve characteristic is still what it is specified to be.

#### **Smarter Valves**

A traditional valve positioner serves only the purpose of maintaining a valve at its intended opening. Digital valve controllers, on the other hand, provide the ability to collect and analyze data about valve position, valve operating characteristics, and valve performance trending. They also provide two-way digital communication to enable diagnostics of the entire valve assembly and instrument. Section 6.12 in this handbook and the following Web pages provide more information: Metso Automation (http://www.metsoautomation.com/), (http://www.emersonprocess.com/fisher/products/fieldvue/dvc/index.html)

The potentials of smart valves are likely to be further increased and better appreciated in the next decade. The main features of a smart valve include its ability to measure its own:

- Upstream pressure
- Downstream pressure
- Temperature
- · Valve opening position
- Actuator air pressure

Smart valves will also eliminate the errors introduced by digital-to-analog and analog-to-digital conversions and will guarantee the updating of their inputs about 10 times per second. In addition, they will be provided with the filters required to remove the errors caused by turbulence in these readings. As a consequence, smart valves will also be able to measure the flow, by solving equations, such as the one below for liquid flow:

$$Q = \frac{C_{v}}{\sqrt{\frac{SPGRAV}{\Delta P_{A}}}}$$

where

Q = Flow rate (GPM)

 $F_L$  = Recovery coefficient

 $C_v$  = Flow capacity factor

 $P_1$  = Upstream pressure (PSIA)

 $P_{v}$  = Liquid vapor press (PSIA)

 $P_c$  = Critical pressure (PSIA)

 $\Delta P_A$  = Valve pressure drop (PSI) or

If Choked:

$$\Delta P_A = F_L^2 \left[ P_1 - \left( 0.96 - 0.28 \sqrt{\frac{P_V}{P_C}} \right) \right] P_V$$

The smart valves of the coming decade will hopefully not only measure their own flows but will also measure them over a rangeability that exceeds most flowmeters (from 25:1 to over 100:1) because they in effect are variable-opening orifices.

If the sensors of the intelligent control valve are connected to a PID chip mounted on the valve, the smart valve becomes a local control loop. In that case, only the operator's displays need to be provided remotely, in a location that is convenient for the operator. In such a configuration, it will be possible to remotely reconfigure/recalibrate the valve as well as to provide it with any limits on its travel or to diagnose stem sticking, trim wear, or any other changes that might warrant maintenance.

#### "Smarter" Transmitters, Sensors, and Analyzers

In the case of transmitters, the overall performance is largely defined by the internal reference used in the sensor. In many cases there is a need for multiple-range and multiple-reference units. For example, pressure transmitters should have both atmospheric and vacuum references and should have sufficient intelligence to automatically switch from one to the other on the basis of the pressure being measured.

Similarly, d/p flow transmitters should have multiple spans and should be provided with the intelligence to automatically switch their spans to match the actual flow as their measurement changes.

The addition of "intelligence" could also increase the amount of information that can be gained from such simple detectors as pitot tubes. If, for example, in addition to detecting

the difference between static and velocity pressures, the pitot tube was able to also measure the Reynolds number, it would be able to approximate the shape of the velocity profile. An "intelligent pitot tube" of such capability could increase the accuracy of volumetric flow measurements.

#### **Improved On-Line Analyzers**

In the area of continuous on-line analysis, further development is needed to extend the capabilities of probe-type analyzers. The needs include the changing of probe shapes to obtain self-cleaning or to improve the ease of cleaning by using "flat tips." The availability of automatic probe cleaners should also be increased and the probe that is automatically being cleaned should be made visible by the use of sight flow indicators, so that the operators can check the cleaner's effectiveness.

More and more analyzers should become self-calibrating, self-diagnosing, and modular in their design. In order to lower maintenance costs, analyzers should also be made more modular for ease of replacement and should be provided with the intelligence to identify their defective modules. The industry should also explore the use of multiple-probe fiber-optic analyzers with multiplexed shared electronics.

#### **Improving Operators' Displays**

The control rooms of the coming decades will be more operator-friendly and more enterprise-wide optimization oriented. The human-machine interfaces (HMIs) in the control rooms are only as good as the ability of the operators to use them.

The hand, the psychological characteristics, the hearing, and color discrimination capability of the human operator must all be part of the design. Even more importantly, the design should also consider the personality and education of the average operator. Therefore, a well-designed HMI is the operator's window on the process.

In past decades, the operator's window on the process was little more than the faceplate of an analog controller and an annunciator. Today, when a single operator is expected to oversee the operation of processes having hundreds if not thousands of variables, the operator must be provided with diagnostic, trend, and historical data in an easily understandable and familiar format.

For that purpose, it is advisable to provide in the control room a large display panel, on which (as one of the options) the operation of the whole plant can be displayed. Using that graphic flowsheet, the operator should have the ability to focus in on any unit operation of interest. As the operator focuses in on smaller and smaller sections of the plant, the information content of the display should increase. In the process of "focusing," the operator must be able to select subsystems, individual loops, or loop components, such as a single control valve. At each level of scale, the display should identify all abnormal conditions (by color and flashing),

while providing all the trend and status data for all related variables.

Another essential feature of modern control systems is their suitability for smooth growth of the plant. This capability is very important in process control because plants are ever expanding and therefore their control systems must also grow with the expansions. A modular approach to operator stations makes the expansion of the plant easier.

#### **Optimization and Advanced Controls**

In some ways we have already passed the age of the single-loop PID control. Yet in the coming decade much more improvement is expected both in multivariable unit operations control and in model-based optimization.

We all know that it is time to stop controlling flows, pressures, and temperatures and to start controlling and optimizing pumping stations, boilers, and chemical reactors. In the next decade, hopefully we will see the development of the universal software package for the various unit operations that can be adapted to specific plants just by the entering of design data for the particular process.

#### **Plant-Wide Modeling and Optimization**

In addition to its role in providing better control, process modeling and simulation can also improve the training of operators. If the simulation model is accurate and if it integrates the dynamics of the process with that of its control system, it can be used to train operators for plant startup without risking the consequences of their inexperience. Needless to say, the building of good models is expensive, but once prepared, they are very valuable.

Business- or enterprise-wide optimization includes the model of not only the manufacturing process, but also the optimization of the raw material supply chain and of the packaging and product distribution chain. This is a higher and more important level of optimization because it requires the simultaneous consideration of all areas of optimization and the finding of enterprise-wide operation strategies, which will keep all areas within their optimum areas of operation.

Plant-wide optimization also involves more than the optimization of the unit processes because it must also consider documentation, maintenance, production scheduling, and quality management considerations. Plant-wide optimization requires the resolution of the conflicting objectives of the operations and strategies.

Naturally, it should be kept in mind that modeling and optimization can only be achieved when the control loops are correctly tuned, the measurements are sampled fast enough, and interactions between loops have been eliminated.

#### **Efficiency and Productivity Controllers**

This handbook already describes a large number of methods to increase the efficiency of unit operations. For example, in the section describing the methods of pumping station optimization, it is pointed out that the lifetime operating cost of a pumping station is about a *hundred times higher than its initial cost*. The returns on the optimization of other unit operations are similar, although not that high. It is for this reason that in the coming decade, optimization is expected to increase.

When using multivariable envelopes for unit operation optimization, the individual variables of levels, pressures, and temperatures become only constraints, while the overall goal is to maximize the efficiency or productivity of the controlled process. New software packages are needed to "educate" and give "personality" to today's multivariable controllers to transform these general-purpose units into chemical reactor, distillation tower, compressor, or any other type of unit operation controllers.

#### **Unit Operation Controllers of the Future**

The next decade could bring a building-block approach to control systems. In this approach all "empty boxes" could be very similar, so that a unit operations controller that was, say, to optimize a dryer, could be converted to control an evaporator or a pumping station just by loading into it a different software package and connecting a different set of I/Os. Once the particular software package was loaded, the unit controller would be customized by a menu-driven adapter package, organized in a question-and-answer format.

During the customization phase, the user would answer questions on piping configuration, equipment sizes, material or heat balances, and the like. Such customization software packages could not only automatically configure and tune the individual loops but could also make the required relative gain calculations to minimize the interaction among them.

#### **HISTORY OF THE HANDBOOK**

The birth of this handbook was connected to my own work: In 1962—at the age of 26—I became the Chief Instrument Engineer at Crawford & Russell, an engineering design firm specializing in the building of plastics plants. C&R was growing and with it the size of my department also increased. Yet, at the age of 26 I did not dare to hire experienced people because I did not feel secure enough to lead and supervise older engineers.

So I hired fresh graduates from the best engineering schools in the country. I picked the smartest graduates and I obtained permission from C&R's president, Sam Russell, to spend every Friday afternoon teaching them. In a few years C&R not only had some outstanding process control engineers but had them at relatively low salaries.

By the time I reached 30, I felt secure enough to stop disguising my youth. So I shaved off my beard and threw away my phony, thick-rimmed eyeglasses, but my Friday's notes remained. They still stood in a 2-foot-tall pile on the corner of my desk.

#### "Does Your Profession Have a Handbook?"

In the mid-1960s an old-fashioned Dutch gentleman named Nick Groonevelt visited my office and asked: "What is that pile of notes?" When I told him, he asked: "Does your profession have a handbook?" "If it did, would I bother to prepare all these notes?" I answered with my own question. (Actually, I was wrong in giving that answer, because Behar's *Handbook of Measurement and Control* was already available, but I did not know about it.) "So," Nick proposed, "let me publish your notes and then the instrument engineers will have a handbook!" In 1968 the first edition of the *Instrument Engineers' Handbook (IEH)* was published.

In 1968, the Soviet tanks—which I fought in 1956 in Budapest—were besieging Prague, so I decided to dedicate the three volumes of the *IEH* to the Hungarian and Czech freedom-fighters. A fellow Hungarian-American, Edward Teller, wrote the preface to the first edition; Frank Ryan—the editor of *ISA Journal*—wrote the introduction. Because of the publication of the first edition of the *IEH*, in 1973 I was elected the youngest ISA fellow ever.

#### **Later Editions**

By the end of the 1970s the world of process control had changed. Pneumatics were on the way out, and new solutions like DCS control and on-line analyzers proliferated. It was time to revise the handbook. The second edition was published in 1985. It was well received.

By the mid-1990s the handbook was ready for another updated edition. By that time the process control market was becoming globalized, "smart" instruments had evolved, and such hardware inventions as fiber-optic probes and throttling solenoid valves proliferated. So I stopped teaching at Yale, cut back on consulting, and prepared the third edition. In this edition I also added a third volume to the two-volume set to cover all the evolving digital software packages, communication networks, buses, and optimization packages.

Work on the fourth edition of the *IEH* started in the new millenium, and the first volume on measurement and analysis was published in 2003. The second volume is in your hands now.

During the nearly four decades of its existence, the *Instrument Engineers' Handbook (IEH)* has become the most widely used reference source for the automation and control (ACE) engineering profession. During this period, our experience and our knowledge of control principles have penetrated all the fields of modern science and technology. I hope that the three volumes of the *IEH* will continue to play a major role in spreading this knowledge and understanding.

#### The Contents of the IEH Volumes

In 1968, this handbook started out as a two-volume reference set and, in that respect, it has not changed. The first volume still deals with measurement, the second with control. What is new is that the third volume deals with digital networks and software systems.

This fourth edition updates the information content of the previously published sections, incorporates the new developments of the last decade, and broadens the horizons of the work from an American to a global perspective. In the first volume, one chapter was devoted to each major measured variable including the detection of flow, level, temperature, pressure, density, viscosity, weight, composition, and safety sensors. Each subchapter (section) was devoted to the discussion of a different method of making that measurement.

This second volume of the *IEH* deals with process control and covers both control hardware and control strategies. The hardware discussed includes transmitters, controllers, control valves, and displays, including the design of control rooms. The chapters on control systems provide in-depth coverage both of the theory of control and of the unit processes of pumping, distillation, chemical reaction, heat transfer, and many others. The individual sections (subchapters) begin with a flowsheet symbol and if the subject matter is a hardware item, start with a feature summary.

This summary provides quick access to specific information on the available sizes, suppliers, ranges, and inaccuracies of the devices covered in that section. The reader is advised to turn to the section of interest and, based on the information in the feature summaries, decide whether the costs, inaccuracies, and other characteristics meet the requirements of the particular application.

We know that there is no greater resource than the combined knowledge and professional dedication of a well-educated new generation. We live in an age when technology can make the difference in overcoming the social and environmental ills on this planet. We live in an age when an inexhaustible and nonpolluting energy technology must be developed. It is hoped that this handbook will make a contribution toward these goals and in addition will also improve the professional standing of automation and control engineers around the world.

Béla Lipták Stamford, Connecticutt (liptakbelaieh4@aol.com)

# **DEFINITIONS**

Absolute (Dynamic) Viscosity (μ) Absorbance (A) Constant of proportionality between applied stress and resulting shear velocity (Newton's hypothesis).

Ratio of radiant energy absorbed by a body to the corresponding absorption of a blackbody at the same temperature. Absorbance equals emittance on bodies whose temperature is not changing. (A = 1 - R - T), where R is the reflectance and T is the transmittance.)

Absorption

The taking in of a fluid to fill the cav-

ities in a solid.

Accumulation

In safety and relief valve terminology, accumulation is the pressure increase over the maximum allowable working pressure of a tank or vessel during discharge through the pressure relief valve. It is given either in percentage of the maximum allowable working pressure or in pressure units such as pounds per square inch or in bars.

**Accuracy** 

See **Inaccuracy**, which is the term used

in this handbook.

Adaptive Control Admittance (A)

See Control, Adaptive

The reciprocal of the impedance of a circuit. The admittance of an AC circuit is analogous to the conductance of a DC circuit. (Units: siemens.)

Adsorption

The adhesion of a fluid in extremely thin layers to the surfaces of a solid. A signal designed to alert, inform, guide,

Alarm

or confirm deviations from acceptable

system status.

Alpha Curve

In resistance bulb terminology, it is the relationship of the resistance change of an RTD vs. temperature. In European alpha curves, the alpha value is 0.00385 ohms per degree C, while in American curves it is 0.00392.

**Ampacity** 

The current (amperes) a conducting system can support without exceeding

Amperometric Titration

**Amperometry** 

the temperature rating assigned to its configuration and application.

Titration in which the end point is determined by measuring the current (amperage) that passes through

The process of performing an amperometric titration. The current flow is monitored as a function of time between working and auxiliary electrodes while the voltage difference between them is held constant; in other designs, the current is monitored as a function of the amount of reagent added to bring about titration of an analyte to the stoichiometrically defined end point. Also called constant potential voltametry.

**Amplifier** 

**Apparent** 

**Approach** 

Viscosity

A device that enables an input signal to control a signal source independent of the signal and is thus capable of delivering an output that is related to and is greater than the input signal.

Viscosity of a non-Newtonian fluid under given conditions. Same as consistency. The different between the wet-bulb temperature of the ambient air and the water temperature leaving a cooling tower. The approach is a function of cooling tower capacity; a large cooling tower will produce a closer approach (colder leaving water) for a given heat load, flow rate, and entering air condition. (Units: °F or °C.)

Artificial Neural Networks (ANNs) An ANN can learn complex functional relations by generalizing from a limited amount of training data; hence, it can thus serve as black-box model of nonlinear, multivariable static and dynamic systems and can be trained by the inputoutput data of these systems. ANNs attempt to mimic the structures and processes of biological neural systems.

They provide powerful analysis properties such as complex processing of large input/output information arrays, representing complicated nonlinear associations among data, and the ability to generalize or form concepts-theory. Attenuation Loss of communication signal strength. **Auto-Manual** A device that enables an operator to Station select either the output of a controller or a manually generated signal. Backlash In mechanical devices, it is the relative movement between interacting parts that results from the looseness of these parts when motion is reversed. **Backplane** Physical connection between individual components and the data and power distribution buses inside a chassis. In relief and safety valve terminology, **Backpressure** it is the pressure on the discharge side of a pressure relief valve. This pressure is the sum of the superimposed and the built-up backpressures. The superimposed backpressure is the pressure that exists in the discharge piping of the relief valve when the valve is closed. Balanced A safety relief valve with the bonnet Safety Relief Valve

vented to atmosphere. The effect of backpressure on the performance characteristics of the valve (set pressure, blow-down, and capacity) is much less than on a conventional valve. The balanced safety relief valve is made in three designs: (1) with a balancing piston, (2) with a balancing bellows, and (3) with a balancing bellows and an auxiliary balancing piston.

**Balling Degrees** Balun (Balanced/ Unbalanced)

Unit of specific gravity used in the brewing and sugar industries.

A device used for matching characteristics between a balanced and an unbalanced medium.

**Band Pass** Filter

An optical or detector filter that permits the passage of a narrow band of the total spectrum. It excludes or is opaque to all other wavelengths.

Bandwidth

Data carrying capacity, the range of frequencies available for signals. The term is also used to describe the rated throughput capacity of a given network medium or protocol.

**Barkometer Degrees Baseband** 

Unit of specific gravity used in the tanning industry.

A communication technique where only one carrier frequency is used to send one signal at a time. Ethernet is an example of a baseband network.

Also called narrow-band. Contrast with

Broadband.

**Basic Control** 

Continuously executed algorithms that drive the process or equipment to a specified state and keep it there, such as indicators, regulatory and device controls, and interlocks.

Batch

A quantity of material produced by the single execution of a batch process. A batch also refers to the intermediate materials during the manufacturing

Baumé Degree

A unit of specific gravity used in the acid and syrup industry. The area between two bents of lines of

Bay

Bent

framing members; usually longitudinal. A line of structural framework composed of columns or ties; a bent may incorporate diagonal bracing members;

usually transverse.

Blackbody

The perfect absorber of all radiant energy that strikes it. A blackbody is also a perfect emitter. Therefore, both its absorbance and emissivity (E) are unity. A blackbody radiates energy in predictable spectral distributions and intensities, which are a function of the blackbody's absolute temperature.

Black Box Model Blowdown

See Empirical Model.

In case of cooling towers, it is the water discharged to control the concentration of impurities in circulated water. (Units: percentage of circulation rate.)

Blowdown (Blowback) In relief valves, it is the difference between the set pressure and the reseating (closing) pressure of a pressure relief valve, expressed in percent of the set pressure, in bars, or in pounds per square inch.

**Bode Diagram** 

A plot of the logarithm of gain or magnitude ratio and a plot of the logarithm of phase angles against the logarithm of frequency for a transfer function.

**Boiling Point Rise** 

This term expresses the difference (usually in °F) between the boiling point of a constant composition solution and the boiling point of pure water at the same pressure. For example, pure water boils at 212°F (100°C) at 1 atmosphere, and a 35% sodium hydroxide solution boils at about 250°F (121°C) at 1 atmosphere. The boiling point rise is therefore 38°F (21°C). In a Dühring plot, the boiling point of a given composition solution is plotted as a function of the boiling point of pure water.

**Calibration Cycle** 

Calibration

Campaign

**Capacitor** 

Traceability

Capacitance (C)

**Cascade Control** 

Characteristic

Chatter

**Impedance** 

Chronopotenti-

**Closing Pressure** 

Coax

**Co-Current** 

Operation

ometry

**Bolometer** Thermal detector that changes its electrical resistance as a function of the radiant energy striking it. The practice of creating safe, high **Bonding** capacity, reliable electrical connectivity between associated metallic parts, machines, and other conductive equipment. **Brightness** A device that uses the radiant energy **Pyrometer** on each side of a fixed wavelength of the spectrum. This band is quite narrow and usually centered at 0.65 microns in the orange-red area of the visible spectrum. **British Thermal** The amount of heat required to raise the Unit (BTU) temperature of one pound of water by one degree Fahrenheit at or near 60° Fahrenheit. **Brix Degree** A specific gravity unit used in the sugar industry. **Broadband** A communication technique that multiplexes multiple independent signals simultaneously, using several distinct carriers. A common term in the telecommunication industry to describe any channel having a bandwidth greater than that of a voice-grade channel (4 kHz). Also called wideband. Contrast with Baseband. BTU "Dry" The heating value of a gas expressed on a "dry basis." The common assumption is that pipeline gas contains 7 pounds (or less) of water vapor per million standard cubic feet. BTU "Saturated" The heating value of a gas expressed on the basis that the gas is saturated with water vapor. This state is defined as the condition when the gas contains the maximum amount of water vapor without condensation, when it is at base pressure and 60°F. **Bubble Point** The temperature at which a mixture of liquids first starts to boil. Built-Up In connection with safety relief valves, **Backpressure** the variable backpressure that develops as a result of flow through the pressure relief valve after it opens. This is an increase in pressure in the relief valve's outlet line caused by the pressure drop through the discharge headers. **Burning** In combustion-related terminology, burning is when the flame does not spread or diffuse but remains at an interface where fuel and oxidant are supplied in proper proportions. Calibrate To ascertain the outputs of a device cor-

responding to a series of input values

that the device is to receive, measure, or transmit. The application of known values as inputs to a device and the registering of the corresponding output readings over the range of that device, in both ascending and descending directions. The relationship of the calibration of an instrument to that of one or more instruments calibrated and certified by a national standardizing laboratory. The total production run of one product, for example, for a single order or season, consisting of one or more lots. The amount of charge, in coulombs, stored in a system necessary to raise the potential difference across it 1 volt; represented by the SI unit farad. Device consisting of two conductors electrically isolated by an insulator. The conductors are called plates, and the insulator is referred to as the dielectric. The larger the capacitor, the smaller its impedance, and the more AC current will flow through it. See Control, Cascade. The impedance that, when connected to the output terminals of a transmission line appear to be infinitely long, for there are no standing waves on the line, and the ratio of voltage to current is the same for each point of the line [nominal impedance of wave-guide]. Rapid, abnormal reciprocating variations in lift during which the disc contacts the seat. When the potential difference between a metallic measuring electrode and a reference electrode is monitored as a function of time. At the measuring electrode an oxidation or reduction of a solution species is taking place. In relief and safety valve terminology, (Reseat Pressure) the pressure, measured at the valve inlet, at which the valve closes, flow is substantially shut off, and there is no measurable lift. Jargon meaning "coaxial cable," consisting of a center wire surrounded by low K insulation, surrounded by a second shield conductor. It has low capacitance and inductance for transmission of high-frequency current. The process feed and steam (or other utility fluid) follow parallel paths through

such processes as an evaporator train.

Countercurrent **Operation Cold Differential Test Pressure** (CDTP)

The feed and steam enter the evaporator train at opposite ends.

The pressure at which the PRV is adjusted to open during testing. The CDTP setting includes the corrections required to consider the expected service temperature and backpressure.

**Cold Junction Combustion Air** Requirement Index (CARI) See Reference Junction.

This dimensionless number indicates the amount of air required (stoichiometrically) to support the combustion of a fuel gas. Mathematically the Combustion Air Requirement Index is defined by the equation below:

$$CARI = \frac{Air/Fuel\ Ratio}{\sqrt{SG}}$$

**Common Mode** Interference **Common Mode** Rejection **Common Mode** Voltage

See Interference, Common Mode.

The ability of a circuit to discriminate against a common mode voltage.

A voltage of the same polarity relative to ground on both sides of a differential input.

Common Resource An equipment entity that services more than one unit, either simultaneously (shared-use resource) or one at a time (exclusive-use resource).

Compliance Conductance (G) The reciprocal of stiffness.

The reciprocal of resistance. (Units: Siemens [formerly "mhos"].)

Conductivity (g)

The reciprocal of resistivity. All solids and liquids have some degree of conductivity. For the purpose of this section, any material above 1 micro Siemen/cm will be considered to be conductive (this includes most metals and water with any ions).

**Conformity** 

The degree or closeness to which one curve approximates another curve. Conformity can be expressed as independent, terminal based, or zero based. Independent conformity is obtained when the calibration curve is so positioned as to minimize the maximum deviation between it and the specified curve. Terminal-based conformity is obtained when the two curves are so positioned that their readings coincide at zero and full span. Zero-based conformity is when they coincide only at zero. In terms of viscosity, the resistance of a substance to deformation. It is the Constant **Backpressure**  same as viscosity for a Newtonian fluid and the same as apparent viscosity for a non-Newtonian fluid.

In connection with safety relief valves, the backpressure that does not change under any condition of operation, whether the pressure relief valve is closed or open.

**Control Action** 

For a controller, the nature of the change in the output of the controller, which is affected by the controller's input.

Control Action, **Derivative** (**Rate**) (**D**) Control Action, **Integral** (Reset) (I)

A control action in which the controller output is proportional to the rate of change of the input.

A control action in which the controller output is proportional to the time integral of the input. In this case the rate of change of the controller output is proportional to the input.

Control Action. Proportional (P)

A control action in which there is a continuous linear relationship between the controller's output and its input.

Control, Cascade

Control configuration in which the output of one controller (the "master") is the set point of another controller (the "slave").

Control.

Control in which the output of the con-Differential Gap troller remains at a minimum or maximum value until the controlled variable reaches the top limit of a band or gap, at which point the output reverses and stays in that state until the controlled variable crosses the bottom limit of the gap. At that point, the controller output returns to its original condition.

Control, Feedback Control in which a measurement is compared to a set point to produce an error signal. This error is acted upon in such a way as to reduce the magnitude of the error.

Control, Feedforward Control in which one or more conditions that are outside the feedback loop and have an influence on the controlled variable are converted into some corrective action in order to minimize the deviations from the set point of the controlled variable.

**Control Horizon** 

Controlled Variable Controller. **Direct Acting**  The number of future manipulated variable moves that are taken into account in developing the optimal MPC solution. The variable that is detected to originate the feedback signal for the controller. A controller that increases its output signal when its measured variable (input signal) increases.

Consistency

Controller, On-Off

A two-position controller, of which one of the two discrete output signal values

Controller, **Program** Controller, Ratio A controller that automatically adjusts its set point to follow a prescribed program. A controller that maintains a predetermined ratio between two variables.

Acting

**Controller, Reverse** A controller that decreases its output signal as the value of its measured variable (input signal) increases.

Controller, Sampling A controller using intermittent readings of the controlled variable (error or set point) to affect control action.

Controller, Self-**Operated** (Regulator)

A controller that derives the required energy for its operation from the system that it controls.

Controller, Time Schedule

A controller in which the set point (or the reference-input signal) automatically follows some predetermined time schedule.

**Control Module** 

A set of equipment and functions that can carry out basic control. For example, a control loop consisting of one or more sensors, actuators, and control functions is a control module. It is also the lowestlevel equipment grouping that acts as a single entity from a control standpoint, but cannot execute procedural elements. May be an individual measurement (with suitable signal conditioning or state names) or a grouping of directly coupled actuators with their associated measurements, alarms, and control actions, including subordinate Control Modules as appropriate. Examples are an uncontrolled temperature, a flow control loop, an automatic block valve with limit switches, or a header containing interlocked (mutually exclusive) block

Control, **Optimizing**  Control that does not hold the controlled variable constant but seeks and maintains a value of the controlled variable that will result in the most advantageous operation of the process.

**Control Recipe** 

Control.

An equipment-specific recipe that defines the production of a single batch. It is usually derived from a master recipe. Control in which a supervisory controlled periodically applies some corrective action, such as set point changes, to a number of controllers.

Control System, Multi-Variable

**Supervisory** 

A control system that uses two or more process variable measurement signals to affect control.

Control, Time **Proportioning** 

Control in which the outputs are periodic pulses whose duration is varied in relation to the actuating error signal.

Control, Velocity Limiting

Control in which the rate of change of some variable is prevented from exceeding a predetermined limit.

Conventional Safety Relief Valve

A safety relief valve with the bonnet vented either to atmosphere or internally to the discharge side of the valve. The performance characteristics (set pressure, blow-down, and capacity) are directly affected by changes of the backpressure on the valve.

Coordination Control

Control functions existing at multiple levels to schedule batches and manage recipes, procedural control execution, equipment entity allocation, and batch

**Corner Frequency** 

In the asymptotic form of the Bode diagram, that frequency that is indicated by a break point. It is the junction of two confluent straight lines asymptotic to the log gain curve.

**Coulometry** 

A process of monitoring analyte concentration by detecting the total amount of electrical charge passed between two electrodes that are held at constant potential or when constant current flow passes between them.

Countercurrent **Operation** 

The process feed and steam (or other utility fluid) enter at opposite ends as they flow through such processes as an evaporator train.

A cooling tower in which the airflow is in

Counterflow **Cooling Tower** 

(Chlorinated

**CPVC** 

the opposite direction from the fall of water through the water cooling tower. A low cost, reasonably inert polymer used for some noninsertion sensors. It is easily solvent-welded. The max temperature range is about 225°F.

Chloride) **Cross-Flow Cooling Tower** 

**Polyvinyl** 

A cooling tower in which airflow through the fill is perpendicular to the plane of the falling water.

Crystallography

How the atoms are arranged in the object; a direct relation exists between these arrangements and materials properties (conductivity, electrical properties, strength, etc.).

Curie (Ci)

A unit of radiation source size, corresponding to 37 billion disintegrations per second.

The progressive reduction or suppres-

**Damping** 

sion of oscillation in a device or system. In the case of the free oscillation of a second-order linear system, it is the

**Damping Factor** 

ratio of the greater by the lesser of a Dielectric A scheme by which changes in insulatpair of consecutive swings of the output ing liquid composition or temperature Compensation in opposite directions (without sign) can be prevented from causing any output about an ultimate steady-state value. error. It requires a second sensor and **Data Servers** A standard interface to provide data homogeneous liquid. exchange between field devices and data Dielectric A unit expressing the relative charge storage capability of various insulators. clients. Constant Deadband The range through which an input can Full vacuum is defined as 1.0, and all gases are indistinguishable from each be varied without causing an observable change in the output. Deadband is other for practical purposes. TFE has a the range through which the measurand dielectric constant of 2.0, cold water about 80. It has no units because it is may be varied by reversing direction without producing an observable the ratio of the dielectric constant of a response in the output signal. substance to that of vacuum. For the **Dead Time** dielectric values of selected materials See Time, Dead. Dead Zone See Zone, Dead. refer to Table 3.3p of the first volume **Deflagration or** A process where the flame front advancof this handbook. **Explosion** Diode es through a gaseous mixture at sub-A two-terminal electronic (usually semisonic speeds. conductor) device that permits current **Deionized Water** Water of extremely high purity, with flow predominantly in only one direction. few ions to carry current. If exposed to See Controller, Direct Acting. **Direct Acting** air for any significant period, it will Controller have a conductivity of about 5 micro **Discontinuity** An abrupt change in the shape [or Siemens/cm due to dissolved CO<sub>2</sub>. impedance] of a wave-guide [creating **Demultiplexing** Separating of multiple input streams a reflection of energy]. that were multiplexed into a common Distance/Velocity A delay attributable to the transport of physical signal back into multiple outmaterial or to the finite rate of propa-Lag put streams. gation of a signal. **Derivative Gain** See Gain, Derivative. Dither A useful oscillation of a small magnitude, **Derivative Time** See Time, Derivative. which is introduced to overcome the **Design Pressure** This pressure is equal to or less than effect of friction, hysteresis, or recorder the maximum allowable working prespen clogging. sure. It is used to define the upper Drift An undesired change in the output of a limit of the normal operating pressure device, which occurs over time and is unrelated to the input, the environment, **Detonation** A process where the advancement of the or the load. In the case of cooling towers flame front occurs at supersonic speeds. it is the water loss due to liquid droplets **Device** In digital systems, a clear and unamentrained in exhaust air. Usually under **Description** biguous, structured text description that 0.2% of circulated water flow rate. allows full utilization/operation of a **Drift Eliminator** (DD) An assembly constructed of wood or field device by a host/master without honeycomb materials that serves to remove entrained moisture from the any prior knowledge of the field device. **Device Description** In the Foundation fieldbus technology discharged air. Language (DDL) concept, it is the definition and de-Droop See Offset. scription of function blocks and their **Dry-Bulb** The temperature of air measured by a parameters. **Temperature** normal thermometer. **Dew Point** Saturation temperature of a gas-water (TDB) Dust-Ignition-Proof Enclosed in a manner to exclude ignitvapor mixture. **Dew Point** The temperature at which condensation able amounts of dust or amounts that **Temperature** begins if air is cooled under constant might affect performance. Enclosed so (DPT) pressure. that arcs, sparks, or heat otherwise gen-**Dielectric** A material that is an electrical insulator erated or liberated inside of the encloor in which an electric field can be sussure will not cause ignition of exterior tained with a minimum of dissipation of accumulations or atmospheric suspenpower. Dielectric materials include sions of dust.

**Dynamic Gain** 

See Gain, Dynamic.

metal-oxides, plastics, and hydrocarbons.

**Dynamic Matrix** 

A matrix built from step responses to predict the changes in the process output that result from the moves of the manipulated variable over the control horizon.

**Economy** 

In case of the evaporation process, this term is a measure of steam use and is expressed in pounds of vapor produced per pound of steam supplied to the evaporator train. For a well-designed evaporator system the economy will be about 10% less than the number of effects; thus, for a triple-effect evaporator the economy will be roughly 2.7. This is a coefficient used to calculate the minimum required discharge area of the PRV.

Effective Coefficient of Discharge Electrochemical

**Process** 

The changes in voltage or current flow that occur between two electrodes in a solution (electrolyte) over time. The oxidation or reduction of the analyte provides data that are related to concentration.

**Electrolytic Probe** 

Probe that is similar to a galvanic probe, except that a potential is applied across the electrodes and the electrodes are not consumed. Dissolved oxygen detection is a primary application of this type of probe.

Electromagnetic Wave (Energy)

A disturbance that propagates outward from any electric charge that oscillates or is accelerated; far from the charge it consists of vibrating electric and magnetic fields that move at the speed of light and are at right angles to each other and to the direction of motion.

Electron Microscope A scientific instrument that uses a beam of highly energetic electrons to examine objects on a very fine scale.

Element, Final Control The controlling element that directly changes the value of the manipulated variable. It can be a control valve, a damper, an electric power modulator, or a variable-speed pump.

**Element, Primary** 

The element that converts the measured variable into a form which can be measured.

Elevated Range, Elevation Elevation, Zero Emissivity or Emittance (E) See Range, Suppressed Zero.

See Zero Elevation.

The emissivity of an object is the ratio of radiant energy emitted by that object divided by the radiant energy that a blackbody would emit at that same temperature. If the emittance is the same at all wavelengths, the object is called a

gray body. Some industrial materials change their emissivity with temperature and sometimes with other variables also. Emissivity always equals absorption and it also equals 1 minus the sum of reflectance and transmittance:

$$(E = A = 1 - T - R)$$

**Empirical Model** 

This type of model can be used for processes for which no physical insight is available or used. This model structure belongs to families that are known to have good flexibility and have been "successful in the past." The parameters of the models are identified based on measurement data. A complete mechanistic model is constructed from *a priori* knowledge.

**Equipment Control** 

The procedural, basic, and coordination control capability that enables an equipment entity to perform its function. It is not part of a recipe but may be directed by a recipe.

**Equipment Entity** 

A set of process and control equipment and associated control capability that has been grouped together to provide some specified process or equipment functionality.

**Equipment Module** 

A group of equipment that can carry out a finite number of specific minor processing activities. An equipment module may include one or more control modules. It is typically centered around a piece of process equipment, such as a weigh tank, heat exchanger, filter, or weighing scale. It is an equipment entity incorporating necessary devices, control modules, and application-specific states and modes to execute some basic process-oriented task or group of tasks. It may include equipment procedural elements (typically phase logic) and/or subordinate equipment modules but may not overlap other equipment modules. Examples are a common (exclusiveuse) weigh tank, a recirculation/transfer pump within a unit, and a shared-use ingredient dosing system.

**Equivalent Time Sampling (ETS)** 

The process that captures high-speed electromagnetic events in real time (nanoseconds) and reconstructs them into an equivalent time (milliseconds), which allows easier measurement with present electronic circuitry.

**Ergonomics** 

An empirical approach to the study of human-machine interactions, with the

	objective of improving efficiency and	Feedback Control	See Control, Feedback.
	reducing strain and discomfort of the operator.	Feedforward Control	See Control, Feedforward.
Error	The difference between the measure-	FEP (Fluorinated	A fluorocarbon that is extremely chem-
	ment signal and its ideal value. A pos-	Ethylene	ically inert, melts at a reasonable tem-
	itive error denotes that the indication of	Propylene)	perature, and can be plastic-welded
	the instrument is greater than the ideal		fairly easily. Hard to bond with adhe-
Error, Systematic	value. An error which, when a number of meas-		sives. Max. temperature range limited to the 300°F (150°C) area.
Error, Systematic	urements are made under the same con-	Fieldbus	An all-digital, two-way, multi-drop
	ditions, measuring the same value of a		communications system for instru-
	given quantity, either remains constant		ments and other plant automation
	or varies according to some definite law		equipment.
F 7	when conditions change.	Firewall	A router or access server, designated as
Error, Zero	The error of a device when it is operating at the lower range value, which		a buffer between any public networks
	ating at the lower range-value, which is commonly referred to as its zero.	Flash Point	and a private network.  The lowest temperature at which a flam-
Ethernet	A baseband local area network specifi-	1 Idsii 1 oiiit	mable liquid gives off enough vapors to
	cation developed by Xerox Corporation,		form a flammable or ignitable mixture
	Intel, and Digital Equipment Corpora-		with air near the surface of the liquid or
	tion to interconnect computer equipment		within the container used. Many hazard-
E	using coaxial cable and transceivers.		ous liquids have flash points at or below
<b>Evaporation Loss</b>	Water evaporated from the circulating water into the atmosphere in the cool-		room temperature. They are normally covered by a layer of flammable vapors
	ing process. (Unit: percentage of total		that will ignite in the presence of a source
	GMP.)		of ignition.
Excitation,	The maximum excitation that can be	Fluidity	Reciprocal of absolute viscosity; unit
Maximum	applied to a device at rated operating		in the cgs system is the rhe, which equals
	conditions without causing damage or	<b>T</b>	1/poise.
	performance degradation beyond specified tolerances.	Floutter	Rapid, abnormal reciprocating varia-
Exception	Procedures and functions that deal with		tions in lift, during which the disc does not contact the seat.
Handling	conditions outside the normal or desired	Forced Draft	A type of mechanical draft water cool-
Ö	behavior of a process.	<b>Cooling Tower</b>	ing tower in which one or more fans
<b>Explosion Proof</b>	All equipment that is contained within		are located at the air inlet to force air
	enclosures that are strong enough to	•	into the tower.
	withstand internal explosions without	Forman	Vocal-tract resonance.
	damage and tight enough to confine the resulting hot gases so that they will not	Formula	A part of recipe that include process inputs, process parameters, and process
	ignite the external atmosphere. This is		outputs. The list of process inputs, out-
	the traditional method of protection and		puts, and data (operating set points,
	is applicable to all sizes and types of		reported values, timing, etc.) required
	equipment.		to execute the batch procedure.
Fan Pitch	The angle a fan blade makes with the	Frequency,	The frequency of a damped oscillatory
	plane of rotation. (Unit: degrees from horizontal.)	Damped	response of a system resulting from a nonoscillatory stimulus.
Fan Stack	Cylindrical or modified cylindrical struc-	Frequency	The frequency-dependent relation, both
(Cylinder)	ture in which the fan operates. Fan cyl-	Response	in terms of gain and phase, between
, •	inders are used on both induced draft	Characteristics	steady-state sinusoidal inputs and the
	and forced draft axial-flow propeller-		resulting steady-state sinusoidal outputs.
Equal (E)	type fans.	Fuel Cells	Cells that convert the chemical energy
Farad (F)	A unit of capacitance. Because this is a very large unit, a unit equal to one		of fuels such as hydrogen into electrical energy, while the electrode and the
	trillionth of a farad (called a pico Farad,		electrolyte remain unaltered. Fuel is con-
	symbol: "pF") is commonly used in RF		verted at the anode into hydrogen ions,
	circuits.		which travel through the electrolyte to

the cathode, and electrons, which travel through an external circuit to the cathode. If oxygen is present at the cathode, it is reduced by these electrons, and the hydrogen and oxygen ions eventually react to form water. **Function Block** A logical processing unit of software that has one or more input and output parameters. **Fuzzy Logic** This type of model is used for processes **Modeling** that are not fully understood. It is a linguistically interpretable rule-based model, which is based on the available expert knowledge and measured data. Gain, Closed Loop The ratio of a change in output to a change in input of a closed loop system at a specified frequency. Gain, Derivative The ratio of the maximum gain that (Rate Gain) results from the proportional plus derivative actions in a controller to the gain due to the proportional mode alone. Gain, Dynamic For a sinusoidal signal, it is the magnitude ratio of the steady-state amplitude of the output signal from a device to the amplitude of the input signal to that device. Gain, Loop At a specified frequency, it is the ratio of the magnitude of the change in the feedback signal to the change in its corresponding error signal. Gain For a linear system, it is the ratio of the (Magnitude amplitude of a steady-state sinusoidal Ratio) output and the amplitude of the input that caused it. Gain, Proportional The ratio of the change in the output of a controller with proportional action to the change in the input of the controller. **Galvanic Probe** A probe in which no external voltage is applied across its electrodes and the current flows as the cell is depolarized when diffusion of the analyte occurs. Electrodes are consumed during this operation and require periodic replacement. **General Recipe** A type of recipe that expresses equipment- and site-independent processing requirements. It is the highest level of recipe. **Gray Body** An object with a constant emittance of less than unity. This emittance is constant at all wavelengths (over that part of the spectrum where the measurement takes place). This means that gray-body radiation curves are identi-

> cal to those of a blackbody, except that they are dropped down on the radiated

power density scale.

**Definitions Gross Calorific** The heat value of energy per unit vol-Value ume at standard conditions, expressed in terms of British thermal unit per standard cubic feet (BTU/SCF) or as kilocalorie per cubic Newton meters (Kcal/N · m3) or other equivalent Ground A conducting connection, whether intentional or accidental, between an electrical circuit or equipment and the earth, or to some conducting body that serves in place of earth. (See NFPA 70-100.) **Ground Fault** Device used to open ungrounded con-**Protector** ductors when high currents, especially those due to line-to-ground fault currents, are encountered. The "electronic guard" (called a "shield" Guard in some RF level literature) consists of a concentric metallic element with an applied voltage that is identical to the voltage on the conductor that it is "guarding." This negates the capacitance between the guarded conductor and the outside world. **Guided Wave** A contact radar technology where Time Radar (GWR) Hagen-Poiseuille

Domain Reflectometry (TDR) has been developed into an industrial-level measurement system where a probe immersed in the medium acts as the waveguide. Defines the behavior of viscous liquid flow through a capillary.

Law HART Is an open, smart field instrumentation protocol that is a de facto fieldbus. It imposes a 1200-bit-per-second digital signal on a twisted pair of wires carry-

ing a 4- to 20-mA input. Home Run Wiring Wire between the cabinet where the Fieldbus host or centralized control system resides and the first field junction box or device.

**Hub (Shared)** Multi-port repeater joining segments into a network.

An undesirable oscillation of some Hunting appreciable magnitude, prolonged even after the external stimuli that caused it disappear.

Hygrometer An apparatus that measures humidity. Hygroscopic A material with great affinity for Material Hysteresis

That property of an element or system that shows the dependence of its output for a given excursion of the input on the history of prior excursions and on the direction of the current traverse. Hysteresis in a damper or valve is caused mostly by friction. Hysteresis in

**Impedance** 

a process transmitter is the maximum difference between readings taken at the same measurand with upscale and downscale approaches to the readings. It is due to inelastic qualities of the sensing element, friction, and backlash. Maximum voltage divided by maximum current in an alternating current circuit. Impedance is composed of resistive, inductive, and capacitive components. Like direct current circuits, the quantity of voltage divided by current is expressed in ohms.

Inaccuracy

The degree of conformity of a measured or indicated value to a recognized standard value. It is usually expressed in terms of measured variable, percent of span, percent of upper-range value, or percent of actual reading.

**Inaccuracy Rating** The quantity that defines the limit that errors will not exceed while the device is operating under specified conditions. Can be expressed in terms of the measured variable (for example ±0.5°F), in terms of percent span, in percent upper-range value, in percent of scale length, or in percent of actual output

**Infrared** 

That portion of the spectrum whose wavelength is longer than that of red light. Only the portion between 0.7 and 20 microns gives usable energy for radiation detectors.

Insulation Resistance

**Integral Action** 

Rate (Reset

Rate)

The resistance measured across the insulation at reference operating conditions when a specified direct current voltage is applied. The goal of the measurement is to determine whether the expected leakage current will or will not be excessive. For PI or PID controllers, it is the ratio of the initial rate of output change caused by the integral action to the change in steady-state output caused by the proportional action. Reset rate is often expressed as the number of repeats per minute because it equals the number of times the proportional correction is repeated by the integral action every

Integral Controller Interface

See Controller, Integral.

(1) Shared boundary. For example, the physical connection between two systems or two devices. (2) Generally, the point of interconnection of two components and the means by which they

**Interoperability** 

some hardware or software protocol. A marketing term with a blurred meaning. One possible definition is the ability for like devices from different manufacturers to work together in a system and be substituted one for another without loss of functionality at the host level (HART).

must exchange signals according to

**Intrinsic Safety** 

When under all conditions, the available energy is limited to levels that are too low to ignite the hazardous atmosphere. This method is useful only for low-power equipment such as instrumentation, communication, and remotecontrol circuits.

Kinematic Viscosity (v) Lambda

Dynamic viscosity/density =  $v = \mu/\rho$ .

Latency

The desired closed loop time constant, often set to equal the loop lag time. Latency measures the worst-case maximum time between the start of a

transaction and the completion of that transaction.

Lift The rise of the disc in a pressure relief

valve.

Line Driver Inexpensive amplifier and signal converter that conditions digital signals to ensure reliable transmissions over extended distances without the use of

modems.

Linearity, Independent The maximum deviation of a calibration curve from a straight line that is so positioned as to minimize that maximum deviation

Linearity. Terminal-Based The maximum deviation of a calibration curve from a straight line, if the line is so positioned that they coincide at the upper and lower range values.

Linearity, **Zero-Based**  The maximum deviation of a calibration curve from a straight line, if the line is so positioned that they coincide at the lower range value and to minimize the maximum deviation.

Linear **Programming** 

A mathematical technique for solving a set of linear equations and inequalities in order to maximize or minimize an additional function called an objec-

**Loop Gain** Characteristics For a closed loop, it is the characteristic curve of the ratio of the change in the return signal to the change in the corresponding error signal.

**Loop Transfer Function** 

This value of a closed control loop is obtained by taking the ratio of the Laplace transform of the return signal

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to the Laplace transform of the corresponding error signal.

Lot Products produced by a set of similar

batches, usually using the same master recipe. A collection of batches prepared using the same recipe. Typically, all batches of a lot are prepared from the same homogeneous source of raw

material.

Louvers Assemblies installed on the air inlet

faces of a tower to eliminate water

splash-out.

**Lower Explosive** Limit (LEL)

The lowest concentration of gas or vapor in air where, once ignition occurs, the gas or vapor will continue to burn after the source of ignition has been removed.

Lower Range-Limit

See Range-Limit, Lower.

**Low-Pass Filters** 

Filters that are used to remove highfrequency interference or noise from

low-frequency signals.

Makeup In cooling towers it is water added to replace loss by evaporation, drift, blow-

down, and leakage. (Unit: percentage

of circulation rate.)

Manchaster A digital signaling technique that contains a signal transition at the center of

every bit cell.

Manipulated Variable

The variable that is manipulated in order to reduce the controller's error and thereby to bring the controlled variable

closer to set point.

Manufacturing Range

A range around the specified burst pressure within which the marked or rated burst pressure must fall. Manufacturing range is not used in ISO standards.

**Master Recipe** 

A recipe for producing a batch of products using a particular set of process

equipment.

Maximum The maximum pressure expected dur-

Allowable ing normal operation.

**Operating** 

Pressure (MAOP)

Maximum Allowable Working **Pressure** (MAWP)

This is the maximum pressure allowed for continuous operation. As defined in the construction codes (ASME B31.3) for unfired pressure vessels, it equals the design pressure for the same design temperature. The maximum allowable working pressure depends on the type of material, its thickness, and the service conditions set as the basis for design. The vessel may not be operated above this pressure or its equivalent at any metal temperature other than that used in its design; consequently for that metal temperature, it is the highest pressure at which the primary pressure relief valve can be set to open.

Measurand **Mechanical Draft Cooling Tower** 

The physical parameter to be measured. A tower through which air movement is effected by one or more fans. There are two general types of such towers: those that use forced draft with fans located at the air inlet and those that use induced draft with fans located at the air exhaust.

Mechanical **Emissivity** Enhancement Micron

Mechanically increasing the emissivity of a surface to near-blackbody conditions (using multiple reflection).

Model-Based Control (MBC) Equivalent to 0.001 millimeters or 10,000 Ångstrom units. A unit used to measure wavelengths of radiant energy. In model-based control (MBC), a process model is used to make control decisions. The controller uses this model of the process to calculate a value for the manipulated variable, which should make the controlled variable behave in the desired way. The "inverse" nomenclature arises from how the model is used. In a normal modeling approach, one specifies the process input, and the model predicts the process output response. In contrast, MBC determines the process input (manipulated variable) that will cause a desired process output response (controlled variable value) to occur. This is the model inverse.

**Model Predictive** Control (MPC)

A model-based control technique that uses process output prediction and calculates consecutive controller moves in order to satisfy control objectives.

Modem

Modulator-demodulator. Device that converts digital and analog signals. At the source, a modem converts digital signals to a form suitable for transmission over analog communication facilities. At the destination, the analog signals are returned to their digital form. Modems allow data to be transmitted over voice-grade telephone lines.

Modulation

The result of a process whereby a characteristic of one wave is varied in accordance with some characteristics of another wave.

Morphology

The shape and size of the particles making up the object; a direct relation exists between these structures and materials properties (ductility, strength, reactivity, etc.)

**Multiple-Effect Evaporation** 

Multiple-effect evaporations use the vapor generated in one effect as the energy source to an adjacent effect. Double- and triple-effect evaporators are the most common; however, sixeffect evaporation can be found in the paper industry, where kraft liquor is concentrated, and as many as 20 effects can be found in desalinization plants.

Multiplexing

A method that allows multiple logical signals to be transmitted simultaneously across a single physical channel. Compare with **Demultiplexing**.

Narrow-Band **Pyrometer** 

A radiation pyrometer that is sensitive to only a narrow segment of wavelengths within the total radiation spectrum. Optical pyrometers are one of the devices in this category.

**Natural Draft Cooling Tower**  A cooling tower in which air movement is essentially dependent upon the difference in density between the entering air and internal air. As the heat of the water is transferred to the air passing through the tower, the warmed air tends to rise and draw in fresh air at the base of the tower.

Net Calorific Value The measurement of the actual avail-

able energy per unit volume at standard conditions, which is always less than the gross calorific value by an amount equal to the latent heat of vaporization of the water formed during combustion. All of the media, connectors, and associated communication elements by which a communication system operates.

Network

**Neurons** 

Newton

A brain cell that passes information by receiving and transmitting electrical impulses. Nodes in neural networks serve similar functions.

**Neutral Zone** 

See Zone, Neutral.

The internationally accepted unit of force, defined as the force required to accelerate one kilogram by one m/sec<sup>2</sup>. It equals 0.2248 pound-force or about 4 ounces.

**Nodes Nominal Tonnage** (Cooling)

Processing elements in neural networks. In cooling towers, one nominal ton corresponds to the transfer of 15,000 BTU/hr (4.4 kW) when water is cooled from 95 to 85°F (35 to 29.4°C) by ambient air having a wet-bulb temperature of 78°F (25.6°C) and when the water circulation rate is 3 GPM (11.3 lpm)

**Nonfragmenting** 

A rupture disc design that, when burst, Disc does not eject fragments that could Nonincendive **Equipment**  interfere with the operation of downstream equipment (i.e., relief valves). Equipment that in normal operations does not constitute a source of ignition. Therefore, its surface temperature shall not exceed ignition temperature of the specified gas to which it may be exposed, and there are no sliding or make-andbreak contacts operating at energy levels capable of causing ignition. Used for all types of equipment in Division 2 locations. Relies on the improbability of an ignition-capable fault condition occurring simultaneously with an escape of hazardous gas.

**Nonlinearity** 

Nonlinearity is expressed as a percent of full range output (%FRO) and is determined from the maximum difference between a datum on the output vs. measurand plot and a best straight line (BSL) drawn through the data.

Normal Mode Rejection

The ability of a circuit to discriminate against normal mode voltage. It can be expressed as a dimensionless ratio, as a scalar ratio, or in decibels (20 times the  $log_{10}$  of that ratio).

**Normal Mode** Voltage **Offset** 

A voltage across the input terminals of a device.

When in a controller the set point is fixed and in the steady state there is a deviation, it is called offset. The change in offset that results from a no-load to a full-load condition is often called "droop."

Oil Immersion

Equipment is submerged in oil to a depth sufficient to quench any sparks that may be produced. This technique is commonly used for switch-gears, but it is not utilized in connection with instruments.

**On-Off Controller Open Loop Gain** 

See Controller, On-Off.

The steady-state gain of a control loop when the other control loop(s) is(are) in manual. (Their control valve opening is constant.)

**Operating Pressure**  The operating pressure of a vessel is the pressure, in pounds per square inch gauge, to which the vessel is usually subjected in service. A processing vessel is usually designed for a maximum allowable working pressure, in pounds per square inch gauge, that will provide a suitable margin above the operating pressure in order to prevent any undesirable operation of the relief device. It is suggested that this margin be approximately 10%, or 25 PSI (173 kPa), whichever is greater. Such a margin will

be adequate to prevent the undesirable opening and operation of the pressure relief valve caused by minor fluctuations in the operating pressure.

Margin

Operating Pressure The margin between the maximum operating pressure and the set pressure of the PRV.

Ratio

**Operating Ratio** of a Rupture Disc

**Operating Pressure** The ratio of the maximum operating pressure to the set pressure of the PRV. The ratio of the maximum operating pressure to the marked burst pressure expressed as a percentage (common U.S. definition). The ratio of the maximum operating pressure to the minimum of the performance tolerance expressed as a percentage (common ISO definition). A procedure that controls the execution

**Operation** 

of a number of phases in a batch. A major programmed processing action or set of related actions, normally consisting of one or more phases.

Optical Pyrometer Also called brightness pyrometer, it uses a narrow band of radiation within the visible range (0.4 to 0.7 microns) to measure temperature by color matching and other techniques.

**Optimizing Control** Overpressure See Control, Optimizing.

The pressure increase over the set pressure of the primary relief device. When the set pressure is the same as the maximum allowable operating pressure (MAOP), the accumulation is the same as the overpressure. Pressure increase over the set pressure of the primary relieving device is overpressure. Note: From this definition it will be observed that when the set pressure of the first (primary) safety or relief valve is less than the maximum allowable working pressure of the vessel, the overpressure may be greater than 10% of set pressure.

The maximum input that can be applied

**Overrange Limit** 

to a device without causing damage or permanent change in its performance. **Partial Pressure** In a mixture of gases, the partial pressure of one component is the pressure of that component if it alone occupied the entire volume at the temperature of

the mixture.

Pascal-Seconds (Pas)

PDVF. Polyvinylidene Fluoride

Internationally accepted unit of absolute (dynamic) viscosity. Pas = Newton $sec/m^2 = 10$  poise = 1000 centipoise. This fluorocarbon has substantially lower temperature limits than the others (250°F

or 120°C) and is less inert chemically.

It is dissolved by the ketones (acetone, MEK, MIBK) and attacked by benzene and high concentrations of sulfuric acid. The most insidious enemy is caustic, which causes brittleness and cracking. It has much better toughness and abrasion resistance, than the other fluorocarbons, as well as unique electrical properties (K = 8).

PE (Polyethylene)

A low temperature insulation that is compatible with a wide range of corrosives but is attacked by most petroleum products. Generally limited to situations where fluoro- and chlorocarbons are not allowed, such as the tobacco and nuclear power industries. Max. allowable temperature is in the 180°F (80°C) area.

PEEK (Polyether Etherketone)

A high-temperature, injection-molded polymer that is chemically quite inert. This material has wide chemical application. Temperature capability is high at 450 to 500°F (225 to 260°C). Avoid any liquids with "phenol" in their name. Adhesive bonding to the molded parts would be difficult.

Perceptron

A transfer function used in some neural networks

PFA (Per-Fluoro-Alkoxy) A fluorocarbon that is quite inert chemically, melts at a fairly high temperature, and is easily plastic welded. It can be used up to 550°F (290°C), but as a probe insulation it is generally limited to 350°F (175°C) due to bonding lim-

Phase

itations with the metal rod. A set of logic steps that completes a major processing function, such as charge, mix, heat, and reaction. A batch is usually in a stable state at the end of a phase. It is the lowest level of procedural control to accomplish a processoriented task. Phases may be further subdivided into equipment-oriented steps and transitions for executing its defined task, as described in European standard IEC 60848 (1988) for specification of sequential function charts. Normally, the phase boundaries represent points of process transition, hold, or activity. The boundaries define major milestones and possible points of safe intervention. Phases may exist either as part of a recipe procedure (recipe phase) or independently for equipment control (equipment phase); however, any constituent steps are always part of the equipment phase.

**Phase Difference** Sensor (PDS) phase angle. **Phase Shift** with test frequency. Phoneme The sound of a human voice. **Photodetector** Pixel ("Picture Element") camera technology. Plenum compartment. Poise  $(\mu)$ (dyne-sec/cm<sup>2</sup>). Poiseuille (pi) Pascal-second. **Polarography** used. **Potentiometry** erence electrodes. **Potting** 

A contact radar technology; unlike TDRbased systems, which measure using subnanosecond time intervals, PDS derives level information from the changes in Of a signal, it is a change of phase angle with transmission. Of a transfer function, it is a change of phase angle Measures thermal radiation by producing an output through release of electrical changes within its body. Photodetectors are small flakes of crystalline materials, such as CdS or InSb, which respond to different portions of the spectrum, consequently showing great selectivity in the wavelengths at which they operate. Square dot, used in machine vision and Air distribution ducting, chamber, or Unit of dynamic or absolute viscosity Suggested name for the new international standard unit of viscosity, the Process for monitoring the diffusion current flow between working and auxiliary electrodes as a function of applied voltage as it is systematically varied. Concentration of analyte allows for flow of the diffusion current, which is linearly dependent on the analyte concentration. Polarography can be applied using direct current, pulsed direct current, or alternating current voltage excitation wave forms. Dissolved oxygen determination is an example of an application for which polarography is When no current is passing between electrodes. Examples: ORP, pH, selective-ion electrodes. The potential difference (at zero current) is monitored between the measuring and ref-Potting compound completely surrounding all live parts and thereby excluding the hazardous atmosphere has been proposed as a method of protection. There is no known usage except in combination with other means. The ratio of total true power (watts) to the apparent power total rms (rootmean-square) volt-amperes.

**Procedure** 

**Process Cell** 

PP Similar to PE. Used for low cost, and where fluoro- and Chlorocarbons are (Polypropylene) excluded. Max. temperature is in the area of 200°F. Pressure, Design The pressure that is used in the design of a device for the purpose of determining the required minimum wall thickness and other characteristics for a given maximum working pressure (MWP) at a given temperature. Pressure, The very maximum pressure that is permissible in a device under any circum-Maximum Working (MWP) stances during operation, at a specified temperature. **Pressure Relieving** The broadest category in the area of pres-Device sure relief devices, includes rupture discs and pressure relief valves of both the simple spring-loaded type and certain pilot-operated types. **Pressure Relief** A generic term that might refer to relief Valve (PRV) valves, safety valves, and pilot-operated valves. The purpose of a PRV is to automatically open and to relieve the excess system pressure by sending the process gases or fluids to a safe location when its pressure setting is reached. Pressure, Surge It is the sum of the operating pressure plus a pressure increment that develops for a very short time while pumps are starting or valves are closing. **Primary Standard** A measuring instrument calibrated at a national standard laboratory such as NIST and used to calibrate other sensors. **Procedural** Control that sequentially directs subor-Control dinate procedural elements or basic controls to execute the steps required by its

defined process-oriented task. A user-defined set of instructions that de-

fine the strategy for making a single batch of a particular type or grade of product. A set of equipment required for production of one or more batches. It usually consists of one or more units. It is a grouping of equipment that comprises one or more complete trains and defines the immediate local domain for production scheduling (analogous to a work cell in discrete manufacturing).

**Process Inputs** Identity and quantity of raw materials and other resources required to make a batch. Other resources include energy and manpower requirements.

**Process Outputs** Identity and quantity of products and/or energy produced at the end of a batch. **Process** Variables, such as temperature, pres-**Parameters** sure, and time, that are set points and

**Power Factor** 

comparison values needed for the production of a batch.

**Proof** A specific gravity unit used in the alcohol industry.

**Proportional Band** In a proportional-only controller, it is

the change required in the input signal to result in a full range change in the

controller's output.

**Proportional** Controller **Protocol** 

See Controller, Proportional.

Formal description of a set of rules and conventions that govern how devices on a network exchange information. In communications it is a set of conventions or rules that must be adhered to by both communicating parties to ensure that information being exchanged between two parties is received and interpreted

correctly.

**Prosodic** The pitch of voice; the duration and Characteristics intensity of speech.

**Prosody** Accent and voice modulation.

An instrument used primarily to mea-**Psychrometer** sure the wet-bulb temperature.

(P)TFE (Tetra-

In the abbreviation, the "P" stands for Fluoro-Ethylene) "polymerized." It is the oldest, highest temperature, and most inert fluorocarbon probe insulation. Extremely difficult to adhesive bond, it is usable up to 550°F (290°C), but on probes, its temperature limit is determined by the type of bonding to the probe rod (300, 450, or 550°F). This is the most common probe insulation in the industry. Since it never melts (it disintegrates producing HF at 600 +°F), it is difficult to fabricate, is impossible to plastic-weld, and exhibits a high degree of microporosity. Can be destroyed by butadiene and styrene monomer.

Purging, Pressurization. Ventilation

These processes depend upon the maintenance of a slight positive pressure of air or inert gas within an enclosure so that the hazardous atmosphere cannot enter. Relatively recent in general application, it is applicable to any size or type of equipment.

**Quevenne Degrees** 

A specific gravity unit used in the expressing the fat content of milk.

A general term for enclosed channels, **Raceway** conduit, and tubing designed for hold-

ing wires and cables.

Radar (Radio **Detection and** Ranging)

A system using beamed and reflected radio-frequency energy for detecting and locating objects, measuring distance or altitude, navigating, homing, bombing,

**Radio Frequency** 

range of an object in the beam's path. A frequency that is higher than sonic but less than infrared. The low end of the RF range is 20 kHz, and its high end is around 100,000 MHz.

and other purposes; in detecting and

ranging, the time interval between trans-

mission of the energy and reception of the reflected energy establishes the

Radio Frequency Interference (RFI)

A phenomenon where electromagnetic waves from one source interfere with the performance of another electrical device.

Range

The region in which a quantity is measured, received, or transmitted. The limits of this region are the lower and upper range-values.

Range, Cooling

For a cooling tower, it is the difference between the temperatures of water inlet and outlet. For a system operating in a steady state, the range is the same as the water temperature rise through the load heat exchanger. Accordingly, the range is determined by the heat load and water flow rate, not by the size or capability of the cooling tower.

Range, Elevated Zero

A range in which the zero value of the measured variable is greater than the lower range-value. Sometimes the term "suppressed range" is also used, but "elevated zero" is preferred.

Range, Suppressed-Zero

A range in which the zero value of the measured variable is less than the lower range value. Sometimes the term "elevated range" is also used, but "suppressed zero range" is preferred.

Range-Value, Lower

The lowest value of the measured variable less that the particular device is adjusted to measure.

Range-Value, **Upper** 

The highest value of the measured variable that the device is adjusted to

Rate Control Action **Rated Relieving** Capacity

**See Control Action, Derivative.** 

It is the maximum relieving capacity of the PRV. These data are normally provided on the nameplate of the PRV. The rated relieving capacity of the PRV exceeds the required relieving capacity and is the basis for sizing the vent header system.

**Ratio Controller Ratio Pyrometer** Reactance (X)

See Controller, Ratio. See Two-Color Pyrometer.

That part of the impedance of a circuit that is caused by either capacitance or inductance or both. (Units: ohms.)

Rear Mount

A technique for making long inactive sections, by mounting the probe on the end of a pipe, with its coax cable running through the pipe to the top of the tank. The coax must survive the process temperature, so it is often of hightemperature construction.

Recipe

A set of procedures and formula variables that specify the production of a batch. There are four types of recipes: general, site, master, and control. A recipe is the complete set of data and operations that define the control requirements for a particular type or grade of final or intermediate product. Specifically, each recipe comprises a header, formula, procedure, and equipment requirements.

Reference .Junction

The thermocouple junction that is at a known or reference temperature. It is that point at which the thermocouple extension wires are connected to the lead wires or to an instrument.

Reference .Junction Compensation The means by which the effect of temperature variations at the reference junction is corrected for.

Reflectance or Reflectivity (R)

The percentage of the total radiation falling on a body that is directly reflected without entry. Reflectance is zero for a blackbody, and nearly 100% for a highly polished surface. (R = 1 -A-T, where A is the absorbance and T is the transmissivity.)

Regulator **Relative Gain** (RG)

See Controller, Self-Operated.

The ratio of the steady-state gain of the loop with other loops in manual, divided by the steady-state gain of the loop when the other loops are in automatic.

**Relative Gain Array** 

A matrix of dimensionless gain ratios giving one RG value for each pairing of manipulated and controlled variables.

**Relative Humidity** 

The ratio of the mole fraction of moisture in a gas mixture to the mole fraction of moisture in a saturated mixture at the same temperature and pressure. Or, the ratio of the amount of moisture in a gas mixture to the amount of moisture in a saturated mixture at equal volume, temperature, and pressure.

**Relative Viscosity** 

Ratio of absolute viscosity of a fluid at any temperature to that of water at 20°C (68°F). Since water at this temperature has a  $\mu$  of 1.002 cp, the relative viscosity of a fluid equals approximately its absolute viscosity in cp. Since density

of water is 1, kinematic viscosity of water equals 1.002 cSt at 20°C.

Relief Valve

An automatic pressure relieving device actuated by the static pressure upstream of the valve, which opens in proportion to the increase in pressure over the operating pressure. It is used primarily for liquid service.

**Relieving Pressure** 

The sum of opening pressure plus overpressure. It is the pressure, measured at the valve's inlet, at which the relieving capacity is determined.

Reopening Pressure The opening pressure when the pressure is raised as soon as practicable after the valve has reseated or closed from a previous discharge.

Repeatability

For full range traverses of a number of consecutive measurements, approaching from the same direction, it is the closeness of agreement among the outputs of the sensor when measuring the same value under the same operating conditions. It is usually expressed in percent of span. A more accurate term for it would be nonrepeatability.

Reproducibility

For a number of consecutive measurements, approaching from both directions, it is the closeness of agreement among the outputs of the sensor when measuring the same value under the same operating conditions over a period of time. It is usually expressed in percent of span. A more accurate term for it would be nonreproducibility. See Control Action, Integral.

**Reset Control** Action

Resistive Component AC current can be separated into two components; the portion that is in phase with the excitation voltage is the resistive component.

Resistivity  $(\rho)$ 

It is the property of a conductive material that determines how much resistance a unit cube will produce. (Units: ohmcentimeters.)

Resolution

The least interval between two adjacent discrete details that can be distinguished one from the other.

Resonance

A condition evidenced by large oscillatory amplitude, which results from a small amplitude periodic input, when the frequency of that input is approaching one of the natural frequencies of the system. The time it takes for the output of a

device, resulting from the application

of a specified input under specified

**Response Time** 

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	operating conditions to move from its initial value to within some specified percentage of its final steady-state value.	Saturation Pressure	The pressure of a fluid when condensation (or vaporization) takes place at a given temperature. (The temperature
Reverse Acting Controller	See Controller, Reverse Acting.	Saybolt Furol	is the saturation temperature.) Time units referring to the Saybolt vis-
Richter Degrees	A specific gravity unit used in the alcohol industry.	Seconds (SFS)	cometer with a Furol capillary, which is larger than a universal capillary.
Riser	In case of a cooling tower, it is the piping that connects the circulating water supply line from the level of the base of the tower or the supply header to the tower inlet connection.	Saybolt Universal Seconds (SUS) Scale Factor	Time units referring to the Saybolt viscometer.  The value of the scale divisions on an instrument. To compute the value of the measured variable, the number of scale
RMS Value	See Value, RMS.		divisions is multiplied by this scale
Roentgen	A unit for expressing the strength of a radiation field. In a 1-Roentgen radiation field, 2.08 billion pairs of ions are	Scaling	factor.  The conversion from engineering units to fractions or percentages.
Roentgen Equivalent Man (rem)	produced in a cubic centimeter of air. A unit of allowable radiation dosage, corresponding to the amount of radiation received when exposed to 1 roentgen over any period of time.	Sealing	The atmosphere is excluded from potential sources of ignition by sealing them in airtight containers. This method is used for components such as relays, not for complete instruments.
<b>Root Valve</b>	The first valve off the process.	<b>Seal-Off Pressure</b>	The pressure, measured at the valve
Rupture Tolerance	For a rupture disc it is the tolerance range on either side of the marked or rated burst pressure within which the rup-		inlet after closing, at which no further liquid, steam, or gas is detected at the downstream side of the seat.
	ture disc is expected to burst. Rupture tolerance may also be represented as a minimum–maximum pressure range. Also referred to as performance toler-	Segment	The section of a network that is terminated in its characteristic impedance. Segments are linked by repeaters to form a complete network.
Safety Relief Valve	ance in ISO standards.  An automatic pressure-actuated relieving device suitable for use as either a safety or relief valve.	Self-Regulation	The property of a system, which permits attainment of equilibrium after a disturbance without the intervention of a controller.
Safety Valve	An automatic pressure-relieving device actuated by the static pressure upstream of the valve and characterized by rapid	Sensitivity	The ratio of the change in output to the change of the input that causes it after a steady state been reached.
Sand Filling	and full opening or pop action. It is used for steam, gas, or vapor service.  All potential sources of ignition are	Sensor	An input device that provides a usable output in response to the input measurand. (A sensor is also commonly called
Saturated Solution	buried in a granular solid, such as sand. The sand acts, in part, to keep the hazardous atmosphere away from the sources of ignition and, in part, as an arc quencher and flame arrester. It is used in Europe for heavy equipment. It is not used in instruments. A solution that has reached the limit of	Service	a sensing element, primary sensor, or primary detector. The measurand is the physical parameter to be measured.) Term used by NFPA-70 (NEC) to demarcate the point at which utility electrical codes published by IEEE (NESC) take over. Includes conductors and equipment that deliver electricity from
	solubility.		utilities.
Saturation	A condition where RF current from a probe-to-ground is determined solely by the impedance of the probe insula-	Servomechanism	An automatic feedback control device in which the controlled variable is a mechanical position or some derivative
	tion. Increased conductivity in the sat- urating medium, even to infinity, will not cause a noticeable change in that current or in the transmitter output.	Set Point	of that position.  An input variable of a controller that sets the desired value of the variable that is being controlled.

Set Pressure (Opening Pressure)	The pressure at which the relief valve is set to open. It is the pressure mea- sured at the valve inlet of the PRV, at which there is a measurable lift, or at		rects its process variable values to improve system performance. The value of a smart field device lies in the quality of data it provides.
	which discharge becomes continuous as determined by seeing, feeling, or hear-	Span	The difference between the upper and lower range-values.
	ing. In the pop-type safety valve, it is the pressure at which the valve moves	<b>Specific Humidity</b>	The ratio of the mass of water vapor to the mass of dry gas in a given volume.
	more in the opening direction com- pared to corresponding movements at	Specific Viscosity	Ratio of absolute viscosity of a fluid to that of a standard fluid, usually water,
	higher or lower pressures. A safety valve or a safety relief valve is not con-	Spectral Emissivity	both at the same temperature.  The ratio of emittance at a specific
	sidered to be open when it is simmering at a pressure just below the popping point, even though the simmering may	Split Ranging	wavelength or very narrow band to that of a blackbody at the same temperature. A configuration in which, from a single
Shear Viscometer	be audible. Viscometer that measures viscosity of a non-Newtonian fluid at several differ-		input signal, two or more signals are generated or two or more final control elements are actuated, each responding
	ent shear rates. Viscosity is extrapo- lated to zero shear rate by connecting the measured points and extending the	Standard Air	consecutively, with or without overlap, to the magnitude of the input signal. Dry air having a density of 0.075 lb/cu.
Signal, Analog	curve to zero shear rate.  A signal representing a continuously	Start-to-Leak	ft. at 70°F and 29.92 in. Hg. For a safety relief valve it is the pres-
Signal, Digital	observed variable.  Information represented by a set of dis-	Pressure	sure at the valve inlet at which the relieved fluid is first detected on the
	crete values in accordance with a prescribed law.		downstream side of the seat before normal relieving action takes place.
Signal-to-Noise Ratio	The ratio of the amplitude of a signal to the amplitude of the noise. The ampli-	Steady State	A variable is at steady-state condition when it is exhibiting negligible change
Signum	tude can be a peak or an rms value, as specified.  A transfer function used in some back-	Stiction (Static Friction)	over a long period of time.  The resistance to the starting of motion.  When stroking a control valve, it is the
Sikes Degree	propagation neural networks.  A specific gravity unit used in the alcohol industry.	Stiffness	combination of sticking and slipping. In the case of a spring element, it is the ratio of the change in force or torque
Simmer (Warn)	The condition just prior to opening at which a spring-loaded relief valve is at	Stoke	to the resulting change in deflection. Unit of kinematic viscosity $\upsilon$ (cm²/sec).
	the point of having zero or negative forces holding the valve closed. Under these conditions, as soon as the valve	Stress Subchannel	Force/Area (F/A). In broadband terminology, a frequency-based subdivision creating a separate
	disc attempts to rise, the spring constant develops enough force to close the	Subsidence Ratio	communications channel.  The ratio of the peak amplitudes of two
Single-Effect Evaporation	valve again. Single-effect evaporation occurs when a dilute solution is contacted only once		successive oscillations of the same sign, measured in reference to an ultimate steady-state value.
	with a heat source to produce a concentrated solution and an essentially pure water vapor discharge.	Superimposed Backpressure	Backpressure that is present in the discharge header before the pressure relief valve starts to open. It can be constant
Site Recipe	A recipe that includes site-specific information, such as local language and	Cummuosiss	or variable, depending on the status of the other PRVs in the system.
Slab	locally available raw materials.  A set of nodes.	Suppression, Zero	See Range, Elevated-Zero. See Zero Suppression.
Smart Field Device	A microprocessor-based process transmitter or actuator that supports two-way communications with a host; digitizes	Surge Pressure Switched Hub	See <b>Pressure</b> , <b>Surge</b> .  Multiport bridge joining networks into a larger network.
	the transducer signals; and digitally cor-	Systematic Error	See Error, Systematic.

System, Linear

A system is linear if its time response to several simultaneous inputs is the sum of their individual (independent) time responses.

**Tapping** Teflon, TFE, FEP, and PFA See Dither.

Most people interchange the name Teflon with TFE. This is completely incorrect, but understandable. TFE was the first fluorocarbon polymer to carry the trade name "Teflon" at E.I. DuPont. DuPont chose to use the "Teflon" trade name for a whole family of fluorocarbon resins, so FEP and PFA made by DuPont are also Teflon. To complicate the matter, other companies now manufacture TFE, FEP, and PFA, which legally cannot be called Teflon, since that name applies only to DuPont-made polymers.

**Thermopile** 

Measures thermal radiation by absorption to become hotter than its surroundings. It is a number of small thermocouples arranged like the spokes of a wheel, with the hot junction at the hub. The thermocouples are connected in series and the output is based on the difference between the hot and cold iunctions.

**Throughput** 

The maximum number of transactions per second that can be communicated by the system.

Time Constant (T)

If a first-order system is responding to a step or an impulse, T is the time required to complete 63.2% of the total rise or decay. In higher-order systems, there is a time constant for each of the first-order components of the process. The time interval between the initiation of an output change or stimulus and the start of the resulting observable

Time, Dead

**Time Domain** Reflectometry (TDR)

A TDR instrument measures the electrical characteristics of wideband transmission systems, subassemblies, components, and lines by feeding in a voltage step and displaying the superimposed reflected signals on an oscilloscope equipped with a suitable time-base

response.

**Timeout** 

Event that occurs when one network device expects to hear from another network device within a specified period of time, but does not. The resulting timeout usually results in a retransmission of information or the dissolving of the session between the two devices.

Time, Ramp Response

The time interval by which an output lags an input, when both are varying at a constant rate.

Time, Settling

After a stimulus to a system, the time required for the output of the system to enter and remain within a specified narrow band centered on its steady-state value. If the stimulus is a step or impulse, the band is often specified as  $\pm 2\%$ .

**Topology** 

Physical arrangement of network nodes and media within an enterprise networking structure or the surface features of an object or "how it looks," its texture; there is a direct relation between these features and materials properties (hardness, reflectivity, etc.).

The ratio of the integrated value of all

**Total Emissivity** 

spectral emittances to that of a blackbody. Train A grouping within one process cell of

units and associated lower-level equipment that is capable of making a batch of material. A train may define a single equipment path for a batch or multiple possibilities, of which one will be selected based on availability during execution of the control recipe. Multiple batches can be processed simultaneously in the same train (but different units).

**Tralles Degrees** 

A specific gravity unit used in the alcohol industry.

Transducer

A device that receives information in the form of one quantity and converts it to information in the form of the same or another quantity. This general definition also applies to primary elements or transmitters. An input transducer produces an electrical output, which is representative of the input measurand. Its output is conditioned and ready for use by the receiving electronics. (The terms "input transducer" and "transducer" can be used interchangeably.)

**Transfer Function** A statement of influence of an element or system, in a mathematical, tabular, or graphical form. This influence can be that of an element or system on a signal or action, which is compared at input and output terminals.

**Transient** 

The behavior of a variable during transition between two steady states.

**Transient** Overshoot

**Transistor** 

It is the maximum overshoot beyond the final steady-state value of an output, which results from a change in an input. Three-terminal, solid state electronic device made of silicone, gallium-

arsenide or germanium and used for

Transmittance or Transmissivity (T)

Transmitter

**Twaddell Degree** 

Two-Color Pyrometer

Unit

**Unit Procedure** 

amplification and switching in integrated circuits.

The percentage of the total radiant energy falling on a body that passes directly through it without being absorbed. Transmittance is zero for a blackbody and nearly 100 percent for a material like glass in the visible spectrum region. (T = 1 - A - R), where A is the absorbance and R is the reflectance.) A transducer that responds to a measured variable generated by a sensor and converts it to a standardized transmission signal. This signal is a function of only the measured variable. The term "transmitter," as commonly used with industrial process control instrumentation, has a narrower definition than those of a sensor or transducer: A transmitter is a transducer that responds to a measured variable by means of a sensing element and converts it to a standardized transmission signal that is a function only of the measured variable.

A specific gravity unit used in the sugar, tanning, and acid industries.

Measures temperature as a function of the radiation ratio emitted around two narrow wavelength bands. Also called ratio pyrometer.

A major piece of process equipment with its associated equipment modules. Mixers, storage tanks, and reactors are examples of units. The associated equipment modules include pumps, valves, heat exchangers, and agitators that are closely associated with the major process equipment. Units operate relatively independently of one another. They are equipment that contains and performs some major processing activity or activities (e.g., react, crystallize, make solution) on one batch at a time. A unit normally comprises a major piece of equipment and directly associated control modules and/or equipment modules that are not shared with other units.

A major programmed processing action or set of related actions, normally consisting of one or more operations. Unit procedures are naturally related to a distinct regime of production: for example, all processing carried out in one batch unit of a multiunit production line. **Unit Recipe** 

A part of a recipe that defines a part of batch production requirements within a unit. It usually includes a number of operations and phases.

**Upper Explosive Limit (UEL)**  The highest concentration of gas or vapor in air in which a flame will continue to burn after the source of ignition has been removed.

Upper Range-Limit The upper limit of the value of the measured variable that a particular instrument is capable of measuring.

Varactor Variable Backpressure ment is capable of measuring. Voltage-sensitive capacitor. Backpressure that varies due to changes

in operation of one or more pressure relief valves connected into a common discharge header.

Variable, Controlled Variable, Manipulated Velocity Gradient (Shear) See Controlled Variable.

See Manipulated Variable.

Rate of change of liquid velocity across the stream—V/L for linear velocity profile, dV/dL for nonlinear velocity profile. Units are  $V-L = ft/sec/ft = sec^{-1}$ . The velocity head is calculated as  $v^2/2g$ ,

where v is the flowing velocity and g is the gravitational acceleration (9.819 m/s<sup>2</sup> or 32.215 ft/s<sup>2</sup> at 60 degrees latitude). The limit that the rate of change of a particular variable may not exceed.

It is used to remotely view local device data described in an object dictionary. A typical device will have at least two VFDs.

Virtual Field Device (VFD)

**Velocity Limit** 

Velocity Head

See Common Mode Voltage.

Common Mode Voltage, Normal Mode Water Loading

Voltage,

See Normal Mode Voltage.

In case of cooling towers it is the water flow divided by effective horizontal wetted area of the tower. (Unit: GPM/ft<sup>2</sup> or m<sup>3</sup>/hr m<sup>2</sup>.)

Wave-Guide

A device that constrains or guides the propagation of electromagnetic waves along a path defined by the physical construction of the wave-guide; includes ducts, a pair of parallel wires, and a coaxial cable.

Wet-Bulb Temperature (WBT) If a thermometer bulb is covered by a wet, water-absorbing substance and is exposed to air, evaporation will cool the bulb to the wet-bulb temperature of the surrounding air. This is the temperature read by a psychrometer. If the air is saturated with water, the wet-bulb, dry-bulb, and dew-point temperatures will all be

White Box Modeling

Wide Band (Total) Pyrometer

**Wobbe Index** 

(E)Xtensible Markup Language (XML) the same. Otherwise, the wet-bulb temperature is higher than the dew-point temperature but lower than the dry-bulb temperature.

This type of modeling is feasible if a good understanding of the process exists. In such cases, the dynamic models are derived based on mass, energy, and momentum balances of the process.

A radiation thermometer that measures the total power density emitted by the material of interest over a wide range of wavelengths.

AGA 4A defines the Wobbe Index as a numerical value, which is calculated by dividing the square root of the relative density (a key flow orifice parameter) into the heat content (or BTU per std. cubic foot) of the gas. Mathematically, the Wobbe Index is defined by the equation below:

Wobbe Index = 
$$\frac{\text{calorific value}}{\sqrt{\text{specific gravity}}}$$

A computer authoring language for publishing documents through the World Wide Web on the Internet. For use in automation, it is better and more flexible

than hypertext markup language (HTML).

**Zero Elevation** 

When the zero of a range is elevated, the amount of its elevation is the quantity by which the zero of the measured variable exceeds the lower rangevalue

**Zero Suppression** 

When the zero of a range is suppressed, the amount of the suppression is the quantity by which the zero of the measured variable is below the lower rangevalue.

Zone, Dead

Zone, Neutral

ured variable is below the lower rangevalue.

A range of input through which the output remains unchanged. This holds true if the input signal is rising or dropping. For two-position controllers (switches), the neutral intermediate zone is the range of input values in which the pre-

## SOCIETIES AND ORGANIZATIONS

AATCC	American Association of Textile Chemists and Colorists	CNI CPAC	ControlNet International Center for Process Analytical Chemistry
ACC	American Chemistry Council	CSA	Canadian Standards Association
ACGIH	American Conference of Governmental		
	Industrial Hygenists	DARPA	Defense Advanced Research Projects Agency
ACS	American Chemical Society	DIERS	Design Institute for Emergency Relief
AGA	American Gas Association		Systems
AIA	Automatic Imaging Association	DIN	Deutsche Institut für Normung (German
AIChE	American Institute of Chemical Engineers		Standards Institute)
AMTEX	American Textile Partnership	DOD	Department of Defense (United States)
ANSI	American National Standards Institute	DOE	Department of Energy
AOCS	American Oil Chemists' Society	DOT	Department of Transportation
APHA	American Public Health Association		•
API	American Petroleum Institute	EBF	European Batch Forum
ARI	Air Conditioning and Refrigeration Institute	ECMA	European Computer Manufacturers Association
ASA	American Standards Association	EEMUA	Engineering Equipment and Materials
ASCE	American Standards Association  American Society of Civil Engineers	LEMUA	Users Association
ASM	Abnormal Situation Management Consor-	EIA	Electronic Industries Association
ASIVI	tium	EIA/TIA	Electrical Industries Alliance/Telecommu-
ASME	American Society of Mechanical Engineers	LIA/ IIA	nications Industries Alliance
ASRE	American Society of Refrigeration Engineers	EPA	Environmental Protection Agency
ASTM	American Society of Refrigeration Engineers  American Society for Testing and Materi-	EPRI	Electric Power Research Institute
ASTWI	als or ASTM International	EXERA	The Instrument Users' Association in
Awwa	American Water Works Association	LALKA	France
Awwa	American water works Association		Tance
BSI	British Standards Institution	FCC	Federal Communications Commission
		FCI	Fluid Control Institute
CARB	California Air Resources Board	FDA	Food and Drug Administration
CCITT	Consultative Committee for International	FF	Fieldbus Foundation
	Telegraphy and Telephony	FIA	Fire Insurance Association
CCSDS	Consultative Committee for Space Data	FM	Factory Mutual
	Systems	FMRC	Factory Mutual Research Corporation
CDC	Centers for Disease Control (United	FPA	Fire Protection Association
	States)	FSEC	Florida Solar Energy Center
CENELEC	European Committee for Electrotechnical		
	Standardization	GERG	Groupe Européen de Rechérches Gaziéres
CIE	Commission International del'Eclairage		(European Gas Research Group)
CII	Construction Industry Institute	GRI	Gas Research Institute
CIL	Canadian Industries Limited	HCF	HART Communication Foundation

IAEI	International Association of Electrical Inspectors	NFPA NIOSH	National Fire Protection Association National Institute of Occupational Safety
IBEW	International Brotherhood of Electrical Workers	NIST	and Health
ICE	Institute of Civil Engineers	MIST	National Institute of Standards and Technology
ICEA	Insulated Cable Engineers Association	NSC	National Safety Council
ICTS	International Consortium of Telemetry	NSPA	National Spa and Pool Association
1015	Spectrum Spectrum	NSPE	National Society of Professional Engineers
IEC	International Electrotechnical Commission	NRC	Nuclear Regulatory Commission
IEEE	Institute of Electrical and Electronic	NIC	Nuclear Regulatory Commission
ILLL	Engineers	ODVA	Open DaviceNet Vander Association
IETF	Internet Engineering Task Force	OSHA	Open DeviceNet Vendor Association
IGT	Institute of Gas Technology	ОЗПА	Occupational Safety and Health Administration
INPO	Institute of Oas Technology  Institute for Nuclear Power Operation	OTS	Office of Technical Services
IPTS	International Practical Temperature Scale	013	Office of Technical Services
IrDA or IRDA	Infrared Data Association	DCT	Detect Comment on Total
ISA	Instrumentation, Systems, and Automation	PCT	Patent Cooperation Treaty
	Society	PNO	Profibus User Organization
ISO	International Standards Organization	SAE	Society of Automotive Engineers
ISSEP	International Soros Science Education Program	SAMA	Scientific Apparatus Manufacturers Association
ISTM	International Society for Testing Materials	SIREP	The Instrument Users' Association in the
ITA	Instrumentation Testing Association		United Kingdom
JBF	Japanese Batch Forum	TAPPI	Technical Association of the Pulp and
JBF JPL	Japanese Batch Forum Jet Propulsion Laboratory	TAPPI	Technical Association of the Pulp and Paper Industry
JPL	Jet Propulsion Laboratory	TIA	Paper Industry Telecommunications Industries Alliance
JPL KEPRI	Jet Propulsion Laboratory  Korean Electric Power Research Institute		Paper Industry Telecommunications Industries Alliance Technischer überwachungs Verein (Techni-
JPL KEPRI LCIE	Jet Propulsion Laboratory  Korean Electric Power Research Institute  Laboratoire Central des Industries Electriques	TIA	Paper Industry Telecommunications Industries Alliance
JPL KEPRI	Jet Propulsion Laboratory  Korean Electric Power Research Institute	TIA	Paper Industry Telecommunications Industries Alliance Technischer überwachungs Verein (Technical Inspection Association) United Association of Journeyman and
JPL KEPRI LCIE	Jet Propulsion Laboratory  Korean Electric Power Research Institute  Laboratoire Central des Industries Electriques	TIA TUV	Paper Industry Telecommunications Industries Alliance Technischer überwachungs Verein (Technical Inspection Association)  United Association of Journeyman and Apprentices of the Plumbing and Pipe Fitting Industry of the United States and
JPL KEPRI LCIE LPGA	Jet Propulsion Laboratory  Korean Electric Power Research Institute  Laboratoire Central des Industries Electriques National LP-Gas Association	TIA TUV UA	Paper Industry Telecommunications Industries Alliance Technischer überwachungs Verein (Technical Inspection Association)  United Association of Journeyman and Apprentices of the Plumbing and Pipe Fitting Industry of the United States and Canada
JPL KEPRI LCIE LPGA MCA	Jet Propulsion Laboratory  Korean Electric Power Research Institute  Laboratoire Central des Industries Electriques National LP-Gas Association  Manufacturing Chemists Association  German standardization association for pro-	TIA TUV UA	Paper Industry Telecommunications Industries Alliance Technischer überwachungs Verein (Technical Inspection Association)  United Association of Journeyman and Apprentices of the Plumbing and Pipe Fitting Industry of the United States and Canada Underwriters Laboratories, Inc.
JPL KEPRI LCIE LPGA MCA	Jet Propulsion Laboratory  Korean Electric Power Research Institute  Laboratoire Central des Industries Electriques National LP-Gas Association  Manufacturing Chemists Association  German standardization association for process control (Normen-Arbeitsgemeinschaft für Meß- und Regeltechnik in der Chemis-	TIA TUV UA	Paper Industry Telecommunications Industries Alliance Technischer überwachungs Verein (Technical Inspection Association)  United Association of Journeyman and Apprentices of the Plumbing and Pipe Fitting Industry of the United States and Canada
JPL KEPRI LCIE LPGA MCA NAMUR	Jet Propulsion Laboratory  Korean Electric Power Research Institute  Laboratoire Central des Industries Electriques National LP-Gas Association  Manufacturing Chemists Association  German standardization association for process control (Normen-Arbeitsgemeinschaft für Meß- und Regeltechnik in der Chemischen Industrie)	TIA TUV UA UL USASI USNRC	Paper Industry Telecommunications Industries Alliance Technischer überwachungs Verein (Technical Inspection Association)  United Association of Journeyman and Apprentices of the Plumbing and Pipe Fitting Industry of the United States and Canada Underwriters Laboratories, Inc. USA Standard Institute U.S. Nuclear Regulatory Commission
JPL KEPRI LCIE LPGA MCA	Jet Propulsion Laboratory  Korean Electric Power Research Institute  Laboratoire Central des Industries Electriques National LP-Gas Association  Manufacturing Chemists Association  German standardization association for process control (Normen-Arbeitsgemeinschaft für Meß- und Regeltechnik in der Chemischen Industrie)  National Aeronautics and Space	TIA TUV UA UL USASI	Paper Industry Telecommunications Industries Alliance Technischer überwachungs Verein (Technical Inspection Association)  United Association of Journeyman and Apprentices of the Plumbing and Pipe Fitting Industry of the United States and Canada Underwriters Laboratories, Inc. USA Standard Institute U.S. Nuclear Regulatory Commission  Verband Deutscher Maschinen und
JPL KEPRI LCIE LPGA MCA NAMUR	Jet Propulsion Laboratory  Korean Electric Power Research Institute  Laboratoire Central des Industries Electriques National LP-Gas Association  Manufacturing Chemists Association  German standardization association for process control (Normen-Arbeitsgemeinschaft für Meß- und Regeltechnik in der Chemischen Industrie)  National Aeronautics and Space Administration	TIA TUV UA UL USASI USNRC	Paper Industry Telecommunications Industries Alliance Technischer überwachungs Verein (Technical Inspection Association)  United Association of Journeyman and Apprentices of the Plumbing and Pipe Fitting Industry of the United States and Canada Underwriters Laboratories, Inc. USA Standard Institute U.S. Nuclear Regulatory Commission
JPL KEPRI LCIE LPGA MCA NAMUR NASA NBFU	Jet Propulsion Laboratory  Korean Electric Power Research Institute  Laboratoire Central des Industries Electriques National LP-Gas Association  Manufacturing Chemists Association  German standardization association for process control (Normen-Arbeitsgemeinschaft für Meß- und Regeltechnik in der Chemischen Industrie)  National Aeronautics and Space Administration  National Board of Fire Underwriters	TIA TUV UA UL USASI USNRC	Paper Industry Telecommunications Industries Alliance Technischer überwachungs Verein (Technical Inspection Association)  United Association of Journeyman and Apprentices of the Plumbing and Pipe Fitting Industry of the United States and Canada Underwriters Laboratories, Inc. USA Standard Institute U.S. Nuclear Regulatory Commission  Verband Deutscher Maschinen und
JPL KEPRI LCIE LPGA MCA NAMUR NASA NBFU NBS	Jet Propulsion Laboratory  Korean Electric Power Research Institute  Laboratoire Central des Industries Electriques National LP-Gas Association  Manufacturing Chemists Association  German standardization association for process control (Normen-Arbeitsgemeinschaft für Meß- und Regeltechnik in der Chemischen Industrie)  National Aeronautics and Space Administration National Board of Fire Underwriters National Bureau of Standards	TIA TUV UA UL USASI USNRC	Paper Industry Telecommunications Industries Alliance Technischer überwachungs Verein (Technical Inspection Association)  United Association of Journeyman and Apprentices of the Plumbing and Pipe Fitting Industry of the United States and Canada Underwriters Laboratories, Inc. USA Standard Institute U.S. Nuclear Regulatory Commission  Verband Deutscher Maschinen und
JPL KEPRI LCIE LPGA MCA NAMUR NASA NBFU	Korean Electric Power Research Institute  Laboratoire Central des Industries Electriques National LP-Gas Association  Manufacturing Chemists Association  German standardization association for process control (Normen-Arbeitsgemeinschaft für Meß- und Regeltechnik in der Chemischen Industrie)  National Aeronautics and Space Administration  National Board of Fire Underwriters National Bureau of Standards National Electrical (Equipment) Manufac-	TIA TUV  UA  UL USASI USNRC  VDMA  WBF WEF	Paper Industry Telecommunications Industries Alliance Technischer überwachungs Verein (Technical Inspection Association)  United Association of Journeyman and Apprentices of the Plumbing and Pipe Fitting Industry of the United States and Canada Underwriters Laboratories, Inc. USA Standard Institute U.S. Nuclear Regulatory Commission  Verband Deutscher Maschinen und Anlagenbau e.V.
JPL KEPRI LCIE LPGA MCA NAMUR  NASA NBFU NBS NEMA	Korean Electric Power Research Institute  Laboratoire Central des Industries Electriques National LP-Gas Association  Manufacturing Chemists Association  German standardization association for process control (Normen-Arbeitsgemeinschaft für Meβ- und Regeltechnik in der Chemischen Industrie)  National Aeronautics and Space Administration  National Board of Fire Underwriters National Bureau of Standards National Electrical (Equipment) Manufacturers Association	TIA TUV  UA  UL USASI USNRC  VDMA  WBF	Paper Industry Telecommunications Industries Alliance Technischer überwachungs Verein (Technical Inspection Association)  United Association of Journeyman and Apprentices of the Plumbing and Pipe Fitting Industry of the United States and Canada Underwriters Laboratories, Inc. USA Standard Institute U.S. Nuclear Regulatory Commission  Verband Deutscher Maschinen und Anlagenbau e.V.  World Batch Forum
JPL KEPRI LCIE LPGA MCA NAMUR NASA NBFU NBS	Korean Electric Power Research Institute  Laboratoire Central des Industries Electriques National LP-Gas Association  Manufacturing Chemists Association  German standardization association for process control (Normen-Arbeitsgemeinschaft für Meß- und Regeltechnik in der Chemischen Industrie)  National Aeronautics and Space Administration  National Board of Fire Underwriters National Bureau of Standards National Electrical (Equipment) Manufac-	TIA TUV  UA  UL USASI USNRC  VDMA  WBF WEF	Paper Industry Telecommunications Industries Alliance Technischer überwachungs Verein (Technical Inspection Association)  United Association of Journeyman and Apprentices of the Plumbing and Pipe Fitting Industry of the United States and Canada Underwriters Laboratories, Inc. USA Standard Institute U.S. Nuclear Regulatory Commission  Verband Deutscher Maschinen und Anlagenbau e.V.  World Batch Forum Water Environment Federation

## ABBREVIATIONS, NOMENCLATURE, ACRONYMS, AND SYMBOLS

NOTES		A/D	analog-to-digital, also analog-to-digital converter
1. Whenever th	e abbreviated form of a unit might lead	AD	actuation depth
	, it should not be used and the name	ADC	analog-to-digital converter
	ritten out in full.	ADIS	approved for draft international standard
2. The values of	of SI equivalents were rounded to three		circulation
decimal plac	÷	ADPCM	adaptive differential pulse-code modulation
	neter and liter are used in their accepted	AE	analyzer element
	ing form instead of those in the standards,	A&E	alarm and event
	re and litre, respectively.	AES	atomic emission spectrometer
	, , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , , ,	AF or a-f	audio frequency
1001	one out of one	AFC	alkaline fuel cell
1002	one out of two	AFD	adjustable frequency drive
1002D	one out of two with diagnostics	AGA3	American Gas Association Report No. 3
2002	two out of two	AGC	automatic generation control or automatic
2003	two out of three		gap control
2003d	two out of three with diagnostics	ai	adobe illustrator
2D	two-dimensional	AI	analog input or artificial intelligence
3D	three-dimensional	AI-AT	analog input-air temperature
		AI-RT	analog input-return temperature
		a(k)	white noise
	A	ALARA	as low as reasonably achievable
a	acceleration	ALARP	as low as reasonably practicable
A	1) area; 2) ampere, symbol for basic SI unit	AliS	alternate lighting of surfaces
	of electric current; also admittance	ALP	low pressure air
Å	$Å$ ngstrom (= $10^{-10}$ m)	Alpm	actual liters per minute
AA	atomic absorption	ALSW	admissible load supply well
AAS	atomic absorption spectrometer	alt	altitude
abs	absolute (e.g., value)	AM	amplitude modulation or actual measure-
ABS	acrylonitrile-butadiene-styrene		ment or alarm management
AC, ac, a-c	alternating current	AMC	annual maintenance contract or adaptive
A/C	air to close		model controller or auto-manual cascade
ACFM	volumetric flow at actual conditions in	AMLCD	active matrix LCD
	cubic feet per minute (= 28.32 alpm)	amp	ampere; also A, $q.v$ .
ACL	asynchronous connection-less	AMPS	advanced mobile phone system
ACM	automatic control mode	AMS	asset management solutions or analyzer
ACMH	actual cubic meter per hour	,	maintenance solutions
ACMM	actual cubic meter per minute	a/n	alpha numeric
ACS	analyzer control system	ANN	artificial neural network
ACSL	advanced continuous simulation language	ANS	adaptive neural swarming

4.0	1	0D (	D
AO	analog output	°Bé	Baumé degrees of liquid density
A/O	air to open	BEP	best efficiency point
AOTF	acousto-optical tunable filters	BFO	beat frequency oscillator
AP	access point	BFW	boiler feed water
APC	automatic process control or advanced pro-	Bhp, BHP	brak horsepower (= 746 W)
	cess control	BIBO	bounded input, bounded output
APDU	application (layer) protocol data unit	°Bk	Barkometer degrees of liquid density
API	application programming interface or abso-	blk	black (wiring code color for AC "hot"
	lute performance index		conductor)
°API	API degrees of liquid density	BMS	burner management system or boiler man-
APM	application pulse modulation		agement system
APSL	air pressure switch, low	ВО	basic operation
AR	auto regressive	BOD	biochemical oxygen demand
ARA	alarm response analysis	bp or b.p.	boiling point
ARIMA	auto regressive integrated moving average	BPCS	basic process control system
ARP	address resolution protocol	BPS or bps	bits per second
ARX	auto regressive with external inputs	BPSK	binary phase shift keying
71101	(model)	Bq	becquerel, symbol for derived SI unit of
ARW	antireset windup	54	radioactivity, joules per kilogram, J/kg
AS	adjustable speed	°Br	Brix degrees of liquid density
ASCI	autosequentially commutated current-fed	BSL	best straight line
ASCI	inverter	BSTR	batch stirred tank reactor
ASCII	American Standard Code for Information	BTR	block transfer read
ASCII		BTU	
ACI	Interchange		British thermal unit (= 1054 J)
AS-I	actuator sensor interface	BWD	backwash drain
ASIC	application-specific integrated chips	BWG	Birmingham wire gauge
ASK	amplitude shift keying	BWR	backwash return
ASU	air separation unit	BWS	backwash supply
asym	asymmetrical; not symmetrical		_
AT	air temperature or analyzer transmitter		C
	air temperature or analyzer transmitter automatic tank gauging	c	1) velocity of light in vacuum ( $3 \times 10^8$ m/s);
AT ATG atm	air temperature or analyzer transmitter automatic tank gauging atmosphere (= 14.7 psi)		<ol> <li>velocity of light in vacuum (3 × 10<sup>8</sup> m/s);</li> <li>centi, prefix meaning 0.01</li> </ol>
AT ATG atm ATP	air temperature or analyzer transmitter automatic tank gauging atmosphere (= 14.7 psi) adenosine triphosphate	c C	<ol> <li>velocity of light in vacuum (3 × 10<sup>8</sup> m/s);</li> <li>centi, prefix meaning 0.01</li> <li>coulombs or symbol for discharge coeffi-</li> </ol>
AT ATG atm ATP ATR	air temperature or analyzer transmitter automatic tank gauging atmosphere (= 14.7 psi) adenosine triphosphate attenuated total reflectance		<ol> <li>velocity of light in vacuum (3 × 10<sup>8</sup> m/s);</li> <li>centi, prefix meaning 0.01</li> </ol>
AT ATG atm ATP ATR AUI	air temperature or analyzer transmitter automatic tank gauging atmosphere (= 14.7 psi) adenosine triphosphate attenuated total reflectance attachment unit interface		<ol> <li>velocity of light in vacuum (3 × 10<sup>8</sup> m/s);</li> <li>centi, prefix meaning 0.01</li> <li>coulombs or symbol for discharge coeffi-</li> </ol>
AT ATG atm ATP ATR	air temperature or analyzer transmitter automatic tank gauging atmosphere (= 14.7 psi) adenosine triphosphate attenuated total reflectance attachment unit interface automatic utility translator	С	1) velocity of light in vacuum (3 × 10 <sup>8</sup> m/s); 2) centi, prefix meaning 0.01 coulombs or symbol for discharge coeffi- cient, also capacitance
AT ATG atm ATP ATR AUI	air temperature or analyzer transmitter automatic tank gauging atmosphere (= 14.7 psi) adenosine triphosphate attenuated total reflectance attachment unit interface	C °C	<ol> <li>velocity of light in vacuum (3 × 10<sup>8</sup> m/s);</li> <li>centi, prefix meaning 0.01 coulombs or symbol for discharge coefficient, also capacitance</li> <li>Celsius degrees of temperature</li> </ol>
AT ATG atm ATP ATR AUI AUTRAN	air temperature or analyzer transmitter automatic tank gauging atmosphere (= 14.7 psi) adenosine triphosphate attenuated total reflectance attachment unit interface automatic utility translator	C°C ca.	1) velocity of light in vacuum (3 × 10 <sup>8</sup> m/s); 2) centi, prefix meaning 0.01 coulombs or symbol for discharge coeffi- cient, also capacitance Celsius degrees of temperature <i>circa</i> : about, approximately
AT ATG atm ATP ATR AUI AUTRAN aux	air temperature or analyzer transmitter automatic tank gauging atmosphere (= 14.7 psi) adenosine triphosphate attenuated total reflectance attachment unit interface automatic utility translator auxiliary	C°C ca.	1) velocity of light in vacuum (3 × 10 <sup>8</sup> m/s); 2) centi, prefix meaning 0.01 coulombs or symbol for discharge coeffi- cient, also capacitance Celsius degrees of temperature <i>circa</i> : about, approximately channel access code computer-aided design
AT ATG atm ATP ATR AUI AUTRAN aux AV	air temperature or analyzer transmitter automatic tank gauging atmosphere (= 14.7 psi) adenosine triphosphate attenuated total reflectance attachment unit interface automatic utility translator auxiliary auxiliary (constraint) variable	C °C ca. CAC CAD	1) velocity of light in vacuum (3 × 10 <sup>8</sup> m/s); 2) centi, prefix meaning 0.01 coulombs or symbol for discharge coeffi- cient, also capacitance Celsius degrees of temperature <i>circa</i> : about, approximately channel access code computer-aided design calorie (gram, = 4.184 J); also g-cal
AT ATG atm ATP ATR AUI AUTRAN aux AV AVC	air temperature or analyzer transmitter automatic tank gauging atmosphere (= 14.7 psi) adenosine triphosphate attenuated total reflectance attachment unit interface automatic utility translator auxiliary auxiliary (constraint) variable air velocity controller	C °C ca. CAC CAD Cal	1) velocity of light in vacuum (3 × 10 <sup>8</sup> m/s); 2) centi, prefix meaning 0.01 coulombs or symbol for discharge coeffi- cient, also capacitance Celsius degrees of temperature <i>circa</i> : about, approximately channel access code computer-aided design
AT ATG atm ATP ATR AUI AUTRAN aux AV AVC AVR	air temperature or analyzer transmitter automatic tank gauging atmosphere (= 14.7 psi) adenosine triphosphate attenuated total reflectance attachment unit interface automatic utility translator auxiliary auxiliary (constraint) variable air velocity controller automatic voltage regulator	C °C ca. CAC CAD Cal CAMAC	1) velocity of light in vacuum (3 × 10 <sup>8</sup> m/s); 2) centi, prefix meaning 0.01 coulombs or symbol for discharge coeffi- cient, also capacitance Celsius degrees of temperature <i>circa</i> : about, approximately channel access code computer-aided design calorie (gram, = 4.184 J); also g-cal control advance moving average control area network or control and auto-
AT ATG atm ATP ATR AUI AUTRAN aux AV AVC AVR	air temperature or analyzer transmitter automatic tank gauging atmosphere (= 14.7 psi) adenosine triphosphate attenuated total reflectance attachment unit interface automatic utility translator auxiliary auxiliary (constraint) variable air velocity controller automatic voltage regulator	C ca. CAC CAD Cal CAMAC CAN	1) velocity of light in vacuum (3 × 10 <sup>8</sup> m/s); 2) centi, prefix meaning 0.01 coulombs or symbol for discharge coefficient, also capacitance Celsius degrees of temperature circa: about, approximately channel access code computer-aided design calorie (gram, = 4.184 J); also g-cal control advance moving average control area network or control and auto- mation network
AT ATG atm ATP ATR AUI AUTRAN aux AV AVC AVR AWG	air temperature or analyzer transmitter automatic tank gauging atmosphere (= 14.7 psi) adenosine triphosphate attenuated total reflectance attachment unit interface automatic utility translator auxiliary auxiliary (constraint) variable air velocity controller automatic voltage regulator American wire gauge	C °C ca. CAC CAD Cal CAMAC CAN	1) velocity of light in vacuum (3 × 10 <sup>8</sup> m/s); 2) centi, prefix meaning 0.01 coulombs or symbol for discharge coefficient, also capacitance Celsius degrees of temperature circa: about, approximately channel access code computer-aided design calorie (gram, = 4.184 J); also g-cal control advance moving average control area network or control and automation network CAPital EXpenditure
AT ATG atm ATP ATR AUI AUTRAN aux AV AVC AVR AWG	air temperature or analyzer transmitter automatic tank gauging atmosphere (= 14.7 psi) adenosine triphosphate attenuated total reflectance attachment unit interface automatic utility translator auxiliary auxiliary (constraint) variable air velocity controller automatic voltage regulator American wire gauge  B bottom product flow rate	C °C ca. CAC CAD Cal CAMAC CAN CAPEX CARI	1) velocity of light in vacuum (3 × 10 <sup>8</sup> m/s); 2) centi, prefix meaning 0.01 coulombs or symbol for discharge coefficient, also capacitance Celsius degrees of temperature circa: about, approximately channel access code computer-aided design calorie (gram, = 4.184 J); also g-cal control advance moving average control area network or control and automation network CAPital EXpenditure combustion air requirement index
AT ATG atm ATP ATR AUI AUTRAN aux AV AVC AVR AWG	air temperature or analyzer transmitter automatic tank gauging atmosphere (= 14.7 psi) adenosine triphosphate attenuated total reflectance attachment unit interface automatic utility translator auxiliary auxiliary (constraint) variable air velocity controller automatic voltage regulator American wire gauge  B bottom product flow rate business-to-business	C °C ca. CAC CAD Cal CAMAC CAN CAPEX CARI CAS	1) velocity of light in vacuum (3 × 10 <sup>8</sup> m/s); 2) centi, prefix meaning 0.01 coulombs or symbol for discharge coefficient, also capacitance Celsius degrees of temperature circa: about, approximately channel access code computer-aided design calorie (gram, = 4.184 J); also g-cal control advance moving average control area network or control and automation network CAPital EXpenditure combustion air requirement index cascade
AT ATG atm ATP ATR AUI AUTRAN aux AV AVC AVR AWG  B B2B °Ba	air temperature or analyzer transmitter automatic tank gauging atmosphere (= 14.7 psi) adenosine triphosphate attenuated total reflectance attachment unit interface automatic utility translator auxiliary auxiliary (constraint) variable air velocity controller automatic voltage regulator American wire gauge  B  bottom product flow rate business-to-business Balling degrees of liquid density	C  °C  ca.  CAC  CAD  Cal  CAMAC  CAN  CAPEX  CARI  CAS  CATV	1) velocity of light in vacuum (3 × 10 <sup>8</sup> m/s); 2) centi, prefix meaning 0.01 coulombs or symbol for discharge coefficient, also capacitance Celsius degrees of temperature circa: about, approximately channel access code computer-aided design calorie (gram, = 4.184 J); also g-cal control advance moving average control area network or control and automation network CAPital EXpenditure combustion air requirement index cascade community antenna television (cable)
AT ATG atm ATP ATR AUI AUTRAN aux AV AVC AVR AWG  B B2B °Ba BAC	air temperature or analyzer transmitter automatic tank gauging atmosphere (= 14.7 psi) adenosine triphosphate attenuated total reflectance attachment unit interface automatic utility translator auxiliary auxiliary (constraint) variable air velocity controller automatic voltage regulator American wire gauge  B  bottom product flow rate business-to-business Balling degrees of liquid density biologically activated carbon	C  °C  ca.  CAC  CAD  Cal  CAMAC  CAN  CAPEX  CARI  CAS  CATV  CBM	1) velocity of light in vacuum (3 × 10 <sup>8</sup> m/s); 2) centi, prefix meaning 0.01 coulombs or symbol for discharge coefficient, also capacitance Celsius degrees of temperature circa: about, approximately channel access code computer-aided design calorie (gram, = 4.184 J); also g-cal control advance moving average control area network or control and automation network CAPital EXpenditure combustion air requirement index cascade community antenna television (cable) condition-based maintenance
AT ATG atm ATP ATR AUI AUTRAN aux AV AVC AVR AWG  B B2B °Ba	air temperature or analyzer transmitter automatic tank gauging atmosphere (= 14.7 psi) adenosine triphosphate attenuated total reflectance attachment unit interface automatic utility translator auxiliary auxiliary (constraint) variable air velocity controller automatic voltage regulator American wire gauge  B bottom product flow rate business-to-business Balling degrees of liquid density biologically activated carbon 1) barometer; 2) unit of atmospheric pres-	C  °C  ca.  CAC  CAD  Cal  CAMAC  CAN  CAPEX  CARI  CAS  CATV  CBM  CBT	1) velocity of light in vacuum (3 × 10 <sup>8</sup> m/s); 2) centi, prefix meaning 0.01 coulombs or symbol for discharge coefficient, also capacitance Celsius degrees of temperature circa: about, approximately channel access code computer-aided design calorie (gram, = 4.184 J); also g-cal control advance moving average control area network or control and automation network CAPital EXpenditure combustion air requirement index cascade community antenna television (cable) condition-based maintenance computer-based timing
AT ATG atm ATP ATR AUI AUTRAN aux AV AVC AVR AWG  B B2B °Ba BAC bar	air temperature or analyzer transmitter automatic tank gauging atmosphere (= 14.7 psi) adenosine triphosphate attenuated total reflectance attachment unit interface automatic utility translator auxiliary auxiliary (constraint) variable air velocity controller automatic voltage regulator American wire gauge  B  bottom product flow rate business-to-business Balling degrees of liquid density biologically activated carbon 1) barometer; 2) unit of atmospheric pressure measurement (= 100 kPa)	C  °C  ca.  CAC  CAD  Cal  CAMAC  CAN  CAPEX  CARI  CAS  CATV  CBM  CBT  cc	1) velocity of light in vacuum (3 × 10 <sup>8</sup> m/s); 2) centi, prefix meaning 0.01 coulombs or symbol for discharge coefficient, also capacitance Celsius degrees of temperature circa: about, approximately channel access code computer-aided design calorie (gram, = 4.184 J); also g-cal control advance moving average control area network or control and automation network CAPital EXpenditure combustion air requirement index cascade community antenna television (cable) condition-based maintenance computer-based timing cubic centimeter (= 10 <sup>-6</sup> m³)
AT ATG atm ATP ATR AUI AUTRAN aux AV AVC AVR AWG  B B2B °Ba BAC bar bara	air temperature or analyzer transmitter automatic tank gauging atmosphere (= 14.7 psi) adenosine triphosphate attenuated total reflectance attachment unit interface automatic utility translator auxiliary auxiliary (constraint) variable air velocity controller automatic voltage regulator American wire gauge  B  bottom product flow rate business-to-business Balling degrees of liquid density biologically activated carbon 1) barometer; 2) unit of atmospheric pressure measurement (= 100 kPa) bar absolute	C  °C  ca.  CAC  CAD  Cal  CAMAC  CAN  CAPEX  CARI  CAS  CATV  CBM  CBT  cc  CC	1) velocity of light in vacuum (3 × 10 <sup>8</sup> m/s); 2) centi, prefix meaning 0.01 coulombs or symbol for discharge coefficient, also capacitance Celsius degrees of temperature circa: about, approximately channel access code computer-aided design calorie (gram, = 4.184 J); also g-cal control advance moving average control area network or control and automation network CAPital EXpenditure combustion air requirement index cascade community antenna television (cable) condition-based maintenance computer-based timing cubic centimeter (= 10 <sup>-6</sup> m³) cooling coil
AT ATG atm ATP ATR AUI AUTRAN aux AV AVC AVR AWG  B B2B °Ba BAC bar bara barg	air temperature or analyzer transmitter automatic tank gauging atmosphere (= 14.7 psi) adenosine triphosphate attenuated total reflectance attachment unit interface automatic utility translator auxiliary auxiliary (constraint) variable air velocity controller automatic voltage regulator American wire gauge  B  bottom product flow rate business-to-business Balling degrees of liquid density biologically activated carbon 1) barometer; 2) unit of atmospheric pressure measurement (= 100 kPa) bar absolute bar gauge	C  °C  ca.  CAC  CAD  Cal  CAMAC  CAN  CAPEX  CARI  CAS  CATV  CBM  CBT  cc  CC  CCD	1) velocity of light in vacuum (3 × 10 <sup>8</sup> m/s); 2) centi, prefix meaning 0.01 coulombs or symbol for discharge coefficient, also capacitance Celsius degrees of temperature circa: about, approximately channel access code computer-aided design calorie (gram, = 4.184 J); also g-cal control advance moving average control area network or control and automation network CAPital EXpenditure combustion air requirement index cascade community antenna television (cable) condition-based maintenance computer-based timing cubic centimeter (= 10 <sup>-6</sup> m³) cooling coil charge-coupled device
AT ATG atm ATP ATR AUI AUTRAN aux AV AVC AVR AWG  B B2B °Ba BAC bar  bara barg bbl	air temperature or analyzer transmitter automatic tank gauging atmosphere (= 14.7 psi) adenosine triphosphate attenuated total reflectance attachment unit interface automatic utility translator auxiliary auxiliary (constraint) variable air velocity controller automatic voltage regulator American wire gauge  B  bottom product flow rate business-to-business Balling degrees of liquid density biologically activated carbon 1) barometer; 2) unit of atmospheric pressure measurement (= 100 kPa) bar absolute bar gauge barrels (= 0.1589 m³)	C  °C  ca.  CAC  CAD  Cal  CAMAC  CAN  CAPEX  CARI  CAS  CATV  CBM  CBT  cc  CC	1) velocity of light in vacuum (3 × 10 <sup>8</sup> m/s); 2) centi, prefix meaning 0.01 coulombs or symbol for discharge coefficient, also capacitance Celsius degrees of temperature circa: about, approximately channel access code computer-aided design calorie (gram, = 4.184 J); also g-cal control advance moving average control area network or control and automation network CAPital EXpenditure combustion air requirement index cascade community antenna television (cable) condition-based maintenance computer-based timing cubic centimeter (= 10 <sup>-6</sup> m³) cooling coil charge-coupled device common cause failure or combination capa-
AT ATG atm ATP ATR AUI AUTRAN aux AV AVC AVR AWG  B B2B °Ba BAC bar bara barg bbl BCD	air temperature or analyzer transmitter automatic tank gauging atmosphere (= 14.7 psi) adenosine triphosphate attenuated total reflectance attachment unit interface automatic utility translator auxiliary auxiliary (constraint) variable air velocity controller automatic voltage regulator American wire gauge  B  bottom product flow rate business-to-business Balling degrees of liquid density biologically activated carbon 1) barometer; 2) unit of atmospheric pressure measurement (= 100 kPa) bar absolute bar gauge barrels (= 0.1589 m³) binary coded decimal	C  °C  ca.  CAC  CAD  Cal  CAMAC  CAN  CAPEX  CARI  CAS  CATV  CBM  CBT  cc  CC  CCD  CCF	1) velocity of light in vacuum (3 × 10 <sup>8</sup> m/s); 2) centi, prefix meaning 0.01 coulombs or symbol for discharge coefficient, also capacitance Celsius degrees of temperature circa: about, approximately channel access code computer-aided design calorie (gram, = 4.184 J); also g-cal control advance moving average control area network or control and automation network CAPital EXpenditure combustion air requirement index cascade community antenna television (cable) condition-based maintenance computer-based timing cubic centimeter (= 10 <sup>-6</sup> m³) cooling coil charge-coupled device common cause failure or combination capacity factor
AT ATG atm ATP ATR AUI AUTRAN aux AV AVC AVR AWG  B B2B °Ba BAC bar bara barg bbl BCD BCM	air temperature or analyzer transmitter automatic tank gauging atmosphere (= 14.7 psi) adenosine triphosphate attenuated total reflectance attachment unit interface automatic utility translator auxiliary auxiliary (constraint) variable air velocity controller automatic voltage regulator American wire gauge  B  bottom product flow rate business-to-business Balling degrees of liquid density biologically activated carbon 1) barometer; 2) unit of atmospheric pressure measurement (= 100 kPa) bar absolute bar gauge barrels (= 0.1589 m³) binary coded decimal backup communication module	C  °C  ca.  CAC  CAD  Cal  CAMAC  CAN  CAPEX  CARI  CAS  CATV  CBM  CBT  cc  CC  CCD  CCF	1) velocity of light in vacuum (3 × 10 <sup>8</sup> m/s); 2) centi, prefix meaning 0.01 coulombs or symbol for discharge coefficient, also capacitance Celsius degrees of temperature circa: about, approximately channel access code computer-aided design calorie (gram, = 4.184 J); also g-cal control advance moving average control area network or control and automation network CAPital EXpenditure combustion air requirement index cascade community antenna television (cable) condition-based maintenance computer-based timing cubic centimeter (= 10 <sup>-6</sup> m³) cooling coil charge-coupled device common cause failure or combination capacity factor cubic centimeter per minute
AT ATG atm ATP ATR AUI AUTRAN aux AV AVC AVR AWG  B B2B °Ba BAC bar bara barg bbl BCD	air temperature or analyzer transmitter automatic tank gauging atmosphere (= 14.7 psi) adenosine triphosphate attenuated total reflectance attachment unit interface automatic utility translator auxiliary auxiliary (constraint) variable air velocity controller automatic voltage regulator American wire gauge  B  bottom product flow rate business-to-business Balling degrees of liquid density biologically activated carbon 1) barometer; 2) unit of atmospheric pressure measurement (= 100 kPa) bar absolute bar gauge barrels (= 0.1589 m³) binary coded decimal	C  °C  ca.  CAC  CAD  Cal  CAMAC  CAN  CAPEX  CARI  CAS  CATV  CBM  CBT  cc  CC  CCD  CCF	1) velocity of light in vacuum (3 × 10 <sup>8</sup> m/s); 2) centi, prefix meaning 0.01 coulombs or symbol for discharge coefficient, also capacitance Celsius degrees of temperature circa: about, approximately channel access code computer-aided design calorie (gram, = 4.184 J); also g-cal control advance moving average control area network or control and automation network CAPital EXpenditure combustion air requirement index cascade community antenna television (cable) condition-based maintenance computer-based timing cubic centimeter (= 10 <sup>-6</sup> m³) cooling coil charge-coupled device common cause failure or combination capacity factor

CCC		1	
CCS	computer control system or constant cur-	cmph	cubic meter per hour
G CTTV I	rent source	CMR	common mode rejection
CCTV	closed circuit television	CMRR	common mode rejection ratio
CCW	counterclockwise	CMS	carbon molecular sieve
cd	candela, symbol for basic SI unit of lumi-	CMV	common-mode voltage
	nous intensity	CNC	computerized numerical control
CD	compact disk, collision detector, compel	CNI	ControlNet International
	data or dangerous coverage factor, cold deck	Co	cobalt
CDDP	cellular digital packet data	CO	controller output or carbon monoxide or
CDF	cumulative distribution function		contact output
CDMA	code division multiple access	$CO_2$	carbon dioxide
CDPD	cellular digital packet data	$CO_2D$	carbon dioxide demand
CDT	color detection tube	COD	chemical oxygen demand
CDTP	cold differential test pressure	COF	coefficient of haze
CE	Conformité Europeéne (European Confor-	COM	component (or compiled) object model
	mity) applicable to electrical safety	COND	conductivity
CEHED	chlorination-caustic extraction-hypochlo-	COP	coefficient of performance
	rite bleaching-caustic extraction-chlorine	cos	cosine, trigonometric function
	dioxide	COT	coil outlet temperature
CEMS	continuous emissions monitoring system	COTS	commercial off-the-shelf
CENP	combustion engineering nuclear power	COV	coil outlet velocity
CF	cleanliness factor or cubic foot	cp or c.p.	1) candle power; 2) circular pitch; 3) center
CFA	continuous flow analyzer	·rr	of pressure (cp and ctp may also be used
CFE	cartridge filter effluent		for centipoises)
CEM	cause and effect matrix	cpm	cycles per minute; counts per minute
CFM or cfm	cubic foot per minute (28.32 lpm)	cps	1) cycles per second (= Hz); 2) counts per
CFR	Code of Federal Regulations	СРЗ	second; 3) centipoises (= 0.001 Pa.S)
CF/Yr	cubic foot per year	CPS	computerized procedure system
CHP	combined heat and power	CPU	central processing unit
CHS	chemical sludge	CPVC	chlorinated polyvinyl chloride
CHWP	chilled water pump	CR	corrosion rate
CHWR	chilled water return	CRC	cyclical redundancy check or cyclic redun-
CHWS		CKC	•
	chilled water supply		dancy code (an error detection coding technique based upon modulo-2 division; some-
Ci	curie (= $3.7 \times 10^{10}$ Bq)		times misused to refer to a block check
CI	cast iron or corrosion inhibitor		
CIM	computer-integrated manufacturing	CDDC	sequence type of error detection coding)
CIO	channel input—output	CRDS	cavity ring-down spectroscopy
CIP	1) computer-aided production; 2) control and	CRH	cold reheat
	information protocol (an application layer	CRLF	carriage return-line feed
	protocol supported by DeviceNet, Control-	CRT	cathode ray tube
GT.	Net, and Ethernet/IP); or 3) clean in place	Cs	cesium
CJ	cold junction	CS	1) carbon steel; 2) constant speed; 3) chlo-
CL	clamp on		rine solution
CL1	electrically hazardous, Class 1, Division 1,	CSD	crystal size distribution
	Groups C or D	CSH	constant speed held
CLD	chemiluminescence detector	CSL	car seal lock
CLOS	common Lisp object system	CSMA/CD	carrier sense, multiple (medium) access
CLP	closed-loop potential factor		with collision detection
cm	centimeter (= 0.01 m) or cubic meter	CSO	car seal open
CM	condition monitoring or communication	CSS	central supervisory station
	(interface) module or control module	CSSD	compatible single side band
CMF	Coriolis mass flowmeter	cSt	centi stoke
CMMS	computerized maintenance management	CSTR	continuous-stirred tank reactor
	system	CT	cooling tower or the product of C for dis-
CMOS	complementary metal oxide semiconductor		infectant concentration and $T$ for time of
CMPC	constrained multivariable predictive control		contact in minutes

CTDIA		D.C.	P 1
CTDMA	concurrent time domain multiple access	DG	directed graph
CTMP	chemi-thermo-mechanical pulp	DH	data highway
CTWP	cooling tower water pump	DH+	data highway plus (high-speed peer-to-
CV	controlled variable or control valve		peer link)
CVAAS	cold vapor atomic absorption spectroscopy	DHCP	dynamic host configuration protocol
CVF	circular variable filters	DI	discrete (digital) input
cvs	comma-separated variables	dia	diameter; also $D$ and $\phi$
CW	clockwise	DIAC	dedicated inquiry access code
CWA	Clean Water Act	DIR	diffused infrared
CWR	cooling water return	DIS	draft international standard
CWS	cooling water supply	DIX	Digital-Intel-Xerox (DIX is the original
CWT	centralized waste treatment		specification that created the de facto Ether-
			net standard; IEEE 802.3 came later, after
	D		Ethernet was established)
d	1) derivative; 2) differential, as in dx/dt;	d(k)	unmeasured disturbance
u	3) deci, prefix meaning 0.1; 4) depth; 5) day	D(k)	measured disturbance
D	diameter; also dia and $\phi$ or derivative time	DLÉ	data link escape
D	of a controller or distillate flow rate	DLL	dynamic link library
DA	data access or direct action or difference in	DLPD	digital light processor display
DA		Dm or dm	decimeter
D/4	aeration	DM OI dill	delta modulation
D/A	digital-to-analog		
DAC	device access code or digital-to-analog	DMA	dynamic mechanical analyzer or direct mem-
	converter	DMC	ory access
DACU	data acquisition and control unit	DMC	dynamic matrix control(ler)
DAE	differential algebraic equation	DMFC	direct methanol conversion fuel cell
DAMPS	digital advanced mobile phone system	DMM	digital multi-meter
DAS	data acquisition system	DN	diameter nominal, the internal diameter of
DB or dB	decibels		a pipe in rounded millimeters
dBa	decibels with "A" weighing to approximate	DO	dissolved oxygen or discrete (digital) output
	the human ear	DOAS	differential optical absorption spectroscopy
DBB	double-block and bleed	d/p cell	differential pressure transmitter (a Foxboro
DBPSK	differential binary phase shift keying		trademark)
DC or dc	direct current	DP	decentralized peripheral
DC	diagnostic coverage	DPC	damper position controller
DCAC	direct contact after cooler	DPCM	differential pulse code modulation
DCE	data communications equipment	DPD	<i>N,N</i> -Diethyl- <i>p</i> -phenylenediamine
DCOM	distributed COM	DPDT	double pole double throw (switch)
DCS	distributed control system	dpi	dots per inch
DD	data definition or device description	DPS	differential pressure switch
		DQPSK	differential quadrature phase shift keying
D/DBP	disinfectants/disinfection byproducts	DR DR	decay ratio
DDC	direct digital control	DSB	double side band
DDE	dynamic data exchange		
DDL	device description language (an object-	DSL	digital subscriber line
	oriented data modeling language currently	DSN	distributed sensor network
	supported by PROFIBUS, FF, and HART)	DSP	digital signal processing
DEDED	chlorine dioxide treatment-caustic extrac-	DSR	direct screen reference
	tion-chlorine dioxide treatment-caustic	DSSS	direct sequence spread spectrum
	extraction-chlorine dioxide treatment	DST	dirty service trim
deg	degree; also $^{\circ}$ ( $\pi/180$ rad)	DSTM	dual-scan twisted nematic
DEMUX	demultiplexer	DT or dt	dead time (second or minutes) or delay time
Deoxo	deoxidation unit	DTB	draft tube baffle
DES	data encryption standard	DTC	digital temperature compensation or dead
DF	direction of flow		time compensator
DFIR	diffused infrared	DTD	document type definition
DFR	digital fiber-optic refractometer	DTE	data terminal equipment
DFT	digital (or discrete) Fourier transforms	DTGS	deuterated tryglycine sulfate
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DTI	die de Ameneisten le eie	- (1-)	for the also area
DTL DTM	diode-transistor logic	e(k) E.L.	feedback error
DIM	device type manager (an active-X component for configuring an industrial network	E.L. ELD	elastic limit or enthalpy logic
	6 6		electroluminescent display
DII	component; a DTM "plugs into" an FDT)	Em	minimum error
DU	dangerous component failure occurred in	EM EME	equipment module
DV	leg but is undetected	Emf or EMF	1) electromotive force (volts); 2) electro-
DV	disturbance variable	E) (I	motive potential (volts)
DVC	digital valve control or discrete valve coupler	EMI	electro-magnetic interference
DVM	digital voltmeter	EMI/RFI	electromagnetic and radio frequency
DWS	dewatered sludge		interference
		em(k)	process/model error
	_	EN	European standard
	E	ENB	Ethernet card
e	1) error; 2) base of natural (Naperian) log-	EP	evolutionary programming or equipment
	arithm; 3) exponential function; also exp		phase
	$(-x)$ as in $e^{-x}$	EPA	enhanced performance architecture
E	1) electric potential in volts; 2) scientific	EPC	engineering-procurement-construction
	notation as in $1.5E - 03 = 1.5 \times 10^{-3}$ ; 3) tray		(firm or industry)
	efficiency in distillation	EPCM	engineering, procurement, and construc-
E{.}	expected value operator		tion management (companies)
E&I	electrical and instrumentation	EPDM	ethylene propylene diene terpolymer
EA	evolutionary algorithm or exhaust air	EPROM	erasable programmable read only memory
EAD	exhaust air damper	EPS	electronic pressure scanner, encapsulated
EAF	exhaust air fan		postscript file, emergency power supply, or
EAI	enterprise application integration		expanded polystyrene
EAM	enterprise asset management	EPSAC	extended prediction self-adaptive controller
EAPROM	erasable alterable programmable read-only	EQ or eq	equation
	memory	ER	external reset
EBCDIC	extended binary code for information	ERM	enterprise resource manufacturing
	interchange	ERP	enterprise resource planning or effective
EBR	electronic batch records		radiated power
ECD	electron capture detector	ERW	electric-resistance-welded
ECG	electrocardiogram	ES	evolutionary strategy
ECKO	eddy-current killed oscillator	ESD	emergency shutdown (system)
ECLiPS	English control language programming	ESN	electronic serial number
ECEN 9	software	ESP	environmental simulation program
ECN	effective carbon number	ETFE	ethylene-tetrafluoroethylene copolymer
ECTFE	ethylene chloro-tetra-fluoro-ethylene (Halar)		(Tefzel)
ED	explosive decompression	ETM	elapsed time meter
EDD	electronic device description	ETMI	expected total mass input
EDS	electronic data sheet (DeviceNet)	ETMP	expected total mass produced
EDTA	ethylenediaminetetraacetic acid	ETS	equivalent time sampling
EDIA	energy dispersive x-ray fluorescence	EU	engineering unit
E/E/PE	electrical/electronic/programmable	EVOP	evolutionary operation or evolutionary
E/E/FE	electronic	LVOI	optimum
E/E/DEC		EWMA	exponentially weighed moving average
E/E/PES	electrical/electronic/programmable electronic	Exp	exponential function as in exp $(-at) = e^{-at}$ ;
EEDDOM	system	Lxp	also $e$
EEPROM	electrically erasable programmable read		also e
EED	only memory		F
EFB	external feedback	Е	-
EFD	engineering flow diagram	F	frequency; also freq or filter, also farad,
EFRVD	expected flow rate value through dryer		symbol for derived SI unit of capacitance,
e.g.	exempli gratia: for example		ampere $\cdot$ second per volt, A $\cdot$ s/V, also feed
EHC	electro-hydraulic control or extended hori-	0.15	flow rate
EID (	zon adaptive controller	°F	Fahrenheit degrees [ $t^{\circ}$ C = ( $t^{\circ}$ F – 32)/1.8]
EHM	equipment health management	FAH	flow alarm, high

FAL	flow alarm, low	FM	frequency modulated or Factory Mutual
FAN	fuzzy, analytical intelligence, neural network	FMAX	maximum feed availability
FARM	frame acceptance and reporting mechanism	<b>FMCW</b>	frequency-modulated carrier wave
FAT	factory acceptance testing	FMEA	failure mode and effects analysis
FB	friction bound	FMEDA	failure modes, effects, and diagnostic analysis
FBAP	function block application process (FF)	FMS	1) fieldbus message specification; 2) field-
FBD	**	11115	
	function block diagram	FNC	bus messaging services/system
FBG	fiber bragg grating		function byte
FBT	fire box temperature	FO	1) fiber optic; 2) fail open
FC	1) flow controller; 2) fail closed; 3) forced	FOP	fiber optic probe
	circulation; 4) fire command panel	FOPDT	first order plus dead time
FCC	fluid catalytic cracking unit	FOSS	first order system series
FCCU	fluidized catalytic cracking unit	FOV	field of view
FCOR	filtering and correlation (method)	fp or f.p.	freezing point
FCS	frame check sequence or field control system	FPC	fine particle content
FCV	flow control valve	FPD	flame photometric detector
FD	forced draft	FPGA	field programmable gate arrays
FDE	fault disconnection electronics	FPM or fpm	feet per minute (= 0.3048 m/m)
FDL	fieldbus data link	fps or ft/s	feet per second (= 0.3048 m/s)
FDM	frequency division multiplexing	FRC	flow recording controller
			ě
FDMA	frequency division multiple access	FRM	frequency response method
FDS	flame detection system or fines density	FRO	full range output
	sensor	FS or fs	full scale or flow switch or full stroke
FDT	field device tool (a MS Windows-based	FSA	fault state active
	framework for engineering and for config-	FSC	fail safe controller
	uration tools)	FSH	flow switch, high
FE	1) final element; 2) flow element; 3) filter	FSHL	flow switch, high-low
	effluent	FSK	frequency shift keying
FED	field emission display	FSL	flow switch, low
FEED	front end engineering and design	FSNL	full speed no load
FEGT	furnace exit gas temperature	FSPF	first stage permeate flow
FEP	fluorinated ethylene propylene	FST	full stroke testing
FES	fixed end system	FT	Fourier transfer or flow transmitter
FF	1) Foundation Fieldbus; 2) feedforward	FTA	fault tree analysis
FF-HSE	Foundation Fieldbus, high-speed Ethernet	FTC	fail to close
FFIC	flow ratio controller	FTIR	Fourier transform infrared
FFT	fast Fourier transform	FTL	fuzzy technology language
FGB	fiber bragg grating	FTNIR	Fourier near infrared
FGD	flue gas desulfurization	FTO	fail to open
FGR	flue gas recirculation	FTP	file transfer protocol
FH	frequency hopping	FTS	fault tolerant system
Fhp	fractional horsepower (e.g., <sup>1</sup> / <sub>4</sub> HP motor)	FTU	formazin turbidity unit
FHSS	frequency hopped spread spectrum	FW	finished water
FI	1) flow indicator; 2) fail intermediate;		
	3) filter influent		G
FIA	flow injection analyzer	Œ	acceleration due to gravity (= 9.806 m/s <sup>2</sup> )
FIC	flow indicator controller	g	or conductivity
FID	flame ionization detector	C	· · · · · · · · · · · · · · · · · · ·
FIE	flame ionization element	G	giga, prefix meaning 10° or process gain or
		C 4	conductance
FIFO	first-in, first-out	GA	genetic algorithm
Fig. or FIG.	figure	gal.	gallon (= 3.785 liters)
FIR	finite impulse response (model)	GB	gigabyte, 1,000,000,000 bytes
FISCO	Fieldbus Intrinsic Safety COncept	GbE	gigabit Ethernet
fl.	fluid	Gbps or GBPS	gigabits per second
FL	fail last (position)	$G_{c}$	feedback controller transfer function
fl. oz.	fluid ounces (= 29.57 cc)	GC	gas chromatograph

g-cal	gramcalorie, q.v.; also cal	HAZOP	HAZard and OPerability studies
GD	group of dryers	HC	horizontal cross-connect or heating coil
$G_d$	unmeasured disturbance transfer function	HCN	hydrogen cyanide
$G_{D}$	measured disturbance transfer function	HD	hot deck
$G_D$	approximate feedforward transfer function	HEC	header error check
D	model	HF	hydrogen fluoride or hydrofluoric acid
GEOS	geosynchronous Earth orbit satellites	HFE	human factors engineering
GFC	gas filter correlation	HFT	hardware fault tolerance
$G_{ m ff}$	feedforward controller transfer function	HGBP	hot gas bypass
GHz	giga-Hertz	HGC	hydraulic gap control
GI	galvanized iron	hh	suffix indicating heavier key component
GIAC	general inquiry access code	HH	high-high
GLR			
	gas-to-liquid ratio	hhv	higher heating value
G-M	Geiger–Mueller tube, for radiation moni-	HIC	hand indicating controller
C.	toring	HIPPS	high-integrity pressure protection system
$G_{\rm m}$	model transfer function	HIPS	high-integrity protection systems
GMC	generic model control	HIS	human interface station
GMR	giant magneto resistive	HIST	host interface system test
GMV	generalized minimum variance	HK	heavy key
GOSUB	go to subroutine	HLL	high-level logic
GOX	gaseous oxygen	HLLS	high-low limit switch
GP	genetic programming	HMI	human-machine interface
$G_p$	process transfer function or process gain	HMP	hexametaphosphate
GPa	giga-Pascal (10 <sup>9</sup> Pa)	HMSD	hexamethyldisiloxane
GPC	generalized predictive control	hor.	horizontal
GPCP	general process control programming	HP or hp	horsepower (U.S. equivalent is 746 W) or
GPH or gph	gallons per hour (= 3.785 lph)		high pressure
GPC	generalized predictive controller	HPBF	high performance butterfly valves
GPM or gpm	gallons per minute (= 3.785 lpm)	HPD	hybrid passive display
GPS	global positioning satellite	HPLC	high pressure (or precision) liquid chroma-
gr	gram		tography
grn	green (wiring code color for grounded	hr	hour
	conductor)	H&RA	hazard & risk analysis
GSC	gas-solid chromatography	HRH	hot reheat
GSD	Profibus version of an electronic data sheet	HRL	hysteresis, repeatability and linearity
GT	gas turbine	HRSG	heat recovery steam generator
GTG	gas turbine generator	HS	hand switch or hot standby
GTO	gate-turn-off thyristor	HSE	high-speed Ethernet (host-level fieldbus)
GUI	graphical user interface	HSF	hydrofluosilic acid
GWR	guided wave radar	his	human system interface
Gy	gray, symbol for derived SI unit of absorbed	HTG	hydrostatic tank gauging
Gy	dose, joules per kilogram, J/kg	HTML	hyper text markup language
	dose, joules per knogram, J/kg	HTTP	hyper text markup language hyper text transfer protocol
	u		**
•	H	HV HVAC	high voltage
h	1) height; 2) hour; 3) suffix indicating heavy		heating, ventilation, and air conditioning
	key component; 4) hour	H/W	hardware
Н	1) humidity expressed as pounds of moisture	HWD	height, width, depth
	per pound of dry air; 2) henry, symbol of	HWP	hot water pump
	derived SI unit of inductance, volt · second	HWS	hot water supply
	per ampere, $V \cdot s/A$ ; 3) high; 4) humidifier	Hz	Hertz, symbol for derived SI unit of fre-
H1	field-level fieldbus, also refers to the 31.25		quency, one per second (l/s)
	Kbps instrinsically safe SP-50, IEC61158-		
	2 physical layer		1
HAD	holographic autostereoscopic display or	I	integral time of a controller in units of time/
	historical data access		repeat
HART	highway addressable remote transducer	IA	instrument air or impedance amplifier

IAC	inquiry access code	ITSE	integral of squared error multiplied by
IAE	integral of absolute error		time
IAQ	indoor air quality	ITT	intelligent temperature transmitters
ibid	in the same place	IWF	initial weighing factor
IC	integrated circuitry, intermediate cross-	IXC	intereXchange carrier
	connect, initial condition, or inorganic carbon		
I&C	instrumentation and control or information		
icc	and control	_	J
ICA		J	joule, symbol for derived SI unit of energy,
ICA	independent computing architecture		heat or work, newton-meter, $N \cdot m$
ICCMS	inadequate core cooling monitoring system	JB	junction box
ICMP	Internet control message protocol	JIT	just-in-time manufacturing
ICP	inductively coupled plazma	JSR	jump to subroutine
ID	inside diameter or induced draft	JT	Joule Thomson
IDCOM	identification command	JTU	Jackson turbidity unit
i.e.	id est: that is		<b>,</b>
IE	integral error		K
I&E	instrument and electrical	_	
IEC	interactive evolutionary computation	k	kilo, prefix meaning 1000
IEH	Instrument Engineers' Handbook	K	coefficient, also dielectric constant or pro-
IETF	Internet engineering task force		cess gain
IF	intermediate frequency	°K or K	degrees Kelvin, symbol for SI unit of tem-
IFS	initiate fault state		perature or process gain (dimensionless)
IGBT		Kbs, Kbps	kilo bits per second
	insulated gate bipolar transistor	KBs	kilo bytes per second
IGV	inlet guide vane	k-cal	kilogram-calories (= 4184 J)
IIS	Internet information server	kg	kilogram, symbol for basic SI unit of mass
IL	instruction list	kg-m	kilogram-meter (torque, = 7.233 foot-
ILD	instrument loop diagrams	kg-III	pounds)
IMC	internal model control or injection cycle	KHP	± 1
iMEMS	integrated micro-electro-mechanical system		potassium acid phthalate
IN	insertion	kip	thousand pounds (= 453.6 kg)
in.	inch (= 25.4 mm)	kJ	kiloJoule
IrGaAs	iridium gallium arsenide	km	kilometer
in-lb	inch-pound (= $0.113 \text{ N} \times \text{m}$ )	KOH	potassium hydroxide
I/O	input/output	$K_p$	proportional gain of a PID controller
IP IP	Internet protocol or ionization potential or	kPa	kilo-Pascals
11	intermediate pressure	$K_u$	ultimate controller gain
I-P		kVA	kilovolt-amperes
	current-to-pressure conversion	KVSP	Kalrez valve stem packing
IPA	isopropyl alcohol	kW	kilowatts
IPL	independent protection layer	KWD	kilowatt demand
IPS	in-plane switching	kWh	kilowatt-hours (= $3.6 \times 10^6$ J)
IPTS	international practical temperature scale	KWIC	Kilowatt indicating controller
IR	infrared	RWIC	Knowatt indicating controller
IRQ	interrupt request queue		
IS	intermediate system or intrinsic safety		L
ISAB	ionic strength adjustment buffer	1	suffix indicating light key component
ISE	integral of squared error or ion selective	L	1) liter (= $0.001 \text{ m}^3 = 0.2642 \text{ gallon}$ ), 2)
	electrode		length; 3) inductance, expressed in henrys;
ISFET	ion-selective field effect transistor		4) low; 5) reflux flow rate
ISM	industrial, scientific, medical	L2F	laser two-focus anemometer
ISP	Internet service provider or interoperable	Lab	CIE functions for lightness, red/green,
101	system provider	Luo	blue/yellow
IТ		LACM	· · · · · · · · ·
IT	information technology (as in IT manager	LACM	local automatic control mode
TTAE	or IT department) or current transmitter	LAG	liquid argon
ITAE	integral of absolute error multiplied by	LAN	local area network
	time	LAS	link active scheduler (FF)
ITD	indium tin oxide	Lat	latitude

Lb or lb	pound (= 0.4535 kg)	LPC	1) large particle content; 2) line predictive
lbf	pound force	21 0	coding
lbm	pound mass	LPG	1) liquified petroleum gas; 2) liquified pro-
LC	level controller or liquid chromatography		pane gas
LCD	liquid crystal display	lph	liters per hour (0.2642 gph)
Lch	CIE functions for lightness, chroma, hue	lpm	liters per minute (0.2642 gpm)
LCI	load commutated inverter	LPR	linear polarization resistance
LCM	life cycle management	LPV	linear parameter varying
LCSR	loop current step response	LQG	linear quadratic Gaussian
LCV	level control valve	LRC	1) longitudinal redundancy check; 2) level
LD	ladder diaphragm or load		recording controller
LDA	laser Doppler anemometer	LRL	lower range limit
LDAD	load distribution algorithm (dryers)	LRV	lower range value
LDAW	load distribution algorithm (wells)	LS	1) level switch; 2) lime slurry
LDP	large display panel	LSB	least significant bit
LEC	local exchange carrier or lower explosive	LSI	large-scale integrator
	limit	LSL	lower specification limit
LED	light emitting diode	LTI	linear time-invariant
LEL	lower explosive limit	LV	low voltage
LEO	low Earth orbit satellites	LVDT	linear variable differential transformer
LEPD	light emitting polymer display	LVN	limiting viscosity number
LF	linear feet	lx	lux, symbol for derived SI unit of illumi-
L/F	reflux-to-feed ratio	1/1	nation, lumen per square meter, lm/m <sup>2</sup>
LFL	lower flammable limit		nation, rainen per square meter, mum
LGR	liquid-to-gas ratio		
LI	level indicator		М
LIC	level indicator controller	m	1) meter, symbol for basic SI unit of length;
LIDAR	laser induced doppler absorption radar or	111	2) milli, prefix meaning 10 <sup>-3</sup> ; 3) minute
LIDITIK	light detection and ranging		(temporal); also min
LIFO	last-in first-out	M	1) thousand (in commerce only); Mach
lim. or lim	limit	1V1	number; 2) molecular weight; 3) mole;
lin.	linear		4) mega, prefix meaning 10 <sup>6</sup>
LIN		mA or ma	
	liquid nitrogen		milliamperes (= 0.001 A)
liq. LK	liquid	MAC	medium access control or model algorithm control or main air compressor
ll	light key	MACID	medium access control identifier
	suffix indicating lighter key component	MACID	
L/L	lead-lag	MAE	minimum absolute error
LL	leased lines or low-low	MAOP	maximum allowable operating pressure
LLC	logical link control	MAP	manufacturing automation (access) protocol
LLK	lighter than light key	MAU	media access unit
LLOI	low-level operator interface	MAWP	maximum allowable working pressure
lm	lumen, symbol for derived SI unit of lumi-	Max	maximum
1	nous flux, candela.steradian, cd.sr	MB	megabyte, 1,000,000 bytes or megabits
ln	Naperian (natural) logarithm to base e	MBC	model-based control
LNG	liquified natural gas	MBPC	model-based predictive control
LO	lock open or local override	MBPS, mbps,	megabits per second
LOC	limiting oxygen concentration	Mbps, Mbs,	
log or log <sub>10</sub>	logarithm to base 10; common logarithm	MBs	
LOI	local operation interface	MC	main cross-connect
long.	longitude	MCFC	molten carbonate fuel cell
LOPA	layers of protection analysis	mCi or mC	millicuries (= 0.001 Ci)
LOR	local-off-remote	m.c.p.	mean candle power
LOS	line of sight	MCP	main control panel or manual control mode
LOX	liquid oxygen	MCR	master control relay
LP	1) liquified petroleum; 2) linear program-	MCT	mercury cadmium telluride or minimum
	ming; 3) low pressure		cycle time

MDBS	mobile data base station	MODEM	modulator/demodulator
MDIS	mobile data intermediate system	MOEA	multiobjective evolutionary algorithm
MDPH	maximum pressure difference (header	MOGA	multiobjective genetic algorithm
	towell)	MOGP	multiobjective genetic programming
m/e	mass-to-energy ratio	mol	mole, symbol for basic SI unit for amount
med.	medium or median		of substance
MEDS	medium Earth orbit satellites	mol.	molecules
MEMS	micro electro mechanical structures	MOON	M out of N voting system
m.e.p.	mean effective pressure	MON	motor octane number
MES	manufacturing execution system, manage-	MOS	metal oxide semiconductor
MES	ment execution system, or mobile end station	MOSFET	metallic oxide semiconductor field-effect
MaV	•	MOSFEI	transistor
MeV	mega-electron volt	MOV	
MF	micro filtration	MOV	metal oxide varistor or motor-operated
MFAC	model free adaptive control	MONG	valve or most open valve
MFC	model free control or microbiological fuel	MOVC	most open valve control
	cell	mp or m.p.	melting point
MFD	mechanical flow diagram	MP	medium pressure
MFE	magnetic flux exclusion	MPa	mega Pascal (106 Pa)
mfg	manufacturer or manufacturing	MPC	model predictive control
MFI	melt flow index or melt factor index	MPEC	mathematical problem with equilibrium
MFR	manual flow rate		constraints
mg	milligrams (= 0.001 gr)	MPFM	multiphase flowmeter
MGD	million gallons per day	mph or MPH	miles per hour (1.609 km/h)
mg/l	milligrams per liter	MPHC	model predictive heuristic controller
mho	outdated unit of conductance, replaced by	MPM or mpm	meters per minute
	Siemens $(S)$ , $q.v$ .	mps or m/s	meters per second
MHz	megahertz	MPS	manufacturing periodic/aperiodic services
mi	miles (= 1.609 km)	Mpy	mills per year
MI	melt index	mR or mr	milliroentgens (= 0.001 R)
MIB	management information base	MRAC	model reference adaptive control
micro	prefix = $10^{-9}$ ; also $\mu$ (mu) or $\mu$ m and some-	mrd	millirads (= 0.001 rd)
	times u, as in ug or µg, both meaning	mrem	milliroentgen-equivalent-man
	microgram (= 10 <sup>-9</sup> kg)	MRP	material requirement planning or manufac-
micron	micrometer (= $10^{-6}$ m)	11111	turing resource planning or material/product
MIE	minimum ignition energy		planning
MIMO	multiple-input multiple-output	me	milliseconds (= 0.001 s)
MIMOSA	machinery information management open	ms MS	
MIMOSA			mass spectrometer or Microsoft
	system alliance	MSA	metropolitan statistical areas
min	1) minutes (temporal); also m; 2) mini-	MSB	most significant bit
MID	mum, 3) mobile identification number	MSC	monitoring and sequential control
MIR	multiple internal reflection	MSD	most significant digit
MIS	management information system	MSDS	material safety data sheet
ml	milliliters (= $0.001 l = 1 cc$ )	MT	measurement test
MLR	multiple linear regression	MTBE	methyl tertiary butyl ether
mm	millimeters (= 0.001 m) or millimicron	MTBF	mean time between failures
	$(=10^{-9} \text{ m})$	MTSO	mobile telephone switching offices
MMAC	multiple model adaptive control	MTTF	mean time to fail
mmf	magnetomotive force in amperes	MTTFD	mean time to fail dangerously
MMI	man-machine interface	MTTFS	mean time to spurious failure
mmpy	millimeters per year	MTTR	mean time to repair
MMS	machine monitoring system or manufactur-	MTU	master terminal unit
	ing message specification	MUX	multiplexer
MMSCFD	million standard cubic feet per day	MV	minimum variance or manipulated variable
MMV	manually manipulated variable	MVA	multiple-domain vertical alignment
MOC	management of change	MVC	minimum variance controller or multi-
MODBUS	a control network		variable control
-			

MW	megawatts (= $10^6 \text{ W}$ )	NS	nominal pipe size, the internal diameter of
MWC	municipal waste combustors		a pipe in inches
MWD	molecular weight distribution	NTC	negative temperature coefficient
	2	NTP	network time protocol or normal tempera-
			ture and pressure, corresponding to 1 atm.
	N		absolute (14.7 psia) and 0°C (32°F)
		NTSC	national television standards code
n	1) nano, prefix meaning 10 <sup>6</sup> ; 2) refractive		
	index; 3) number of trays	NTU	nephalometric turbidity unit
N	newton, symbol for derived SI unit of	NUT	network update time
	force, kilogram-meter per second squared,		_
	$kg \cdot m/s^2$		0
$N_0$	Avogadro's number (= $6.023 \times 10^{23} \text{ mol}^{-1}$ )	OA	operational amplifier or outside air
N-16	nitrogen-16	OAC	operator automatic control
NA	numeric aperture	OAD	outside air damper
NAAQS	National Ambient Air Quality Standards	OCD	orifice-capillary detector
NAP	network access port/point	OD	outside diameter or oxygen demand
NARMAX	nonlinear autoregressive w/exogenous mov-	ODBC	open database connectivity or communica-
1 (1 22 (1) 11 21 2	ing average input nodes	0220	tion
NARX	nonlinear autoregressive w/exogenous input	OEM	original equipment manufacturer
11/11/21	nodes	OES	optical emission spectrometer
NAT	network address translation	oft or OFT	optical fiber thermometry
NB			•
NB	nominal bore, internal diameter of a pipe	ohm	unit of electrical resistance; also $\Omega$ (omega)
MDI	in inches	OI	operator interface
NBJ	nonlinear Box-Jenkins	OI-F	operator interface for filtering
NC or N/C	normally closed (switch contact)	OI-P	plant operator interface
NC	numeric controller	OIU	operator interface unit
NCAP	networking capable application processors	OJT	on-the-job training
NDIR	nondispersive infrared	OL	overload
NDM	normal disconnect mode	OLE	object linking and embedding
NDT	nondestructive testing	OLED	organic LED
NEC	National Electrical Code	OLE_DB	object linking and embedding data base
NESC	National Electrical Safety Code	OMAC	open modular architecture controls
NEXT	near end cross-talk	OMMS	optical micrometer for micro-machine
nF	nano filtration	ON	octane number
NFI	near field imaging	OP	output or operating point
NFIR	nonlinear finite impulse response	OPAM	online plant asset management
NIC	network interface card	OPC	object link embedding (OLE) for process
NIP	normal incident pyrheliometer	ore	control
NIR	near infrared	OPEX	OPerational EXpenditure
Nm or nm	nanometer (10 <sup>-9</sup> meter)	OP-FRIR	open path Fourier-transform infrared
	nuclear magnetic resonance	OP-FKIK OP-HC	
NMR	•		open path hydrocarbon
NMV	normal mode voltage	OP-TDLAS	open path tunable diode-laser absorption
NO or N/O	normally open (switch contact)	OD 1111	spectroscopy
NOE	nonlinear output error	OP-UV	open path ultraviolet
NPN	transistor with base of p-type and emitter	Or	orange (typical wiring code color)
	and collector of n-type material	OREDA	Offshore Reliability Data Handbook
NPS	nominal pipe size, the internal diameter of	ORP	oxidation-reduction potential
	a pipe in inches	OS	operator station or operating system
NPSH	net positive discharge head	OSFP	open shortest path first
NPSHA	net positive discharge head available	OSI	open system interconnection (model)
NPSHR	net positive discharge head required	OSI/RM	open system interconnect/reference model
NPT	network time protocol	OT	operator terminal or open tubular
NR	narrow range	OTDR	optical time domain reflectometer
NRM	normal response mode	OTSG	once-through steam generator
NRZ	nonreturn to zero (NZR refers to a digital	OZ OZ	ounce (= 0.0283 kg)
•	signaling technique)	OZ	ozone
		~ <b>_</b>	== = ±±+ <b>=</b>

P P P 1) pressure; 2) pico, prefix meaning [0] 12, per sure element of the polyethylene or penalty on error or pressure element pressure cautiful problem. PEE pressure cautiful problem pressure cautiful problem pressure cautiful problem. PEE proportion exchange membrane fuel cell or polyment electrolyte membrane fuel cell or	OZA	agamatad ain	PDU	mustaged data unit
P  I) pressure; 2) pico, prefix meaning 10 <sup>-13</sup> , also resistivity  P&IID piping and instrumentation diagram pascal, symbol for derived \$1 unit of stress and pressure, newtons per square meter, N/m²  PA plant air, phase angle, or pole assignment PAC phase alternating line or pressure alarm, low maion controllers  PAH pressure alarm, high pressure alarm, low pressure different process flow diagram or probability of failure on demand pressure alarm, low pressure different process flow diagram or probability of failure on demand pressure indicator process gas chromatograph proc		ozonated air		protocol data unit
P I) pressure: 2) pico, prefix meaning 10-12, also resistivity  P&IID piping and instrumentation diagram piping and pressure, newtons per square meter, N/m² pascal, symbol for derived S1 unit of stress and pressure, newtons per square meter, N/m² pascal, symbol for derived S1 unit of stress and pressure, newtons per square meter, N/m² path average concentration or process automation and pressure and path average concentration or process automation and path average concentration or process automation and controllers path average concentration or process automation and controllers path average concentration or process automation and controllers path average problem and controllers in process automation system (successor to DCS) or project application specification per pondical and of a controller in % (100%/controller gain) or push button personal computer (MS Windows based) or pressure controller or polychlorinated dibenzo-p-dioxin polychlorinated dibenzo-polychlorinated polychlorinated dibenzo-polychlorinated dibenzo-polychlorinated dibenzo-polychlorinated dibenzo-polychlorina	OZW	ozonated water		
As a resistivity   piping and instrumentation diagram   pized, symbol for derived \$1 unit of stress and pressure, newtons per square meter, N/m²   part as a pressure, newtons per square meter, N/m²   part air, phase angle, or pole assignment path average concentration or process automation controllers   process automation system (successor to DCS) or project application specification proportional and of a controller in \$\frac{P}{100}\$   process automation system (successor to DCS) or project application specification proportional band of a controller in \$\frac{P}{100}\$   process automation system (successor to DCS) or project application specification proportional band of a controller in \$\frac{P}{100}\$   process automation system (successor to DCS) or project application specification proportional band of a controller in \$\frac{P}{100}\$   proportional and of a controller in \$\frac{P}{100}\$   proportional and particle project by a proportional and particle project polychorinated dibenze-p-dioxin project polychorinated dibenze-p-dioxin project polychorinated dibenze-p-dioxin proportional and particle proportional and positive displacement or proportional and positive displacement or proportional a		P		sure element
PAID   piping and instrumentation diagram   pascal, symbol for derived SI unit of stress and pressure, newtons per square meter, N/m²   PEM   PEMFC   polysmer electrolyte membrane fuel cell or polymer electrolyte electrony fuel cell or polymer electrolyte electrony fuel process dural electrolyte electrony fuel process fuel cell electrolyte per porgammane electron electrolyte field.  PFA	p	1) pressure; 2) pico, prefix meaning 10 <sup>-12</sup> ,		
Pa pascal, symbol for derived SI unit of stress and pressure, newtons per square meter, N/m²  PA plant air, phase angle, or pole assignment path everage concentration or process automation controllers path average concentration or process automation controllers phosphoric acid fuel cell programmable electronic system per-fluoro-alkoxy copolymer (a form of Tedno) process automation system (successor to DCS) or project application specification process automation system (successor to DCS) or project application specification process automation system (successor to DCS) or project application specification process automation system (successor to DCS) or project application specification process automation system (successor to DCS) or project application specification proportional band of a controller in % (100%-controller gain) or push button process automation system or pressure controll experimental process process are controller programmaneutron activation analysis principal component analysis principal component analysis principal computer control system process control system process control system process control system or personal communication services process control system or prosonal communication services process control system or prosonal didivative or percentage detected or positive displacement or proportional and derivative or pressure control valve proportional and derivative or percentage detected or positive displacement or proportional and derivative or percentage detected or positive displacement or proportional and derivative or percentage detected or positive displacement or proportional and derivative or percentage detected or positive displacement or proportional and derivative or percentage detected or positive displacement or proportional and derivative or percentage detected or positive displacement or proportional and derivative or percentage detected or positive displacement or proportional and derivative or percentage detected or positive displacement or proportional and derivative o		also resistivity		
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PA PA plant air, phase angle, or pole assignment phace plant air, phase angle, or pole assignment phace and pharting phace and phace are processed phase and phosphoric acid fuel cell pharting phosphoric acid fuel cell phosphoric fuel cell phosphoric acid fuel cell phosphoric acid fuel cell phosphoric acid fuel cell phosphoric fuel cell phosphoric fuel fuel fuel fuel fuel fuel fuel fuel	Pa	pascal, symbol for derived SI unit of stress	PEMFC	
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mation controllers per-fluoro-alkoxy copolymer (a form of PAFC phosphoric acid fuel cell pressure alarm, high pressure alarm, high pressure alarm, high pase alternating line or pressure alarm, low pulse amplitude modulation path pash presonal area network pash pascal-second, a viscosity unit pash project application specification path path project application specification path path proportional band of a controller in % (100%/controller gain) or push button personal computer (MS-Windows based) or pressure controller progressure controller progressure controller progressure correction control progressure correction control progressure correction control mode path principal component analysis profice progressure correction control mode path project progressure correction control mode path project progressure correction control mode path proportional and integral or pressure indicator progressure correction control mode path proportional and integral or pressure indicator progressure indicator progressure indicator progressure indicator progressure indicator progressure indicator progressure indicator proportional and integral or pressure indicator progressure indicator indicator progressure indicator indicator indicator progressure indicator	PA	plant air, phase angle, or pole assignment		
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low   process flow diagram or probability of failure on demand   personal area network   personal one project application specification   personal composer (Indow/controller gain) or push button   personal computer (Ms-Windows based)   or pressure controller   personal computer (Ms-Windows based)   or pressure controller   principal component analysis   pi or pl   poiseuille, a viscosity unit   proportional and integral or pressure indicator   proportional and integral or pressure   personal computer control mode   pinging and instrument (diagram)   process personal computer control mode   pinging and instrument (diagram)   process necentration   proportional, integral, and derivative (control modes in a classic controller) or photo-indication services   percent; also %   p	PAH		PFC	•
PAM pulse amplitude modulation PAN personal area network Pas Pascal-second, a viscosity unit PAS process automation system (successor to DCS) or project application specification PAS process automation system (successor to DCS) or project application specification PB proportional band of a controller in % (100%/controller gain) or push button PC personal computer (MS-Windows based) or pressure controller PCA principal component analysis PCB printed circuit board PCC pressure correction control PI proportional and integral or pressure or pressure correction control mode PCC pressure correction control mode PCC pressure correction control mode PCC personal computer control system PCDD polychlorinated dibenzo-p-dioxin PCDF polychlorinated dibenzo-p-dioxin PCDF polychlorinated dibenzo furans PCB principal component regression PCR principal component regression PCR principal component regression PCR process control system or personal communication services PCT Patent Cooperation Treaty PCT Patent Cooperation Treaty PD positivité displacement or proportional and derivative or percentage detected or position detector PCR persure control valve PCT Patent Cooperation Treaty PDD positive displacement or proportional and derivative or percentage detected or position detector PCR persure control valve PCT persure control valve PCT Patent Cooperation Treaty PDD positive displacement or proportional and derivative or percentage detected or position detector PCR persure control valve PCR persure differential linear complementary PDD positive displacement or proportional and derivative or portable document file PLC programmable logic controller PDC pressure differential linear complementary PDD pulsed discharge detector PDLCP partial differential linear complementary PDD pulsed discharge detector PDLCP partial differential linear complementary PDD pulsed discharge detector PDLCP partial differential linear complementary PDD plase duration modulation PMM pedictive maintenance PMA physical layer signaling or partial least square	PAL	phase alternating line or pressure alarm,		
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phase difference sensor PMF probability mass function				
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D) II CD		DTC	
PMLCD	passive matrix LCD	PTC	positive temperature coefficient or pro-
PMMC	permanent magnet moving coil		grammable telemetry controller
PMS	plant monitoring system	PTFE	polytetrafluoroethylene (conventional Teflon)
PMT	photo-multiplier tube or photometer tube	PU	per unit
PN	pressure, nominal	PUVF	pulsed ultraviolet fluorescence
PNP	transistor with base of n-type and emitter	PV	process variable (measurement) or the
	and collector of p-type material		HART primary variable
PO	polymer	PVC	polyvinyl chloride
POF	positive opening feature	PVDF	polyvinylidene fluoride
POL	problem oriented language	PVHI	process variable high (reading or
POPRV	pilot operated pressure relief valve		measurement)
POTW	publicly owned treatment works	PVLO	process variable low (reading or
PP	polypropylene or pole placement		measurement)
ppb or PPB	parts per billion	PW	private wire
PPC	process procedure chart	PWM	pulse width modulation
PPD	pounds per day	PWR	pressurized water reactor
ppm or PPM	parts per million or pulse position modulation	PZT	lead-zirconate-titanate ceramic
ppmV	volumetric parts per million		
PPP	point-to-point protocol		Q
ppt	parts per trillion	q	1) rate of flow; 2) electric charge in cou-
PRBS	pseudo random binary sequence	1	lombs, C
PRC	pressure recording controller or production	$q^{-1}$	backward shift operator
	cycle	Q	quantity of heat in joules, J or electric
PRD	pressure relief device		charge
Precip	precipitate or precipitated	°Q	Quevenne degrees of liquid density
PRV	pressure relief valve or pressure reducing	QA	quality assurance
	valve	QAM	quadrature amplitude modulation
PS	power supply (module) or pressure switch	QBET	quench boiler exit temperature
	or partial stroke	QCM	quartz crystal microbalance
PSA	pressure swing adsorption	QEV	quick exhaust valve
PSAT	pre-startup acceptance test	QMS	quality management system
PSD	power spectral density or photosensitive	QoS	quality of service
102	device	QPSK	quadrature phase shift keying
PSE	pressure scale effect	qt	quart (0.9463 liter)
PSG	phosphosilicate glass	q.v.	qual (0.5405 liter) quod vide: which see
PSH	pressure switch, high	QV	quaternary variable
PSI	pre-startup inspection	Q٧	quaternary variable
psi or PSI	pounds per square inch (= 6.894 kPa)		R
PSIA or psia	absolute pressure in pounds per square		radius; also rad
1 SIA OI psia	inch	r R	
PSID or psid	differential pressure in pounds per square	K	1) resistance, electrical, ohms; 2) resistance,
131D or psid	inch		thermal, meter-kelvin per watt, $m \cdot K/W$ ; 3)
PSIG or psig	above atmospheric (gauge) pressure in		gas constant (= $8.317 \times 10^7$ erg · mol <sup>-1</sup> ,°C <sup>-1</sup> );
1 51G of psig	pounds per square inch		4) roentgen, symbol for accepted unit of
PSK	phase shift keying		exposure to x and gamma radiation, (= $2.58 \times 10^{-4}$ G/L <sub>x</sub> )
PSL		?	10 <sup>-4</sup> C/kg)
PSM	pressure switch, low	$r^2$	multiple regression coefficient
	process safety management	Ra	radium
PSS	programmable safety system	RA	return air or reaction (failure) alarm or
PSSR	pre-startup safety review	D A CD I	reverse action
PST	partial stroke testing	RACM	remote automatic control mode
PSTN	public switched telephone network	Rad	1) radius; also r; 2) radian, symbol for SI
PSU	post-startup		unit of plane angle measurement or symbol
PSV	pressure safety valve		for accepted SI unit of absorbed radiation
pt	point or part or pint (= 0.4732 liter)	D.1.D.	dose, (= 0.01 Gy)
PT	pressure transmitter	RAD	return air damper
PTB	Physikalisch-Technische Bundesanstalt	RADAR	radio detection and ranging

DAID	and and and among of incommunity distance	D	mantian mata alama
RAID	redundant array of inexpensive disks	$R_r$	reaction rate, slope
RAM	random access memory	RRF	risk reduction factor
RASCI	responsible for, approves, supports, consults, informed	RRT	relative response time (the time required to remove the disturbance)
RAT	return air temperature	RS	recommended standard
RBC	remote base communication module	RSA	rural service areas
RCF	rotational centrifugal force	RSS	root sum squared
RCU	remote control unit	RSSI	received signal strength indicator
R&D	research and development	RTD	resistance temperature detector
RD	rupture disk	RTL	resistance-transistor logic
RDP	remote desktop protocol	RTO	real time optimization or operation
Re	Reynolds number	RTOS	real time operating system
REC	roll eccentricity compensation	RTR	remote transmission request
ReD	Reynolds number corresponding to a par-	RTS	<u> •</u>
ReD		RTS/CTS	ready (or request) to send
madan	ticular pipe diameter		request to send/clear to send
redox	oxidation–reduction	RTU	remote terminal unit
rem	measure of absorbed radiation dose by liv-	RUDS	reflectance units of dirt shade
	ing tissue (roentgen equivalent man)	RV	relief valve
rev	revolution, cycle	RVDT	rotary variable differential transformer
RF or rf	radio frequency or return fan	RVP	Reid vapor pressure
RFC	request for comment (an Internet protocol	RW	raw water
	specification) or rotational centrifugal force	RWF	raw water flow
	or rising film concentrator	RWS	remote work station
RFF	remote fiber fluorimetry		
RFI	radio frequency interference		S
RFQ	request for quote	S or s	1) second, symbol for basic SI unit of time;
RG	relative gain		2) Laplace variable; 3) Siemens (Siemens/
RGA	residual gas analyzer or relative gain array		cm), symbol for unit of conductance,
	or relative gain analysis		amperes per volt, A/V; 4) separation
RGB	red, green, and blue	SA	supply air
RGM	reactive gaseous mercury	SAN	surface acoustic wave
RH	relative humidity or reheated or reheater	SAP	service access point
RHA	relative humidity alarm	SASFC	single automatic stage flow control
RHC	receding horizon adaptive controller or	sat.	saturated
	reheat coil	SAT	site acceptance test or supervisory audio
RHCV	relative humidity control valve	5711	tone or supply air temperature
RHE	relative humidity element	SAW	surface acoustic wave
RHPZ	right half plane zero	S.B.	set-point bandwidth
RI	refractive index	S.B. SC	system codes or speed controller
RIO	remote operator interface	SCADA	
RIP	routing information protocol	SCADA	supervisory (system) control and data acquisition
RJT	ring joint type	CCCM	•
r(k)	set point	SCCM	standard cubic centimeter per minute
RLL	relay ladder logic	SCD	streaming current detector or sulfur chemi-
RMS or rms		CCE	lumenesce detector
KIVIS OI IIIIS	root mean square (square root of the mean	SCE	saturated calomel electrode
DNC	of the square) or rotary mirror sleeves	SCFH	standard cubic feet per hour
RNG	ring number	SCFM	standard cubic feet per minute (air flow at
RO	reverse osmosis		1.0 atm and 70°F)
ROI	return on investment	SCM	station class mark
ROM	read-only memory	SCMM	standard cubic meter per minute
RON	research octane number	SCO	synchronous connection oriented
RPC	remote procedure call (RFC1831)	SCOT	support coated open tubular (column)
RPG	remote password generator	SCR	silicone-controlled rectifier or selective
RPM or rpm	revolutions per minute		catalytic reduction
rps	revolutions per second	SCS	sample control system

SD	component in leg has failed safe and failure	SOER	sequence of events recorder
	has been detected	SOFA	secondary over fire air
S/D	shut down (valve)	SOFC	solid oxide fuel cell
SDIU	Scanivalve digital interface unit	SONAR	sound navigation ranging
SDN	send data with no acknowledgement	SOP	standard operating procedure
SDS	smart distributed system	SP	set point or Smith predictor
SEA	spokesman election algorithm or slurry	SPC	statistical process control
	density sensor	SPDT	single pole double pole throw (switch)
Sec or sec	seconds; also s	Sp. G or sp. gr.	specific gravity; also SG
SEI	system efficiency index	Sph	starts per hour
SELV	source: extra low voltage	SPI	serial peripheral interface
SER	sequence of event recorder	SPL	1) sound pressure level or 2) sound power
SF	supply fan		level
S/F	smoke and fire (detector)	SPR	set-point rate
SFC	sequential function chart or system function	SPRT	standard platinum resistance thermometer
	configuration or static frequency converter	SPST	single pole single throw (switch)
SFD	system flow diagram or start of frame	Sq	square
	delimiter	sQC	statistical quality control
SFF	safe failure fraction	SQL	structured (or standard, or sequential) query
SFI	sight flow indicator		language
SFR	spurious failure rate	Sr	steradian, symbol for SI unit of solid angle
SG or SpG	specific gravity; also sp. gr.		measurement
S/H or S&H	sample and hold	SRD	send and request data with reply
SH	superheated or superheater	SRS	safety requirements specification
SHE	standard hydrogen electrode	SRV	safety relief valve
SHS	sample handling system	SS	stainless steel or selector switch
SI	system international	SSB	single side band
SIC	speed indicating controller	SSC	solid state contactor
SID	system identification digit (number)	SSE	size scale effect
SIF	safety instrumented function	SSF	Saybolt seconds furol
SIG	special interest group	SSL	secure socket layers
SIL	safety integrity level	SSR	solid state relay
sin	sine, trigonometric function	SSU	Saybolt seconds universal
SIS	safety instrumented system	ST	structured text or steam turbine
SISO	single-input single output	STC	self-tuning controller
SKU	stock keeping units	std.	standard
SLAMS	state and local air monitoring stations	STEL	short term exposure limit
SLC	safety life cycle or single loop controller	STEP	standard for the exchange of product model
slph	standard liters per hour	5121	data
slpm	standard liters per minute	STG	steam turbine generator
SMC	sliding mode control	STIG	steam injection gas turbine
SMCr	sliding mode controller	Stm.	steam injection gas taronic
SMR	specialized mobile radio	STP	shielded twisted pair or standard tempera-
SMTP	simple mail transfer (management) protocol	511	ture and pressure, corresponding to 70°F
S/N	signal-noise (ratio)		(21.1°C) and 14.7 psia (1 atm. Abs.)
SNCR	selective non-catalytic reduction	STR	spurious trip rates or self-tuning regulator
SNG	synthetic natural gas	SU	security unit or component in leg has failed
SNMP	simple network management protocol		safe and failure has not been detected
SNR	signal-to-noise ratio	SUS	Seybold universal seconds or stochastic
SNTP	simple network time protocol	505	uniform selection
SOA	safe operation area	SV	secondary variable or safety valve or sole-
SOAP	simple object access protocol (an Internet	5 1	noid valve
50/11	protocol that provides a reliable stream-	S/W or SW	software
	oriented connection for data transfer)	SWIR	short wave infrared
SOE	sequence of events	$s^2_y$	sample variance of output y
JOL	sequence or events	Зу	sample variance of output y

	_		
	Т	TMR	triple modular redundancy
t	1) ton (metric, = 1000 kg); 2) time;	TMT	tube metal temperature
	3) thickness	TN	total nitrogen or twisted nematic
T	1) temperature; 2) tera, prefix meaning 10 <sup>12</sup> ;	$t_{\rm o} (t_d)$	process dead time (seconds)
	3) period (= 1/Hz, in seconds); 4) tesla, sym-	TOC	total organic carbon
	bol for derived SI unit of magnetic flux den-	TOD	total oxygen demand
	sity, webers per square meter, Wb/m2	TOF	time of flight
$T^{1}/_{2}$	half life	TOP	technical and office protocol
TAH	temperature alarm, high	TP	turbine protection
TAL	temperature alarm, low	TPD	tons per day
Tan	tangent, trigonometric function	TQM	total quality management
Tanh	hyperbolic tangent	TR	temperature recorder or time delay relay
TAS	thallium-arsenic-selenide	T/R	transmit/receive
Tau	process time constant (seconds)	TRC	temperature recording controller
TBM	tertiary butyl mercaptan	TRI	track reference in
TBP	true boiling point	TRO	track reference out
t/c	thermal coefficient of linear expansion	T.S.	tensile strength
TC		TSA	temperature swing adsorption
IC	thermocouple, temperature controller or	TSH	temperature switch, high
TCAN	total carbon	TSL	temperature switch, low
TCAM	timer/counter access modules	TSM	-
TCD	thermal conductivity detector		thermal stress monitoring
TCI	track command in	TSR	terminate and stay resident
TCO	track command out	TT	temperature transmitter or transit time
TCP	transmission control protocol	TTC	tungstram titanium carbide or time to close
TCP/IP	transmission control protocol/Internet	TT&C	telemetry, tracking and command
	protocol	TTFM	transit time flow measurement
TCV	temperature control valve	TTL	transistor-transistor logic or time to live
$t_d$	process dead time (seconds)	TTO	time to open
$T_d$	derivative time (in seconds) of a PID controller	TTP	through the probe
TD	time delay	$t_u$	ultimate period
TDLAS	tunable diode laser absorption spectroscopy	TV	tertiary variable
TDM	time division multiplexing	°Tw	Twadell degrees of liquid density
TDMA	time division multiple access	TWA	time weighed average
TDP	dew point temperature	TWB	wet bulb temperature
TDR	time domain reflectometry	TWM	technical working method
TE	temperature element	TY	temperature relay
T/E	thermoelectric	τ (Tau)	process time constant (seconds)
TEM	transmission electron microscope	$\tau F$	PV filter time constant F
TFELD	thin film electroluminescent display	• •	1 V Inter time constant 1
	thin film transistor		U
TFT			
TG	thermogravimetry	u	prefix = $10^{-6}$ when the Greek letter $\mu$ is not
TGQ	total gas supply	LIADE	available
TH	upper limit of comfort zone	UART	universal asynchronous receiver transmitter
THC	total hydrocarbon	UBET	unbiased estimation
THR	total heat release	UCMM	unconnected message manager
Ti	integral time (in seconds) of a PID controller	UDP	user/universal data/datagram protocol
TI	test interval (time interval between tests)	UEL	upper explosive limit
	or temperature indicator	UF	ultra filtration
TIC	temperature indicating controller or total	u <sub>fb</sub> (k)	feedback controller output
	inorganic carbon	UFD	utility flow diagram
TIFF	tagged image file format	$u_{ff}(k)$	feedforward controller output
TISAB	total ionic strength adjustment buffer	UFL	upper flammable limit
TL	lower limit of comfort zone	UGS	underground gas storage
TLV	threshold limit value	UHF	ultra high frequency
TMP	1) thermo-mechanical pulp; 2) transmem-	UHSDS	ultra high speed deluge system
	brane pressure	u(k)	controller output
	crane pressure	<b>∞</b> (11)	Tomatoner output

TIMI		X / O X /	
UML	universal modeling language	V&V	verification & validation
UPS	uninterruptable power supply	VVVF	variable voltage variable frequency drive
UPV	unfired pressure vessel		
URL	upper range limit		W
URV	upper range value	W	1) width; 2) mass flow rate
USART	universal synchronous/asynchronous receiv-	W	1) watt, symbol for derived SI unit of power,
	er transmitter		joules per second, J/s; 2) weight; also wt
USB	universal serial bus		water; 3) water
USL	upper specification limit	WAN	wide area network
USV	unloading solenoid valve	Wb	weber, symbol for derived SI unit of mag-
UTP	unshielded twisted pair	*****	netic flux, volt $\cdot$ seconds, $V \cdot s$
UTS	ultimate tensile stress	WCOT	wall coated open tubular (column)
UUP	unshielded untwisted pair		
UV	ultraviolet	WDXRF	wavelength dispersion x-ray fluorescence
UVS	uninterruptible voltage supply	WF	weighing factor
UV-VIS-NIR	ultraviolet-visible-near infrared	WFS	water flow switch
O V- V 15-1VIIX	unaviolet-visiole-near infrared	WG	standard (British) wire gauge
	V	Wh	white (wiring code color for AC neutral
			conductor)
V	velocity	WI	Wobble Index
v or V	volt, symbol for derived SI unit of voltage,	WLAN	wireless local area network
	electric potential difference and electromo-	WPAN	wireless personal area network
	tive force, watts per ampere, W/A	WS	work station
VA	vertical alignment	wt	weight; also W
Vac	a.c. voltage		
VAV	variable air volume		X
VBA	visual basis for applications	X	molar fraction of light component in bot-
VCO	voltage controlled oscillator	••	tom product
VCR	virtual communication relationship	X	reactance in ohms
VDC	volts DC	XLS	limit switch
VDF	vacuum fluorescent display	XML	eXtensible markup language
VDT	video display tube	XP	blade pitch position
VDU	video display unit or visual display unit		electromagnetic radiation
vert.	vertical	x-ray XRF	x-ray fluorescence
VF	vacuum fluorescent	XSCV	superheat control valve
VFD	variable frequency drive or vacuum fluo-	XSET	•
	rescent display or virtual field device		start-up setting
VFIR	very fast infrared	XYZ	tri-stimulus functions
VHF	very high frequency		
VIS	visible		Y
V-L	vapor–liquid (ratio)	Y	expansion factor, or molar fraction of light
V/M	voltmeter		component in distillate
VME	Virsa Module Europe (IEEE 1014-1987)	y(k)	process output
VMS	vibration monitoring system	yd	yard (= 0.914 m)
VOC	volatile organic compounds or volatile or-	yr	year
, 5 0	ganic carbon		
VP	valve position		Z
VPA	valve position alarm	Z	molar fraction of light component in feed
VPC	valve position controller	Z	1) atomic number (proton number); 2)
VPN	virtual private network	L	electrical impedance (complex) expressed
VPS	valve position switch		in ohms
VR VR	virtual reality	ZAFC	zinc air fuel cells
VRL	very low frequencies	ZC	position controller
VRL VRML	virtual reality modeling language	ZEB	zero energy band
		ZEB ZIC	= ·
vs. VSA	versus vacuum swing absorption	ZOH	position indicating controller zero order hold
VSA VSD	variable speed drive	ZSC	limit switch – closed
1 0D	variable speed drive	LSC	mint switch – closed

ZSCO ZSO	limit switch – closed/open limit switch – open	$\omega$ (omega)	angular velocity expressed in radians per second
ZSRG	zero signal reference grid	$\Omega$ (omega)	ohm
ZT	position transmitter or zone temperature	$\phi$	diameter, also dia and D
$\partial$	partial derivative	~	alternating current
		,	minute, angular or temporal
		′′	second, angular
MISCELLANEOUS	LETTER SYMBOLS	$\perp$	perpendicular to, normal to
			parallel
α (alpha)	1) geometric angle; 2) radiation particle (helium atom); 3) linear expansion coefficient; 4) average relative volatility between the	%	percent; also pct

	key components across the column	GREEK ALPHAB	ET
$\beta$ (beta)	radiation particle (electron)		
γ (gamma)	1) electromagnetic radiation; 2) surface ten-	Α, α	alpha
	sion; also $\sigma$ (sigma)	Β, β	beta
$\Delta$ (delta)	difference, change or deviation from a	Γ, γ	gamma
	steady-state condition	$\Delta$ , $\delta$	delta
$\varepsilon$ (epsilon)	1) emmissivity; 2) linear strain, relative	E, $\varepsilon$	epsilon
	elongation $\varepsilon \times \Delta 1/1^{\circ}$	Z, ζ	zeta
$\eta$ (eta)	1) efficiency; 2) viscosity (absolute); also $\mu$	H, $\eta$	eta
$\theta$ (theta)	thermal resistance	$\Theta$ , $\theta$	theta
$\lambda$ (lambda)	1) thermal conductivity; 2) wavelength;	Ι, ι	iota
	3) relative gain	Κ, κ	kappa
$\Lambda$ (lambda)	relative gain array	Λ, λ	lambda
$\mu$ (mu)	1) viscosity (absolute); also $\eta$ ; 2) linear	$M, \mu$	mu
	attenuation coefficient; 3) prefix, micro =	N, <i>v</i>	nu
	$10^{-6}$ ; also u; 4) m $\mu$ : millimicron ( $10^{-9}$ m)	Ξ, ξ	xi
$\mu$ m	micron $(10^{-6} \text{ m})$	O, <i>o</i>	omicron
v (nu)	viscosity, kinematic	$\Pi$ , $\pi$	pi
$\pi$ (pi)	1) surface pressure; 2) constant = 3.1416	P, ρ	rho
$\rho$ (rho)	1) density; 2) resistivity	$\Sigma$ , $\sigma$	sigma
$\sigma$ (sigma)	1) surface tension; also $\gamma$ ; 2) conductivity;	Τ, τ	tau
	3) normal stress; 4) nuclear capture cross	Υ, ν	upsilon
	section	$\Phi$ , $\phi$	phi
$\Sigma$ (sigma)	summation	Χ, χ	chi
$\tau$ (tau)	1) time delay; 2) shear stress; 3) time	$\Psi$ , $\psi$	psi
	constant	$\Omega$ , $\omega$	omega